WA-LIST (05) 1 Corr. 14-12-2005

THE WASSENAAR ARRANGEMENT

ON

EXPORT CONTROLS FOR CONVENTIONAL ARMS

AND

DUAL-USE GOODS AND TECHNOLOGIES

LIST OF DUAL-USE GOODS AND TECHNOLOGIES

AND

MUNITIONS LIST

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These Lists reflect the agreements recorded in Appendix 5 to the Initial Elements, dated 19 December 1995, and all amendments, including those approved by the Plenary Meeting (13–14 December 2005) and the Corrigendum to the 2005 Lists.

DUAL-USE LIST

<u>Note</u> Terms in "quotations" are defined terms. Refer to 'Definitions of Terms used in these Lists' annexed to this List.

GENERAL TECHNOLOGY NOTE

The export of "technology" which is "required" for the "development", "production" or "use" of items controlled in the Dual-Use List is controlled according to the provisions in each Category. This "technology" remains under control even when applicable to any uncontrolled item.

Controls do not apply to that "technology" which is the minimum necessary for the installation, operation, maintenance (checking) and repair of those items which are not controlled or whose export has been authorised.

<u>Note</u> This does not release such "technology" controlled in entries 1.E.2.e. & 1.E.2.f. and 8.E.2.a. & 8.E.2.b.

Controls do not apply to "technology" "in the public domain", to "basic scientific research" or to the minimum necessary information for patent applications.

GENERAL SOFTWARE NOTE

The Lists do not control "software" which is either:

- 1. Generally available to the public by being:
 - a. Sold from stock at retail selling points without restriction, by means of:
 - 1. Over-the-counter transactions;
 - 2. Mail order transactions;
 - 3. Electronic transactions; or
 - 4. Telephone call transactions; <u>and</u>
 - b. Designed for installation by the user without further substantial support by the supplier; <u>or</u>

<u>Note</u> Entry 1 of the General Software Note does not release "software" controlled by Category 5 - Part 2 ("Information Security").

2. "In the public domain".

1. A. SYSTEMS, EQUIPMENT AND COMPONENTS

- 1. A. 1. Components made from fluorinated compounds, as follows:
 - a. Seals, gaskets, sealants or fuel bladders specially designed for "aircraft" or aerospace use made from more than 50 % by weight of any of the materials controlled by 1.C.9.b. or 1.C.9.c.;
 - b. Piezoelectric polymers and copolymers made from vinylidene fluoride materials controlled by 1.C.9.a.:
 - 1. In sheet or film form; and
 - 2. With a thickness exceeding 200 µm;
 - c. Seals, gaskets, valve seats, bladders or diaphragms made from fluoroelastomers containing at least one vinylether group as a constitutional unit, specially designed for "aircraft", aerospace or missile use.
- 1. A. 2. "Composite" structures or laminates, having any of the following:
 - a. An organic "matrix" and made from materials controlled by 1.C.10.c., 1.C.10.d. or 1.C.10.e.; or
 - <u>Note</u> 1.A.2.a does not control finished or semi-finished items specially designed for purely civilian applications as follows:
 - a. Sporting goods;
 - b. Automotive industry;
 - c. Machine tool industry;
 - *d. Medical applications.*
 - b. A metal or carbon "matrix" and made from:
 - 1. Carbon "fibrous or filamentary materials" with:
 - a. A specific modulus exceeding 10.15×10^6 m; <u>and</u>
 - b. A specific tensile strength exceeding $17.7 \times 10^4 \text{ m}$; or
 - 2. Materials controlled by 1.C.10.c.
 - <u>Note</u> 1.A.2.b. does not control finished or semi-finished items specially designed for purely civilian applications as follows:
 - a. Sporting goods;
 - b. Automotive industry;
 - c. Machine tool industry;
 - *d. Medical applications.*

- 1. A. 2. b. <u>Technical Notes</u>
 - 1. Specific modulus: Young's modulus in pascals, equivalent to N/m^2 divided by specific weight in N/m^3 , measured at a temperature of $(296 \pm 2) K ((23 \pm 2)^{\circ}C)$ and a relative humidity of $(50 \pm 5)\%$.
 - 2. Specific tensile strength: ultimate tensile strength in pascals, equivalent to N/m^2 divided by specific weight in N/m^3 , measured at a temperature of $(296 \pm 2) K((23 \pm 2)^{\circ}C)$ and a relative humidity of $(50 \pm 5)\%$.
 - <u>Note</u> 1.A.2. does not control composite structures or laminates made from epoxy resin impregnated carbon "fibrous or filamentary materials" for the repair of aircraft structures or laminates, provided the size does not exceed 1 m^2 .
- 1. A. 3. Manufactures of non-fluorinated polymeric substances controlled by 1.C.8.a.3. in film, sheet, tape or ribbon form:
 - a. With a thickness exceeding 0.254 mm; or
 - b. Coated or laminated with carbon, graphite, metals or magnetic substances.
 - <u>Note</u> 1.A.3. does not control manufactures when coated or laminated with copper and designed for the production of electronic printed circuit boards.
- 1. A. 4. Protective and detection equipment and components not specially designed for military use, as follows:
 - a. Gas masks, filter canisters and decontamination equipment therefor designed or modified for defence against biological agents or radioactive materials "adapted for use in war" or chemical warfare (CW) agents and specially designed components therefor;
 - b. Protective suits, gloves and shoes specially designed or modified for defence against biological agents or radioactive materials "adapted for use in war" or chemical warfare (CW) agents;
 - c. Nuclear, biological and chemical (NBC) detection systems specially designed or modified for detection or identification of biological agents or radioactive materials "adapted for use in war" or chemical warfare (CW) agents and specially designed components therefor.
 - <u>Note</u> 1.A.4. does not control :
 - a. Personal radiation monitoring dosimeters;
 - b. Equipment limited by design or function to protect against hazards specific to civil industries, such as mining, quarrying, agriculture, pharmaceuticals, medical, veterinary, environmental, waste management, or to the food industry.

- 1. A. 5. Body armour, and specially designed components therefor, not manufactured to military standards or specifications, nor to their equivalents in performance.
 - <u>N.B.</u> For "fibrous or filamentary materials" used in the manufacture of body amour, see entry 1.C.10.
 - <u>Note 1</u> 1.A.5. does not control body armour or protective garments when accompanying their user for the user's own personal protection.
 - <u>Note 2</u> 1.A.5. does not control body armour designed to provide frontal protection only from both fragment and blast from non-military explosive devices.

1. B. TEST, INSPECTION AND PRODUCTION EQUIPMENT

- 1. B. 1. Equipment for the production of fibres, prepregs, preforms or "composites" controlled by 1.A.2. or 1.C.10., as follows, and specially designed components and accessories therefor:
 - a. Filament winding machines of which the motions for positioning, wrapping and winding fibres are coordinated and programmed in three or more axes, specially designed for the manufacture of "composite" structures or laminates from "fibrous or filamentary materials";
 - b. Tape-laying or tow-placement machines of which the motions for positioning and laying tape, tows or sheets are coordinated and programmed in two or more axes, specially designed for the manufacture of "composite" airframe or missile structures;
 - Multidirectional, multidimensional weaving machines or interlacing machines, including adapters and modification kits, for weaving, interlacing or braiding fibres to manufacture "composite" structures;
 <u>Technical Note</u>

For the purposes of 1.B.1.c. the technique of interlacing includes knitting.

<u>Note</u> 1.B.1.c. does not control textile machinery not modified for the above end-uses.

- d. Equipment specially designed or adapted for the production of reinforcement fibres, as follows:
 - 1. Equipment for converting polymeric fibres (such as polyacrylonitrile, rayon, pitch or polycarbosilane) into carbon fibres or silicon carbide fibres, including special equipment to strain the fibre during heating;
 - 2. Equipment for the chemical vapour deposition of elements or compounds on heated filamentary substrates to manufacture silicon carbide fibres;
 - 3. Equipment for the wet-spinning of refractory ceramics (such as aluminium oxide);
 - 4. Equipment for converting aluminium containing precursor fibres into alumina fibres by heat treatment;

- 1. B. 1. e. Equipment for producing prepregs controlled by 1.C.10.e. by the hot melt method;
 - f. Non-destructive inspection equipment capable of inspecting defects three dimensionally, using ultrasonic or X-ray tomography and specially designed for "composite" materials.
- 1. B. 2. Equipment for producing metal alloys, metal alloy powder or alloyed materials, specially designed to avoid contamination and specially designed for use in one of the processes specified in Item 1.C.2.c.2.
- 1. B. 3. Tools, dies, moulds or fixtures, for "superplastic forming" or "diffusion bonding" titanium or aluminium or their alloys, specially designed for the manufacture of:
 - a. Airframe or aerospace structures;
 - b. "Aircraft" or aerospace engines; or
 - c. Specially designed components for those structures or engines.

1. C. MATERIALS

<u>Technical Note</u>

Metals and alloys

Unless provision to the contrary is made, the words 'metals' and 'alloys' cover crude and semi-fabricated forms, as follows:

Crude forms

Anodes, balls, bars (including notched bars and wire bars), billets, blocks, blooms, brickets, cakes, cathodes, crystals, cubes, dice, grains, granules, ingots, lumps, pellets, pigs, powder, rondelles, shot, slabs, slugs, sponge, sticks;

<u>Semi-fabricated forms</u> (whether or not coated, plated, drilled or punched):

- a. Wrought or worked materials fabricated by rolling, drawing, extruding, forging, impact extruding, pressing, graining, atomising, and grinding, i.e.: angles, channels, circles, discs, dust, flakes, foils and leaf, forging, plate, powder, pressings and stampings, ribbons, rings, rods (including bare welding rods, wire rods, and rolled wire), sections, shapes, sheets, strip, pipe and tubes (including tube rounds, squares, and hollows), drawn or extruded wire;
- b. Cast material produced by casting in sand, die, metal, plaster or other types of moulds, including high pressure castings, sintered forms, and forms made by powder metallurgy.

The object of the control should not be defeated by the export of non-listed forms alleged to be finished products but representing in reality crude forms or semi-fabricated forms.

- 1. C. 1. Materials specially designed for use as absorbers of electromagnetic waves, or intrinsically conductive polymers, as follows:
 - a. Materials for absorbing frequencies exceeding 2×10^8 Hz but less than 3×10^{12} Hz;
 - <u>Note 1</u> 1.C.1.a. does not control:
 - a. Hair type absorbers, constructed of natural or synthetic fibres, with non-magnetic loading to provide absorption;
 - b. Absorbers having no magnetic loss and whose incident surface is non-planar in shape, including pyramids, cones, wedges and convoluted surfaces;
 - *c. Planar absorbers, having all of the following characteristics:1. Made from any of the following:*
 - a. Plastic foam materials (flexible or non-flexible) with carbon-loading, or organic materials, including binders, providing more than 5% echo compared with metal over a bandwidth exceeding $\pm 15\%$ of the centre frequency of the incident energy, and not capable of withstanding temperatures exceeding $450 \text{ K} (177^{\circ} \text{ C}); \text{ or }$
 - b. Ceramic materials providing more than 20% echo compared with metal over a bandwidth exceeding $\pm 15\%$ of the centre frequency of the incident energy, and not capable of withstanding temperatures exceeding 800 K (527°C);

Technical Note

Absorption test samples for 1.C.1.a. Note 1.c.1. should be a square at least 5 wavelengths of the centre frequency on a side and positioned in the far field of the radiating element.

- 2. Tensile strength less than $7 \times 10^6 \text{ N/m}^2$; and
- 3. Compressive strength less than $14 \times 10^6 \text{ N/m}^2$;
- d. Planar absorbers made of sintered ferrite, having:
 - 1. A specific gravity exceeding 4.4; and
 - 2. A maximum operating temperature of 548 K (275°C).
- <u>Note 2</u> Nothing in Note 1 releases magnetic materials to provide absorption when contained in paint.
- 1. C. 1. b. Materials for absorbing frequencies exceeding 1.5×10^{14} Hz but less than 3.7×10^{14} Hz and not transparent to visible light;

- 1. C. 1. c. Intrinsically conductive polymeric materials with a bulk electrical conductivity exceeding 10,000 S/m (Siemens per metre) or a sheet (surface) resistivity of less than 100 ohms/square, based on any of the following polymers:
 - 1. Polyaniline;
 - 2. Polypyrrole;
 - 3. Polythiophene;
 - 4. Poly phenylene-vinylene; or
 - 5. Poly thienylene-vinylene.

Technical Note

Bulk electrical conductivity and sheet (surface) resistivity should be determined using ASTM D-257 or national equivalents.

- 1. C. 2. Metal alloys, metal alloy powder and alloyed materials, as follows:
 - <u>Note</u> 1.C.2. does not control metal alloys, metal alloy powder and alloyed materials for coating substrates.

Technical Notes

- 1. The metal alloys in 1.C.2. are those containing a higher percentage by weight of the stated metal than of any other element.
- 2. Stress-rupture life should be measured in accordance with ASTM standard *E-139* or national equivalents.
- 3. Low cycle fatigue life should be measured in accordance with ASTM Standard E-606 'Recommended Practice for Constant-Amplitude Low-Cycle Fatigue Testing' or national equivalents. Testing should be axial with an average stress ratio equal to 1 and a stress-concentration factor (K_t) equal to 1. The average stress is defined as maximum stress minus minimum stress divided by maximum stress.
- 1. C. 2. a. Aluminides, as follows:
 - 1. Nickel aluminides containing a minimum of 15 weight percent aluminium, a maximum of 38 weight percent aluminium and at least one additional alloying element;
 - 2. Titanium aluminides containing 10 weight percent or more aluminium and at least one additional alloying element;
 - b. Metal alloys, as follows, made from material controlled by 1.C.2.c.:
 - 1. Nickel alloys with:
 - a. A stress-rupture life of 10,000 hours or longer at 923 K (650°C) at a stress of 676 MPa; or
 - b. A low cycle fatigue life of 10,000 cycles or more at 823 K (550° C) at a maximum stress of 1,095 MPa;
 - 2. Niobium alloys with:
 - a. A stress-rupture life of 10,000 hours or longer at 1,073 K (800°C) at a stress of 400 MPa; or
 - b. A low cycle fatigue life of 10,000 cycles or more at 973 K (700°C) at a maximum stress of 700 MPa;

- 1. C. 2. b. 3. Titanium alloys with:
 - a. A stress-rupture life of 10,000 hours or longer at 723 K (450°C) at a stress of 200 MPa; or
 - b. A low cycle fatigue life of 10,000 cycles or more at 723 K (450°C) at a maximum stress of 400 MPa;
 - 4. Aluminium alloys with a tensile strength of:
 - a. 240 MPa or more at 473 K (200°C); or
 - b. 415 MPa or more at 298 K (25°C);
 - 5. Magnesium alloys with:
 - a. A tensile strength of 345 MPa or more; and
 - b. A corrosion rate of less than 1 mm/year in 3% sodium chloride aqueous solution measured in accordance with ASTM standard G-31 or national equivalents;
- 1. C. 2. c. Metal alloy powder or particulate material, having all of the following characteristics:
 - Made from any of the following composition systems: <u>Technical Note</u> X in the following equals one or more alloying elements.
 - a. Nickel alloys (Ni-Al-X, Ni-X-Al) qualified for turbine engine parts or components, i.e. with less than 3 non-metallic particles (introduced during the manufacturing process) larger than $100 \ \mu m \text{ in } 10^9$ alloy particles;
 - b. Niobium alloys (Nb-Al-X or Nb-X-Al, Nb-Si-X or Nb-X-Si, Nb-Ti-X or Nb-X-Ti);
 - c. Titanium alloys (Ti-Al-X or Ti-X-Al);
 - d. Aluminium alloys (Al-Mg-X or Al-X-Mg, Al-Zn-X or Al-X-Zn, Al-Fe-X or Al-X-Fe); <u>or</u>
 - e. Magnesium alloys (Mg-Al-X or Mg-X-Al); and
 - 2. Made in a controlled environment by any of the following processes:
 - a. "Vacuum atomisation";
 - b. "Gas atomisation";
 - c. "Rotary atomisation";
 - d. "Splat quenching";
 - e. "Melt spinning" and "comminution";
 - f. "Melt extraction" and "comminution"; or
 - g. "Mechanical alloying";
 - 3. Capable of forming materials controlled by 1.C.2.a. or 1.C.2.b.;
- 1. C. 2. d. Alloyed materials, having all of the following characteristics:
 - 1. Made from any of the composition systems specified in 1.C.2.c.1.;
 - 2. In the form of uncomminuted flakes, ribbons or thin rods; and
 - 3. Produced in a controlled environment by any of the following:
 - a. "Splat quenching";
 - b. "Melt spinning" <u>or;</u>
 - c. "Melt extraction";

- 1. C. 3. Magnetic metals, of all types and of whatever form, having any of the following characteristics:
 - a. Initial relative permeability of 120,000 or more and a thickness of 0.05 mm or less;

Technical Note

Measurement of initial permeability must be performed on fully annealed materials.

- b. Magnetostrictive alloys, having any of the following characteristics:
 - 1. A saturation magnetostriction of more than 5×10^{-4} ; or
 - 2. A magnetomechanical coupling factor (k) of more than 0.8; or
- c. Amorphous or nanocrystalline alloy strips, having all of the following characteristics:
 - 1. A composition having a minimum of 75 weight percent of iron, cobalt or nickel;
 - 2. A saturation magnetic induction (B_s) of 1.6 T or more; and
 - 3. Any of the following:
 - a. A strip thickness of 0.02 mm or less; or
 - b. An electrical resistivity of 2×10^{-4} ohm cm or more.

Technical Note

'Nanocrystalline' materials in 1.C.3.c. are those materials having a crystal grain size of 50 nm or less, as determined by X-ray diffraction.

- 1. C. 4. Uranium titanium alloys or tungsten alloys with a "matrix" based on iron, nickel or copper, having all of the following:
 - a. A density exceeding 17.5 g/cm^3 ;
 - b. An elastic limit exceeding 880 MPa;
 - c. An ultimate tensile strength exceeding 1,270 MPa; and
 - d. An elongation exceeding 8%.
- 1. C. 5. "Superconductive" "composite" conductors in lengths exceeding 100 m or with a mass exceeding 100 g, as follows:
 - a. Multifilamentary "superconductive" "composite" conductors containing one or more niobium-titanium filaments:
 - 1. Embedded in a "matrix" other than a copper or copper-based mixed "matrix"; or
 - 2. Having a cross-section area less than $0.28 \times 10^{-4} \text{ mm}^2$ (6 µm in diameter for circular filaments);
 - b. "Superconductive" "composite" conductors consisting of one or more "superconductive" filaments other than niobium-titanium, having all of the following:
 - 1. A "critical temperature" at zero magnetic induction exceeding 9.85 K (-263.31°C) but less than 24 K (-249.16°C);
 - 2. A cross-section area less than $0.28 \times 10^{-4} \text{ mm}^2$; and
 - 3. Remaining in the "superconductive" state at a temperature of 4.2 K (-268.96°C) when exposed to a magnetic field corresponding to a magnetic induction of 12 T.
- 1. C. 6. Fluids and lubricating materials, as follows:

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- a. Hydraulic fluids containing, as their principal ingredients, any of the following compounds or materials:
 - 1. Synthetic silahydrocarbon oils, having all of the following: <u>Technical Note</u> For the purpose of 1.C.6.a.1., silahydrocarbon oils contain exclusively silicon, hydrogen and carbon.
 - a. A flash point exceeding 477 K (204°C);
 - b. A pour point at 239 K (-34°C) or less;
 - c. A viscosity index of 75 or more; and
 - d. A thermal stability at 616 K (343°C); or
 - Chlorofluorocarbons, having all of the following: <u>Technical Note</u> For the purpose of 1.C.6.a.2., chlorofluorocarbons contain exclusively carbon, fluorine and chlorine.
 - a. No flash point;
 - b. An autogenous ignition temperature exceeding 977 K (704°C);
 - c. A pour point at 219 K (-54°C) or less;
 - d. A viscosity index of 80 or more; and
 - e. A boiling point at 473 K (200°C) or higher;
- 1. C. 6. b. Lubricating materials containing, as their principal ingredients, any of the following compounds or materials:
 - 1. Phenylene or alkylphenylene ethers or thio-ethers, or their mixtures, containing more than two ether or thio-ether functions or mixtures thereof; or
 - 2. Fluorinated silicone fluids with a kinematic viscosity of less than 5,000 mm²/s (5,000 centistokes) measured at 298 K (25°C);
- C. 6. c. Damping or flotation fluids with a purity exceeding 99.8%, containing less than 25 particles of 200 μm or larger in size per 100 ml and made from at least 85% of any of the following compounds or materials:
 - 1. Dibromotetrafluoroethane;
 - 2. Polychlorotrifluoroethylene (oily and waxy modifications only); or
 - 3. Polybromotrifluoroethylene;
- 1. C. 6. d. Fluorocarbon electronic cooling fluids, having all of the following characteristics:
 - 1. Containing 85% by weight or more of any of the following, or mixtures thereof:
 - a. Monomeric forms of perfluoropolyalkylether-triazines or perfluoroaliphatic-ethers;
 - b. Perfluoroalkylamines;
 - c. Perfluorocycloalkanes; or
 - d. Perfluoroalkanes;
 - 2. Density at 298 K (25°C) of 1.5 g/ml or more;
 - 3. In a liquid state at 273 K (0° C); and
 - 4. Containing 60% or more by weight of fluorine.
- 1. C. 6. <u>Technical Note</u>

For the purpose of 1.C.6.:

- a. Flash point is determined using the Cleveland Open Cup Method described in ASTM D-92 or national equivalents;
- b. Pour point is determined using the method described in ASTM D-97 or national equivalents;
- *c.* Viscosity index is determined using the method described in ASTM D-2270 or national equivalents;
- *d. Thermal stability is determined by the following test procedure or national equivalents:*

Twenty ml of the fluid under test is placed in a 46 ml type 317 stainless steel chamber containing one each of 12.5 mm (nominal) diameter balls of M-10 tool steel, 52100 steel and naval bronze (60% Cu, 39% Zn, 0.75% Sn);

The chamber is purged with nitrogen, sealed at atmospheric pressure and the temperature raised to and maintained at $644 \pm 6 K$ (371 ± 6°C) for six hours;

The specimen will be considered thermally stable if, on completion of the above procedure, all of the following conditions are met:

- 1. The loss in weight of each ball is less than 10 mg/mm^2 of ball surface;
- 2. The change in original viscosity as determined at 311 K (38°C) is less than 25%; and
- 3. The total acid or base number is less than 0.40;
- e. Autogenous ignition temperature is determined using the method described in ASTM E-659 or national equivalents.
- 1. C. 7. Ceramic base materials, non-"composite" ceramic materials, ceramic-"matrix" "composite" materials and precursor materials, as follows:
 - a. Base materials of single or complex borides of titanium having total metallic impurities, excluding intentional additions, of less than 5,000 ppm, an average particle size equal to or less than 5 μ m and no more than 10% of the particles larger than 10 μ m;
 - b. Non-"composite" ceramic materials in crude or semi-fabricated form, composed of borides of titanium with a density of 98% or more of the theoretical density;

<u>Note</u> 1.C.7.b. does not control abrasives.

- c. Ceramic-ceramic "composite" materials with a glass or oxide-"matrix" and reinforced with fibres having all of the following:
 - 1. Made from any of the following materials:
 - a. Si-N;
 - b. Si-C;
 - c. Si-Al-O-N; <u>or</u>
 - d. Si-O-N; and
 - 2. Having a specific tensile strength exceeding 12.7×10^3 m;
- 1. C. 7. d. Ceramic-ceramic "composite" materials, with or without a continuous metallic phase, incorporating particles, whiskers or fibres, where carbides or nitrides of silicon, zirconium or boron form the "matrix";

- e. Precursor materials (i.e., special purpose polymeric or metallo-organic materials) for producing any phase or phases of the materials controlled by 1.C.7.c., as follows:
 - 1. Polydiorganosilanes (for producing silicon carbide);
 - 2. Polysilazanes (for producing silicon nitride);
 - 3. Polycarbosilazanes (for producing ceramics with silicon, carbon and nitrogen components);
- f. Ceramic-ceramic "composite" materials with an oxide or glass "matrix" reinforced with continuous fibres from any of the following systems:
 - 1. Al₂O_{3; <u>or</u>}
 - 2. Si-C-N.
 - <u>Note</u> 1.C.7.f. does not control "composites" containing fibres from these systems with a fibre tensile strength of less than 700 MPa at 1,273 K (1,000° C) or fibre tensile creep resistance of more than 1% creep strain at 100 MPa load and 1,273 K (1,000° C) for 100 hours.
- 1. C. 8. Non-fluorinated polymeric substances, as follows:
 - a. 1. Bismaleimides;
 - 2. Aromatic polyamide-imides;
 - 3. Aromatic polyimides;
 - 4. Aromatic polyetherimides having a glass transition temperature (T_g) exceeding 513 K (240° C);

<u>Note</u> 1.C.8.a. does not control non-fusible compression moulding powders or moulded forms.

- b. Thermoplastic liquid crystal copolymers having a heat distortion temperature exceeding 523 K (250°C) measured according to ISO 75-3 (2004), or national equivalents, with a load of 1.82 N/mm^2 and composed of:
 - 1. Any of the following:
 - a. Phenylene, biphenylene or naphthalene; or
 - b. Methyl, tertiary-butyl or phenyl substituted phenylene, biphenylene or naphthalene; and
 - 2. Any of the following acids:
 - a. Terephthalic acid;
 - b. 6-hydroxy-2 naphthoic acid; <u>or</u>
 - c. 4-hydroxybenzoic acid;
- c. Polyarylene ether ketones, as follows:
 - 1. Deleted
 - 2. Polyether ketone ketone (PEKK);
 - 3. Polyether ketone (PEK);
 - 4. Polyether ketone ether ketone ketone (PEKEKK);
- 1. C. 8. d. Polyarylene ketones;
 - e. Polyarylene sulphides, where the arylene group is biphenylene, triphenylene or combinations thereof;

f. Polybiphenylenethersulphone having a glass transition temperature (Tg) exceeding 513 K (240° C).

Technical Note

The glass transition temperature (Tg) for 1.C.8. materials is determined using the method described in ISO 11357-2 (1999) or national equivalents.

- 1. C. 9. Unprocessed fluorinated compounds, as follows:
 - a. Copolymers of vinylidene fluoride having 75% or more beta crystalline structure without stretching;
 - b. Fluorinated polyimides containing 10% by weight or more of combined fluorine;
 - c. Fluorinated phosphazene elastomers containing 30% by weight or more of combined fluorine.
- 1. C. 10. "Fibrous or filamentary materials" which may be used in organic "matrix", metallic "matrix" or carbon "matrix" "composite" structures or laminates, as follows:
 - a. Organic "fibrous or filamentary materials", having all of the following:
 - 1. A specific modulus exceeding $12.7 \times 10^6 \text{ m}$; and
 - 2. A specific tensile strength exceeding 23.5×10^4 m;

<u>Note</u> 1.C.10.a. does not control polyethylene.

- b. Carbon "fibrous or filamentary materials", having all of the following:
 - 1. A specific modulus exceeding 12.7×10^6 m; and
 - 2. A specific tensile strength exceeding $23.5 \times 10^4 \text{ m}$;

Technical Note

Properties for materials described in 1.C.10.b. should be determined using SACMA recommended methods SRM 12 to 17, or national equivalent tow tests, such as Japanese Industrial Standard JIS-R-7601, Paragraph 6.6.2., and based on lot average.

<u>Note</u> 1.C.10.b. does not control fabric made from "fibrous or filamentary materials" for the repair of aircraft structures or laminates, in which the size of individual sheets does not exceed 50 cm x 90 cm.

- 1. C. 10. c. Inorganic "fibrous or filamentary materials", having all of the following:
 - 1. A specific modulus exceeding 2.54×10^6 m; and
 - 2. A melting, softening, decomposition or sublimation point exceeding 1,922 K (1,649°C) in an inert environment;

<u>Note</u> 1.C.10.c. does not control:

- 1. Discontinuous, multiphase, polycrystalline alumina fibres in chopped fibre or random mat form, containing 3 weight percent or more silica, with a specific modulus of less than 10×10^6 m;
- 2. Molybdenum and molybdenum alloy fibres;
- 3. Boron fibres;
- 4. Discontinuous ceramic fibres with a melting, softening, decomposition or sublimation point lower than 2,043 K (1,770°C) in an inert environment.
- 1. C. 10. d. "Fibrous or filamentary materials":
 - 1. Composed of any of the following:
 - a. Polyetherimides controlled by 1.C.8.a; or
 - b. Materials controlled by 1.C.8.b. to 1.C.8.f.; or
 - 2. Composed of materials controlled by 1.C.10.d.1.a. or 1.C.10.d.1.b. and "commingled" with other fibres controlled by 1.C.10.a., 1.C.10.b. or 1.C.10.c.;
- 1. C. 10. e. Resin-impregnated or pitch-impregnated fibres (prepregs), metal or carboncoated fibres (preforms) or "carbon fibre preforms", as follows:
 - 1. Made from "fibrous or filamentary materials" controlled by 1.C.10.a., 1.C.10.b. or 1.C.10.c.;
 - 2. Made from organic or carbon "fibrous or filamentary materials":
 - a. With a specific tensile strength exceeding 17.7×10^4 m;
 - b. With a specific modulus exceeding 10.15×10^6 m;
 - c. Not controlled by 1.C.10.a. or 1.C.10.b.; and
 - d. When impregnated with materials controlled by 1.C.8. or 1.C.9.b., having a glass transition temperature (T_g) exceeding 383 K (110°C) or with phenolic or epoxy resins, having a glass transition temperature (T_g) equal to or exceeding 418 K (145°C).
 - <u>Notes</u> 1.C.10.e. does not control:
 - 1. Epoxy resin "matrix" impregnated carbon "fibrous or filamentary materials" (prepregs) for the repair of aircraft structures or laminates, in which the size of individual sheets of prepreg does not exceed 50 cm x 90 cm;

Notes contd

2. Prepregs when impregnated with phenolic or epoxy resins having a glass transition temperature (Tg) less than 433 K $(160^{\circ}C)$ and a cure temperature lower than the glass transition temperature.

Technical Note

The glass transition temperature (Tg) for 1.C.10.e. materials is determined using the method described in ASTM D 3418 using the dry method. The glass transition temperature for phenolic and epoxy resins is determined using the method described in ASTM D 4065 at a frequency of 1Hz and a heating rate of 2 K (°C) per minute using the dry method.

Technical Notes

- 1. Specific modulus: Young's modulus in pascals, equivalent to N/m^2 divided by specific weight in N/m^3 , measured at a temperature of $(296 \pm 2) K$ $((23 \pm 2)^{\circ}C)$ and a relative humidity of $(50 \pm 5)\%$.
- 2. Specific tensile strength: ultimate tensile strength in pascals, equivalent to N/m^2 divided by specific weight in N/m^3 , measured at a temperature of $(296 \pm 2) \text{ K} ((23 \pm 2)^{\circ}\text{C})$ and a relative humidity of $(50 \pm 5)\%$.
- 1. C. 11. Metals and compounds, as follows:
 - a. Metals in particle sizes of less than 60 µm whether spherical, atomised, spheroidal, flaked or ground, manufactured from material consisting of 99% or more of zirconium, magnesium and alloys of these; *Technical Note*

The natural content of hafnium in the zirconium (typically 2% to 7%) is counted with the zirconium.

- <u>Note</u> The metals or alloys listed in 1.C.11.a. are controlled whether or not the metals or alloys are encapsulated in aluminium, magnesium, zirconium or beryllium.
- b. Boron or boron carbide of 85% purity or higher and a particle size of $60 \,\mu\text{m}$ or less;
 - <u>Note</u> The metals or alloys listed in 1.C.11.b. are controlled whether or not the metals or alloys are encapsulated in aluminium, magnesium, zirconium or beryllium.
- c. Guanidine nitrate;
- d. Nitroguanidine (NQ) (CAS 556-88-7).

- 1. C. 12. Materials as follows: <u>Technical Note</u> These materials are typically used for nuclear heat sources.
 - a. Plutonium in any form with a plutonium isotopic assay of plutonium-238 of more than 50% by weight;

<u>Note</u> 1.C.12.a. does not control:

- 1. Shipments with a plutonium content of 1 g or less;
- 2. Shipments of 3 "effective grams" or less when contained in a sensing component in instruments.
- b. "Previously separated" neptunium-237 in any form. <u>Note</u> 1.C.12.b. does not control shipments with a neptunium-237 content of 1 g or less.

1. D. SOFTWARE

- 1. D. 1. "Software" specially designed or modified for the "development", "production" or "use" of equipment controlled by 1.B.
- 1. D. 2. "Software" for the "development" of organic "matrix", metal "matrix" or carbon "matrix" laminates or "composites".
- 1. E. <u>TECHNOLOGY</u>
- 1. E. 1. "Technology" according to the General Technology Note for the "development" or "production" of equipment or materials controlled by 1.A.1.b., 1.A.1.c., 1.A.2. to 1.A.5., 1.B. or 1.C.
- 1. E. 2. Other "technology", as follows:
 - a. "Technology" for the "development" or "production" of polybenzothiazoles or polybenzoxazoles;
 - b. "Technology" for the "development" or "production" of fluoroelastomer compounds containing at least one vinylether monomer;
- 1. E. 2. c. "Technology" for the design or "production" of the following base materials or non-"composite" ceramic materials:
 - 1. Base materials having all of the following characteristics:
 - a. Any of the following compositions:
 - 1. Single or complex oxides of zirconium and complex oxides of silicon or aluminium;
 - 2. Single nitrides of boron (cubic crystalline forms);
 - 3. Single or complex carbides of silicon or boron; or
 - 4. Single or complex nitrides of silicon;

- 1. E. 2. c. 1. b. Total metallic impurities, excluding intentional additions, of less than:
 - 1. 1,000 ppm for single oxides or carbides; or
 - 2. 5,000 ppm for complex compounds or single nitrides; and
 - c. Being any of the following:
 - 1. Zirconia with an average particle size equal to or less than $1 \,\mu m$ and no more than 10% of the particles larger than $5 \,\mu m$;
 - 2. Other base materials with an average particle size equal to or less than 5 μ m and no more than 10% of the particles larger than 10 μ m; or
 - 3. Having all of the following:
 - a. Platelets with a length to thickness ratio exceeding 5;
 - b. Whiskers with a length to diameter ratio exceeding 10 for diameters less than $2 \mu m$; and
 - c. Continuous or chopped fibres less than $10\,\mu\text{m}$ in diameter;
- 1. E. 2. c. 2. Non-"composite" ceramic materials composed of the materials described in 1.E.2.c.1.; Note 1.E.2.c.2. does not control technology for the design or

te 1.E.2.c.2. *does not control technology for the design or production of abrasives.*

- 1. E. 2. d. "Technology" for the "production" of aromatic polyamide fibres;
 - e. "Technology" for the installation, maintenance or repair of materials controlled by 1.C.1.;
 - f. "Technology" for the repair of "composite" structures, laminates or materials controlled by 1.A.2., 1.C.7.c. or 1.C.7.d.
 - <u>Note</u> 1.E.2.f. does not control "technology" for the repair of "civil aircraft" structures using carbon "fibrous or filamentary materials" and epoxy resins, contained in aircraft manufacturers' manuals.

2. A. SYSTEMS, EQUIPMENT AND COMPONENTS

<u>N.B.</u> For quiet running bearings, see Item 9 on the Munitions List.*

- 2. A. 1. Anti-friction bearings and bearing systems, as follows, and components therefor: <u>Note</u> 2.A.1. does not control balls with tolerances specified by the manufacturer in accordance with ISO 3290 as grade 5 or worse.
 - Ball bearings and solid roller bearings having all tolerances specified by the manufacturer in accordance with ISO 492 Tolerance Class 4 (or ANSI/ABMA Std 20 Tolerance Class ABEC-7 or RBEC-7, or other national equivalents), or better, and having both rings and rolling elements (ISO 5593) made from monel or beryllium; <u>Note</u> 2.A.1.a. does not control tapered roller bearings.
 - b. Other ball bearings and solid roller bearings having all tolerances specified by the manufacturer in accordance with ISO 492 Tolerance Class 2 (or ANSI/ABMA Std 20 Tolerance Class ABEC-9 or RBEC-9, or other national equivalents), or better;

<u>Note</u> 2.A.1.b. does not control tapered roller bearings.

- c. Active magnetic bearing systems using any of the following:
 - 1. Materials with flux densities of 2.0 T or greater and yield strengths greater than 414 MPa;
 - 2. All-electromagnetic 3D homopolar bias designs for actuators; or
 - 3. High temperature (450 K (177°C) and above) position sensors.

2. B. TEST, INSPECTION AND PRODUCTION EQUIPMENT

Technical Notes

- 1. Secondary parallel contouring axes, (e.g., the w-axis on horizontal boring mills or a secondary rotary axis the centre line of which is parallel to the primary rotary axis) are not counted in the total number of contouring axes. Rotary axes need not rotate over 360°. A rotary axis can be driven by a linear device (e.g., a screw or a rack-and-pinion).
- 2. For the purposes of 2.B, the number of axes which can be co-ordinated simultaneously for "contouring control" is the number of axes along or around which, during processing of the workpiece, simultaneous and interrelated motions are performed between the workpiece and a tool. This does not include any additional axes along or around which other relative motions within the machine are performed, such as:

^{*} France, the Russian Federation and Ukraine view this list as a reference list drawn up to help in the selection of dual-use goods which could contribute to the indigenous development, production or enhancement of conventional munitions capabilities.

Technical Notes contd.

- a. Wheel-dressing systems in grinding machines;
- b. Parallel rotary axes designed for mounting of separate workpieces;
- *c.* Co-linear rotary axes designed for manipulating the same workpiece by holding it in a chuck from different ends.
- 3. Axis nomenclature shall be in accordance with International Standard ISO 841, 'Numerical Control Machines - Axis and Motion Nomenclature'.
- 4. For the purposes of this Category a "tilting spindle" is counted as a rotary axis.
- 5. Stated positioning accuracy levels derived from measurements made according to ISO 230/2 (1997) or national equivalents may be used for each machine tool model instead of individual machine tests. Stated positioning accuracy means the accuracy value provided to national licensing authorities as representative of the accuracy of a machine model.

Determination of Stated Values

- a. Select five machines of a model to be evaluated;
- b. Measure the linear axis accuracies according to ISO 230/2 (1997);
- c. Determine the A-values for each axis of each machine. The method of calculating the A-value is described in the ISO standard;
- *d.* Determine the mean value of the *A*-value of each axis. This mean value \overline{A} becomes the stated value of each axis for the model ($\overline{Ax} \quad \overline{Ay}$...);
- e. Since the Category 2 list refers to each linear axis there will be as many stated values as there are linear axes;
- f. If any axis of a machine model not controlled by 2.B.1.a. to 2.B.1.c. has a stated accuracy \overline{A} of 5 microns for grinding machines and 6.5 microns for milling and turning machines or better, the builder should be required to reaffirm the accuracy level once every eighteen months.
- 2. B. 1. Machine tools and any combination thereof, for removing (or cutting) metals, ceramics or "composites", which, according to the manufacturer's technical specification, can be equipped with electronic devices for "numerical control", and specially designed components as follows:
 - <u>Note 1</u> 2.B.1. does not control special purpose machine tools limited to the manufacture of gears. For such machines, see Item 2.B.3.
 - <u>Note 2</u> 2.B.1. does not control special purpose machine tools limited to the manufacture of any of the following parts:
 - a. Crank shafts or cam shafts;
 - *b. Tools or cutters;*
 - c. Extruder worms;
 - d. Engraved or facetted jewellery parts;
 - <u>Note 3</u> A machine tool having at least two of the three turning, milling or grinding capabilities (e.g., a turning machine with milling capability), must be evaluated against each applicable entry 2.B.1.a., b. or c.

- 2. B. 1. a. Machine tools for turning, having all of the following characteristics:
 - 1. Positioning accuracy with "all compensations available" equal to or less (better) than 4.5 μ m according to ISO 230/2 (1997) or national equivalents along any linear axis; and
 - 2. Two or more axes which can be coordinated simultaneously for "contouring control";
 - <u>Note</u> 2.B.1.a. does not control turning machines specially designed for the production of contact lenses.

2. B. 1. b. Machine tools for milling, having any of the following characteristics:

Having all of the following:

1.

- a. Positioning accuracy with "all compensations available" equal to or less (better) than 4.5 μm according to ISO 230/2 (1997) or national equivalents along any linear axis; and
- b. Three linear axes plus one rotary axis which can be coordinated simultaneously for "contouring control";
- 2. Five or more axes which can be coordinated simultaneously for "contouring control";
- 3. A positioning accuracy for jig boring machines, with "all compensations available", equal to or less (better) than $3.0 \,\mu m$ according to ISO 230/2 (1997) or national equivalents along any linear axis; or
- 4. Fly cutting machines, having all of the following characteristics:
 - a. Spindle "run-out" and "camming" less (better) than 0.0004 mm TIR; and
 - b. Angular deviation of slide movement (yaw, pitch and roll) less (better) than 2 seconds of arc, TIR, over 300 mm of travel.

2. B. 1. c. Machine tools for grinding, having any of the following characteristics:

- 1. Having all of the following:
 - a. Positioning accuracy with "all compensations available" equal to or less (better) than 3.0 µm according to ISO 230/2 (1997) or national equivalents along any linear axis; and
 - b. Three or more axes which can be coordinated simultaneously for "contouring control"; <u>or</u>
- 2. Five or more axes which can be coordinated simultaneously for "contouring control";

<u>Notes</u> 2.B.1.c. does not control grinding machines, as follows:

- 1. Cylindrical external, internal, and external-internal grinding machines having all the following characteristics:
 - a. Limited to cylindrical grinding; and
 - b. Limited to a maximum workpiece capacity of 150 mm outside diameter or length.
- 2. Machines designed specifically as jig grinders that do not have a z-axis or a w-axis, with a positioning accuracy with "all compensations available" less (better) than 3 μm according to ISO 230/2 (1997) or national equivalents.
- *3. Surface grinders.*
- B. 1. d. Electrical discharge machines (EDM) of the non-wire type which have two or more rotary axes which can be coordinated simultaneously for "contouring control";
- 2. B. 1. e. Machine tools for removing metals, ceramics or "composites" having all of the following characteristics:
 - 1. Removing material by means of any of the following:
 - a. Water or other liquid jets, including those employing abrasive additives;
 - b. Electron beam; or
 - c. "Laser" beam; and
 - 2. Having two or more rotary axes which:
 - a. Can be coordinated simultaneously for "contouring control"; and
 - b. Have a positioning accuracy of less (better) than 0.003°;
 - f. Deep-hole-drilling machines and turning machines modified for deep-holedrilling, having a maximum depth-of-bore capability exceeding 5,000 mm and specially designed components therefor.
- 2. B. 2. Numerically controlled machine tools using a magnetorheological finishing (MRF) process equipped to produce non-spherical surfaces and having any of the following characteristics:
 - a. Finishing the form to less (better) than 1.0 µm; or
 - b. Finishing to a roughness less (better) than 100 nm rms.

Technical Note

For the purposes of 2.B.2., 'MRF' is a material removal process using an abrasive magnetic fluid whose viscosity is controlled by a magnetic field.

2. B. 3. "Numerically controlled" or manual machine tools, and specially designed components, controls and accessories therefor, specially designed for the shaving, finishing, grinding or honing of hardened ($R_c = 40$ or more) spur, helical and double-helical gears with a pitch diameter exceeding 1,250 mm and a face width of 15% of pitch diameter or larger finished to a quality of AGMA 14 or better (equivalent to ISO 1328 class 3).

- 2. B. 4. Hot "isostatic presses", having all of the following, and specially designed components and accessories therefor:
 - a. A controlled thermal environment within the closed cavity and a chamber cavity with an inside diameter of 406 mm or more; and
 - b. Any of the following:
 - 1. A maximum working pressure exceeding 207 MPa;
 - 2. A controlled thermal environment exceeding 1,773 K (1,500°C); or
 - 3. A facility for hydrocarbon impregnation and removal of resultant gaseous degradation products.

Technical Note

The inside chamber dimension is that of the chamber in which both the working temperature and the working pressure are achieved and does not include fixtures. That dimension will be the smaller of either the inside diameter of the pressure chamber or the inside diameter of the insulated furnace chamber, depending on which of the two chambers is located inside the other.

- <u>N.B.</u> For specially designed dies, moulds and tooling see Items 1.B.3., 9.B.9. and ML18. of the Munitions List.*
- B. 5. Equipment specially designed for the deposition, processing and in-process control of inorganic overlays, coatings and surface modifications, as follows, for non-electronic substrates, by processes shown in the Table and associated Notes following 2.E.3.f., and specially designed automated handling, positioning, manipulation and control components therefor:
 - a. Chemical vapour deposition (CVD) production equipment having all of the following:
 - 1. Process modified for one of the following:
 - a. Pulsating CVD;
 - b. Controlled nucleation thermal deposition (CNTD); or
 - c. Plasma enhanced or plasma assisted CVD; and
 - 2. Any of the following:
 - a. Incorporating high vacuum (equal to or less than 0.01 Pa) rotating seals; <u>or</u>
 - b. Incorporating *in situ* coating thickness control;
 - b. Ion implantation production equipment having beam currents of 5 mA or more;

^{*} France, the Russian Federation and Ukraine view this list as a reference list drawn up to help in the selection of dual-use goods which could contribute to the indigenous development, production or enhancement of conventional munitions capabilities.

- B. 5. c. Electron beam physical vapour deposition (EB-PVD) production equipment incorporating power systems rated for over 80 kW, having any of the following:
 - 1. A liquid pool level "laser" control system which regulates precisely the ingots feed rate; <u>or</u>
 - 2. A computer controlled rate monitor operating on the principle of photoluminescence of the ionised atoms in the evaporant stream to control the deposition rate of a coating containing two or more elements;
 - d. Plasma spraying production equipment having any of the following characteristics:
 - 1. Operating at reduced pressure controlled atmosphere (equal to or less than 10 kPa measured above and within 300 mm of the gun nozzle exit) in a vacuum chamber capable of evacuation down to 0.01 Pa prior to the spraying process; <u>or</u>
 - 2. Incorporating *in situ* coating thickness control;
 - e. Sputter deposition production equipment capable of current densities of 0.1 mA/mm^2 or higher at a deposition rate of 15 μ m/h or more;
 - f. Cathodic arc deposition production equipment incorporating a grid of electromagnets for steering control of the arc spot on the cathode;
 - g. Ion plating production equipment allowing for the *in situ* measurement of any of the following:
 - 1. Coating thickness on the substrate and rate control; or
 - 2. Optical characteristics.
 - <u>Note</u> 2.B.5.a., 2.B.5.b., 2.B.5.e., 2.B.5.f. and 2.B.5.g. do not control chemical vapour deposition, cathodic arc, sputter deposition, ion plating or ion implantation equipment specially designed for cutting or machining tools.
- 2. B. 6. Dimensional inspection or measuring systems, equipment and "electronic assemblies", as follows:
 - a. Computer controlled or "numerically controlled" co-ordinate measuring machines (CMM), having a three dimensional (volumetric) maximum permissible error of indication (MPEE) at any point within the operating range of the machine (i.e., within the length of axes) equal to or less (better) than $1.7 + L/1,000 \mu m$ (L is the measured length in mm), tested according to ISO 10360-2 (2001);
 - b. Linear and angular displacement measuring instruments, as follows:
 - 1. Linear displacement measuring instruments having any of the following:

<u>Technical Note</u> For the purpose of 2.B.6.b.1., 'linear displacement' means the change of distance between the measuring probe and the measured object.

- 2. B. 6. b. 1. a. Non-contact type measuring systems with a "resolution" equal to or less (better) than 0.2 μm within a measuring range up to 0.2 mm;
 - b. Linear voltage differential transformer systems having all of the following characteristics:
 - 1. "Linearity" equal to or less (better) than 0.1% within a measuring range up to 5 mm; and
 - 2. Drift equal to or less (better) than 0.1% per day at a standard ambient test room temperature ± 1 K; or
 - c. Measuring systems having all of the following:
 - 1. Containing a "laser"; and
 - 2. Maintaining, for at least 12 hours, over a temperature range of ± 1 K around a standard temperature and at a standard pressure, all of the following:
 - a. A "resolution" over their full scale of $0.1 \,\mu m$ or less (better); and
 - b. A "measurement uncertainty" equal to or less (better) than $(0.2 + L/2,000) \mu m$ (L is the measured length in mm);
 - d. "Electronic assemblies" specially designed to provide feedback capability in systems controlled by 2.B.6.b.1.c.
 - <u>Note</u> 2.B.6.b.1. does not control measuring interferometer systems, with an automatic control system that is designed to use no feedback techniques, containing a "laser" to measure slide movement errors of machine-tools, dimensional inspection machines or similar equipment.
- 2. B. 6. b. 2. Angular displacement measuring instruments having an "angular position deviation" equal to or less (better) than 0.00025°;
 - <u>Note</u> 2.B.6.b.2. does not control optical instruments, such as autocollimators, using collimated light (e.g., laser light) to detect angular displacement of a mirror.
- 2. B. 6. c. Equipment for measuring surface irregularities, by measuring optical scatter as a function of angle, with a sensitivity of 0.5 nm or less (better).
 - <u>Note</u> Machine tools which can be used as measuring machines are controlled if they meet or exceed the criteria specified for the machine tool function or the measuring machine function.
- 2. B. 7. "Robots" having any of the following characteristics and specially designed controllers and "end-effectors" therefor:

 B. 7. a. Capable in real time of full three-dimensional image processing or full three-dimensional scene analysis to generate or modify "programmes" or to generate or modify numerical programme data;

<u>Technical Note</u> The scene analysis limitation does not include approximation of the third dimension by viewing at a given angle, or limited grey scale interpretation for the perception of depth or texture for the approved tasks $(2 \ 1/2 \ D)$.

- b. Specially designed to comply with national safety standards applicable to explosive munitions environments;
- c. Specially designed or rated as radiation-hardened to withstand greater than 5×10^3 Gy (Si) without operational degradation; or
- d. Specially designed to operate at altitudes exceeding 30,000 m.
- 2. B. 8. Assemblies or units, specially designed for machine tools, or dimensional inspection or measuring systems and equipment, as follows:
 - a. Linear position feedback units (e.g., inductive type devices, graduated scales, infrared systems or "laser" systems) having an overall "accuracy" less (better) than (800 + (600 x L x 10⁻³)) nm (L equals the effective length in mm);

<u>N.B.</u> For "laser" systems see also Note to 2.B.6.b.1.

B. Rotary position feedback units (e.g., inductive type devices, graduated scales, infrared systems or "laser" systems) having an "accuracy" less (better) than 0.00025°;
 N.P. For "laser" systems are also Nate to 2.P.6 h l.

<u>N.B.</u> For "laser" systems see also Note to 2.B.6.b.1.

- c. "Compound rotary tables" and "tilting spindles", capable of upgrading, according to the manufacturer's specifications, machine tools to or above the levels specified in 2.B.
- 2. B. 9. Spin-forming machines and flow-forming machines, which, according to the manufacturer's technical specification, can be equipped with "numerical control" units or a computer control and having all of the following:
 - a. Two or more controlled axes of which at least two can be coordinated simultaneously for "contouring control"; and
 - b. A roller force more than 60 kN.

Technical Note

Machines combining the function of spin-forming and flow-forming are for the purpose of 2.B.9. regarded as flow-forming machines.

2. C. MATERIALS - None

2. D. <u>SOFTWARE</u>

- 1. "Software", other than that controlled by 2.D.2., specially designed or modified for the "development", "production" or "use" of equipment controlled by 2.A. or 2.B.
- 2. "Software" for electronic devices, even when residing in an electronic device or system, enabling such devices or systems to function as a "numerical control" unit, capable of co-ordinating simultaneously more than 4 axes for "contouring control".

<u>Note1</u> 2.D.2. does not control "software" specially designed or modified for the operation of machine tools not controlled by Category 2.

<u>Note 2</u> 2.D.2. does not control "software" for items controlled by 2.B.2. See 2.D.1. for control of "software" for items controlled by 2.B.2.

2. E. <u>TECHNOLOGY</u>

- 2. E. 1. "Technology" according to the General Technology Note for the "development" of equipment or "software" controlled by 2.A., 2.B. or 2.D.
- 2. E. 2. "Technology" according to the General Technology Note for the "production" of equipment controlled by 2.A. or 2.B.
- 2. E. 3. Other "technology", as follows:
 - a. "Technology" for the "development" of interactive graphics as an integrated part in "numerical control" units for preparation or modification of part programmes;
 - b. "Technology" for metal-working manufacturing processes, as follows:
 - 1. "Technology" for the design of tools, dies or fixtures specially designed for any of the following processes:
 - a. "Superplastic forming";
 - b. "Diffusion bonding"; <u>or</u>
 - c. "Direct-acting hydraulic pressing";
- 2. E. 3. b. 2. Technical data consisting of process methods or parameters as listed below used to control:
 - a. "Superplastic forming" of aluminium alloys, titanium alloys or "superalloys":
 - 1. Surface preparation;
 - 2. Strain rate;
 - 3. Temperature;
 - 4. Pressure;

- 2. E. 3. b. 2. b. "Diffusion bonding" of "superalloys" or titanium alloys:
 - 1. Surface preparation;
 - 2. Temperature;
 - 3. Pressure;
 - c. "Direct-acting hydraulic pressing" of aluminium alloys or titanium alloys:
 - 1. Pressure;
 - 2. Cycle time;
 - d. "Hot isostatic densification" of titanium alloys, aluminium alloys or "superalloys":
 - 1. Temperature;
 - 2. Pressure;
 - 3. Cycle time;
- 2. E. 3. c. "Technology" for the "development" or "production" of hydraulic stretchforming machines and dies therefor, for the manufacture of airframe structures;
 - d. "Technology" for the "development" of generators of machine tool instructions (e.g., part programmes) from design data residing inside "numerical control" units;
 - e. "Technology" for the "development" of integration "software" for incorporation of expert systems for advanced decision support of shop floor operations into "numerical control" units;
 - f. "Technology" for the application of inorganic overlay coatings or inorganic surface modification coatings (specified in column 3 of the following table) to non-electronic substrates (specified in column 2 of the following table), by processes specified in column 1 of the following table and defined in the Technical Note.
 - <u>N.B.</u> This Table should be read to control the technology of a particular 'Coating Process' only when the 'Resultant Coating' in column 3 is in a paragraph directly across from the relevant 'Substrate' under column 2. For example, Chemical Vapour Deposition (CVD) coating process technical data are controlled for the application of 'silicides' to 'Carbon-carbon, Ceramic and Metal "matrix" "composites"' substrates, but are not controlled for the application of 'silicides' to 'Cemented tungsten carbide (16), Silicon carbide (18)' substrates. In the second case, the 'Resultant Coating' is not listed in the paragraph under column 3 directly across from the paragraph under column 2 listing 'Cemented tungsten carbide (16), Silicon carbide (18)'.

1.	<u>Coating Process</u> $(1)^*$	2.	<u>Substrate</u>	3.	Resultant Coating
A.	Chemical Vapour Deposition (CVD)		"Superalloys"		Aluminides for internal passages
			Ceramics (19) and Low- expansion glasses (14)		Silicides Carbides Dielectric layers (15) Diamond Diamond-like carbon (17)
			Carbon-carbon, Ceramic and Metal "matrix" "composites"		Silicides Carbides Refractory metals Mixtures thereof (4) Dielectric layers (15) Aluminides Alloyed aluminides (2) Boron nitride
			Cemented tungsten carbide (16), Silicon carbide (18)		Carbides Tungsten Mixtures thereof (4) Dielectric layers (15)
			Molybdenum and Molybdenum alloys		Dielectric layers (15)
			Beryllium and Beryllium alloys		Dielectric layers (15) Diamond Diamond-like carbon (17)
			Sensor window materials (9)		Dielectric layers (15) Diamond Diamond-like carbon (17)

^{*} The numbers in parenthesis refer to the Notes following this Table.

TABLE - DEPOSITION TECHNIQUES

1.	Coating Process (1)	2.	Substrate	3.	Resultant Coating
B.	Thermal-Evaporation Physical Vapour Deposition (TE-PVD)				
B.1.	Physical Vapour Deposition (PVD): Electron-Beam (EB-PVD)		"Superalloys"		Alloyed silicides Alloyed aluminides (2) MCrAlX (5) Modified zirconia (12) Silicides Aluminides Mixtures thereof (4)
			Ceramics (19) and Low- expansion glasses (14)		Dielectric layers (15)
			Corrosion resistant steel (7)		MCrAlX (5) Modified zirconia (12) Mixtures thereof (4)
			Carbon-carbon, Ceramic and Metal "matrix" "composites"		Silicides Carbides Refractory metals Mixtures thereof (4) Dielectric layers (15) Boron nitride
			Cemented tungsten carbide (16), Silicon carbide (18)		Carbides Tungsten Mixtures thereof (4) Dielectric layers (15)
			Molybdenum and Molybdenum alloys		Dielectric layers (15)
			Beryllium and Beryllium alloys		Dielectric layers (15) Borides Beryllium
			Sensor window materials (9)		Dielectric layers (15)
			Titanium alloys (13)		Borides Nitrides

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1.	Coating Process (1)	2.	Substrate	3.	Resultant Coating
B.2.	Ion assisted resistive heating Physical Vapour Deposition (PVD) (Ion Plating)		Ceramics (19) and Low- expansion glasses (14)		Dielectric layers (15) Diamond-like carbon (17)
	(Ion Flating)		Carbon-carbon, Ceramic and Metal "matrix" "composites"		Dielectric layers (15)
			Cemented tungsten carbide (16), Silicon carbide		Dielectric layers (15)
			Molybdenum and Molybdenum alloys		Dielectric layers (15)
			Beryllium and Beryllium alloys		Dielectric layers (15)
			Sensor window materials (9)		Dielectric layers (15) Diamond-like carbon (17)
B.3.	Physical Vapour Deposition (PVD): "Laser" Vaporization		Ceramics (19) and Low- expansion glasses (14)		Silicides Dielectric layers (15) Diamond-like carbon (17)
			Carbon-carbon, Ceramic and Metal "matrix" "composites"		Dielectric layers (15)
			Cemented tungsten carbide (16), Silicon carbide		Dielectric layers (15)
			Molybdenum and Molybdenum alloys		Dielectric layers (15)
			Beryllium and Beryllium alloys		Dielectric layers (15)
			Sensor window materials (9)		Dielectric layers (15) Diamond-like carbon

				-	
1.	Coating Process (1)	2.	<u>Substrate</u>	3.	Resultant Coating
B.4.	Physical Vapour Deposition (PVD): Cathodic Arc Discharge		"Superalloys"		Alloyed silicides Alloyed aluminides (2) MCrAlX (5)
			Polymers (11) and Organic "matrix" "composites"		Borides Carbides Nitrides Diamond-like carbon (17)
C.	Pack cementation (see A above for out-of-pack cementation) (10)		Carbon-carbon, Ceramic and Metal "matrix" "composites"		Silicides Carbides Mixtures thereof (4)
			Titanium alloys (13)		Silicides Aluminides Alloyed aluminides (2)
			Refractory metals and alloys (8)		Silicides Oxides
D.	Plasma spraying		"Superalloys"		MCrAlX (5) Modified zirconia (12) Mixtures thereof (4) Abradable Nickel-Graphite Abradable materials containing Ni-Cr-Al Abradable Al-Si-Polyester Alloyed aluminides (2)
			Aluminium alloys (6)		MCrAlX (5) Modified zirconia (12) Silicides Mixtures thereof (4)
			Refractory metals and alloys (8)		Aluminides Silicides Carbides

1.	Coating Process (1)	2.	Substrate	3.	Resultant Coating
D.	(continued)		Corrosion resistant steel (7)		MCrAlX (5) Modified zirconia (12) Mixtures thereof (4)
			Titanium alloys (13)		Carbides Aluminides Silicides Alloyed aluminides (2) Abradable Nickel-Graphite Abradable materials containing Ni-Cr-Al Abradable Al-Si-Polyester
E.	Slurry Deposition		Refractory metals and alloys (8)		Fused silicides Fused aluminides except for resistance heating elements
			Carbon-carbon, Ceramic and Metal "matrix" "composites"		Silicides Carbides Mixtures thereof (4)
F.	Sputter Deposition		"Superalloys"		Alloyed silicides Alloyed aluminides (2) Noble metal modified aluminides (3) MCrAlX (5) Modified zirconia (12) Platinum Mixtures thereof (4)
			Ceramics and Low- expansion glasses (14)		Silicides Platinum Mixtures thereof (4) Dielectic layers (15) Diamond-like carbon (17)

1.	Coating Process (1)	2.	Substrate	3.	Resultant Coating
F.	(continued)		Titanium alloys (13)		Borides Nitrides Oxides Silicides Aluminides Alloyed aluminides (2) Carbides
			Carbon-carbon, Ceramic and Metal "matrix" "composites"		Silicides Carbides Refractory metals Mixtures thereof (4) Dielectric layers (15) Boron nitride
			Cemented tungsten carbide (16), Silicon carbide (18)		Carbides Tungsten Mixtures thereof (4) Dielectric layers (15) Boron nitride
			Molybdenum and Molybdenum alloys		Dielectric layers (15)
			Beryllium and Beryllium alloys		Borides Dielectric layers (15) Beryllium
			Sensor window materials (9)		Dielectric layers (15) Diamond-like carbon (17)
			Refractory metals and alloys (8)		Aluminides Silicides Oxides Carbides

TABLE - DEPOSITION TECHNIQUES

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1.	Coating Process (1)	2.	<u>Substrate</u>	3.	Resultant Coating
G.	Ion Implantation		High temperature bearing steels		Additions of Chromium Tantalum or Niobium (Columbium)
			Titanium alloys (13)		Borides Nitrides
			Beryllium and Beryllium alloys		Borides
			Cemented tungsten carbide (16)		Carbides Nitrides

TABLE - DEPOSITION TECHNIQUES - NOTES

- 1. The term 'coating process' includes coating repair and refurbishing as well as original coating.
- 2. The term 'alloyed aluminide coating' includes single or multiple-step coatings in which an element or elements are deposited prior to or during application of the aluminide coating, even if these elements are deposited by another coating process. It does not, however, include the multiple use of single-step pack cementation processes to achieve alloyed aluminides.
- 3. The term 'noble metal modified aluminide' coating includes multiple-step coatings in which the noble metal or noble metals are laid down by some other coating process prior to application of the aluminide coating.
- 4. The term 'mixtures thereof' includes infiltrated material, graded compositions, co-deposits and multilayer deposits and are obtained by one or more of the coating processes specified in the Table.
- 5. 'MCrAlX' refers to a coating alloy where M equals cobalt, iron, nickel or combinations thereof and X equals hafnium, yttrium, silicon, tantalum in any amount or other intentional additions over 0.01 weight percent in various proportions and combinations, except:
 - a. CoCrAlY coatings which contain less than 22 weight percent of chromium, less than 7 weight percent of aluminium and less than 2 weight percent of yttrium;
 - b. CoCrAlY coatings which contain 22 to 24 weight percent of chromium, 10 to 12 weight percent of aluminium and 0.5 to 0.7 weight percent of yttrium; or
 - c. NiCrAlY coatings which contain 21 to 23 weight percent of chromium, 10 to 12 weight percent of aluminium and 0.9 to1.1 weight percent of yttrium.
- 6. The term 'aluminium alloys' refers to alloys having an ultimate tensile strength of 190 MPa or more measured at 293 K (20°C).
- 7. The term 'corrosion resistant steel' refers to AISI (American Iron and Steel Institute) 300 series or equivalent national standard steels.
- 8. 'Refractory metals and alloys' include the following metals and their alloys: niobium (columbium), molybdenum, tungsten and tantalum.
- 9. 'Sensor window materials', as follows: alumina, silicon, germanium, zinc sulphide, zinc selenide, gallium arsenide, diamond, gallium phosphide, sapphire and the following metal halides: sensor window materials of more than 40 mm diameter for zirconium fluoride and hafnium fluoride.

TABLE - DEPOSITION TECHNIQUES – NOTES

- 10. "Technology" for single-step pack cementation of solid airfoils is not controlled by Category 2.
- 11. 'Polymers', as follows: polyimide, polyester, polysulphide, polycarbonates and polyurethanes.
- 12. 'Modified zirconia' refers to additions of other metal oxides (e.g., calcia, magnesia, yttria, hafnia, rare earth oxides) to zirconia in order to stabilise certain crystallographic phases and phase compositions. Thermal barrier coatings made of zirconia, modified with calcia or magnesia by mixing or fusion, are not controlled.
- 13. 'Titanium alloys' refers only to aerospace alloys having an ultimate tensile strength of 900 MPa or more measured at 293 K (20°C).
- 14. 'Low-expansion glasses' refers to glasses which have a coefficient of thermal expansion of 1 x 10^{-7} K⁻¹ or less measured at 293 K (20° C).
- 15. 'Dielectric layers' are coatings constructed of multi-layers of insulator materials in which the interference properties of a design composed of materials of various refractive indices are used to reflect, transmit or absorb various wavelength bands. Dielectric layers refers to more than four dielectric layers or dielectric/metal "composite" layers.
- 16. 'Cemented tungsten carbide' does not include cutting and forming tool materials consisting of tungsten carbide/(cobalt, nickel), titanium carbide/(cobalt, nickel), chromium carbide/nickel-chromium and chromium carbide/nickel.
- 17. "Technology" specially designed to deposit diamond-like carbon on any of the following is not controlled: magnetic disk drives and heads, equipment for the manufacture of disposables, valves for faucets, acoustic diaphragms for speakers, engine parts for automobiles, cutting tools, punching-pressing dies, office automation equipment, microphones, medical devices or moulds, for casting or moulding of plastics, manufactured from alloys containing less than 5% beryllium.
- 18. 'Silicon carbide' does not include cutting and forming tool materials.
- 19. Ceramic substrates, as used in this entry, does not include ceramic materials containing 5% by weight, or greater, clay or cement content, either as separate constituents or in combination.

TABLE - DEPOSITION TECHNIQUES - TECHNICAL NOTE

Processes specified in Column 1 of the Table are defined as follows:

- a. Chemical Vapour Deposition (CVD) is an overlay coating or surface modification coating process wherein a metal, alloy, "composite", dielectric or ceramic is deposited upon a heated substrate. Gaseous reactants are decomposed or combined in the vicinity of a substrate resulting in the deposition of the desired elemental, alloy or compound material on the substrate. Energy for this decomposition or chemical reaction process may be provided by the heat of the substrate, a glow discharge plasma, or "laser" irradiation.
 - <u>N.B.1</u> CVD includes the following processes: directed gas flow out-of-pack deposition, pulsating CVD, controlled nucleation thermal deposition (CNTD), plasma enhanced or plasma assisted CVD processes.
 - <u>N.B.2</u> Pack denotes a substrate immersed in a powder mixture.
 - <u>N.B.3</u> The gaseous reactants used in the out-of-pack process are produced using the same basic reactions and parameters as the pack cementation process, except that the substrate to be coated is not in contact with the powder mixture.
- b. Thermal Evaporation-Physical Vapour Deposition (TE-PVD) is an overlay coating process conducted in a vacuum with a pressure less than 0.1 Pa wherein a source of thermal energy is used to vaporize the coating material. This process results in the condensation, or deposition, of the evaporated species onto appropriately positioned substrates.

The addition of gases to the vacuum chamber during the coating process to synthesize compound coatings is an ordinary modification of the process.

The use of ion or electron beams, or plasma, to activate or assist the coating's deposition is also a common modification in this technique. The use of monitors to provide in-process measurement of optical characteristics and thickness of coatings can be a feature of these processes.

Specific TE-PVD processes are as follows:

- 1. Electron Beam PVD uses an electron beam to heat and evaporate the material which forms the coating;
- 2. Ion Assisted Resistive Heating PVD employs electrically resistive heating sources in combination with impinging ion beam(s) to produce a controlled and uniform flux of evaporated coating species;
- 3. "Laser" Vaporization uses either pulsed or continuous wave "laser" beams to vaporize the material which forms the coating;

TABLE - DEPOSITION TECHNIQUES - TECHNICAL NOTE

Processes specified in Column 1 of the Table - continued:

- b. 4. Cathodic Arc Deposition employs a consumable cathode of the material which forms the coating and has an arc discharge established on the surface by a momentary contact of a ground trigger. Controlled motion of arcing erodes the cathode surface creating a highly ionized plasma. The anode can be either a cone attached to the periphery of the cathode, through an insulator, or the chamber. Substrate biasing is used for non line-of-sight deposition.
 - <u>N.B.</u> This definition does not include random cathodic arc deposition with non-biased substrates.
 - 5. Ion Plating is a special modification of a general TE-PVD process in which a plasma or an ion source is used to ionize the species to be deposited, and a negative bias is applied to the substrate in order to facilitate the extraction of the species from the plasma. The introduction of reactive species, evaporation of solids within the process chamber, and the use of monitors to provide in-process measurement of optical characteristics and thicknesses of coatings are ordinary modifications of the process.
- c. Pack Cementation is a surface modification coating or overlay coating process wherein a substrate is immersed in a powder mixture (a pack), that consists of:
 - 1. The metallic powders that are to be deposited (usually aluminium, chromium, silicon or combinations thereof);
 - 2. An activator (normally a halide salt); and
 - 3. An inert powder, most frequently alumina.

The substrate and powder mixture is contained within a retort which is heated to between 1,030 K (757°C) and 1,375 K (1,102°C) for sufficient time to deposit the coating.

- d. Plasma Spraying is an overlay coating process wherein a gun (spray torch) which produces and controls a plasma accepts powder or wire coating materials, melts them and propels them towards a substrate, whereon an integrally bonded coating is formed. Plasma spraying constitutes either low pressure plasma spraying or high velocity plasma spraying.
 - <u>N.B.1</u> Low pressure means less than ambient atmospheric pressure.
 - <u>N.B.2</u> High velocity refers to nozzle-exit gas velocity exceeding 750 m/s calculated at 293 K (20°C) at 0.1 MPa.

TABLE - DEPOSITION TECHNIQUES - TECHNICAL NOTE

Processes specified in Column 1 of the Table - continued:

- e. Slurry Deposition is a surface modification coating or overlay coating process wherein a metallic or ceramic powder with an organic binder is suspended in a liquid and is applied to a substrate by either spraying, dipping or painting, subsequent air or oven drying, and heat treatment to obtain the desired coating.
- f. Sputter Deposition is an overlay coating process based on a momentum transfer phenomenon, wherein positive ions are accelerated by an electric field towards the surface of a target (coating material). The kinetic energy of the impacting ions is sufficient to cause target surface atoms to be released and deposited on an appropriately positioned substrate.
 - <u>N.B.1</u> The Table refers only to triode, magnetron or reactive sputter deposition which is used to increase adhesion of the coating and rate of deposition and to radio frequency (RF) augmented sputter deposition used to permit vaporisation of non-metallic coating materials.
 - <u>N.B.2</u> Low-energy ion beams (less than 5 keV) can be used to activate the deposition.
- g. Ion Implantation is a surface modification coating process in which the element to be alloyed is ionized, accelerated through a potential gradient and implanted into the surface region of the substrate. This includes processes in which ion implantation is performed simultaneously with electron beam physical vapour deposition or sputter deposition.

TABLE - DEPOSITION TECHNIQUES - STATEMENT OF UNDERSTANDING

It is understood that the following technical information, accompanying the table of deposition techniques, is for use as appropriate.

- 1. "Technology" for pretreatments of the substrates listed in the Table, as follows:
 - a. Chemical stripping and cleaning bath cycle parameters, as follows:
 - 1. Bath composition
 - a. For the removal of old or defective coatings, corrosion product or foreign deposits;
 - b. For preparation of virgin substrates;
 - 2. Time in bath;
 - 3. Temperature of bath;
 - 4. Number and sequences of wash cycles;
 - b. Visual and macroscopic criteria for acceptance of the cleaned part;
 - c. Heat treatment cycle parameters, as follows:
 - 1. Atmosphere parameters, as follows:
 - a. Composition of the atmosphere;
 - b. Pressure of the atmosphere;
 - 2. Temperature for heat treatment;
 - 3. Time of heat treatment;
 - d. Substrate surface preparation parameters, as follows:
 - 1. Grit blasting parameters, as follows:
 - a. Grit composition;
 - b. Grit size and shape;
 - c. Grit velocity;
 - 2. Time and sequence of cleaning cycle after grit blast;
 - 3. Surface finish parameters;
 - 4. Application of binders to promote adhesion;
 - e. Masking technique parameters, as follows:
 - 1. Material of mask;
 - 2. Location of mask;
- 2. "Technology" for in situ quality assurance techniques for evaluation of the coating processes listed in the Table, as follows:
 - a. Atmosphere parameters, as follows:
 - 1. Composition of the atmosphere;
 - 2. Pressure of the atmosphere;
 - b. Time parameters;
 - c. Temperature parameters;
 - d. Thickness parameters;
 - e. Index of refraction parameters;
 - f. Control of composition;
- 3. "Technology" for post deposition treatments of the coated substrates listed in the Table, as follows:
 - a. Shot peening parameters, as follows:
 - 1. Shot composition;
 - 2. Shot size;
 - 3. Shot velocity;

TABLE - DEPOSITION TECHNIQUES - STATEMENT OF UNDERSTANDING

- 3. b. Post shot peening cleaning parameters;
 - c. Heat treatment cycle parameters, as follows:
 - 1. Atmosphere parameters, as follows:
 - a. Composition of the atmosphere;
 - b. Pressure of the atmosphere;
 - 2. Time-temperature cycles;
 - d. Post heat treatment visual and macroscopic criteria for acceptance of the coated substrates;
- 4. "Technology" for quality assurance techniques for the evaluation of the coated substrates listed in the Table, as follows:
 - a. Statistical sampling criteria;
 - b. Microscopic criteria for:
 - 1. Magnification;
 - 2. Coating thickness uniformity;
 - 3. Coating integrity;
 - 4. Coating composition;
 - 5. Coating and substrates bonding;
 - 6. Microstructural uniformity;
 - c. Criteria for optical properties assessment (measured as a function of wavelength):
 - 1. Reflectance;
 - 2. Transmission;
 - 3. Absorption;
 - 4. Scatter;
- 5. "Technology" and parameters related to specific coating and surface modification processes listed in the Table, as follows:
 - a. For Chemical Vapour Deposition (CVD):
 - 1. Coating source composition and formulation;
 - 2. Carrier gas composition;
 - 3. Substrate temperature;
 - 4. Time-temperature-pressure cycles;
 - 5. Gas control and part manipulation;
 - b. For Thermal Evaporation Physical Vapour Deposition (PVD):
 - 1. Ingot or coating material source composition;
 - 2. Substrate temperature;
 - 3. Reactive gas composition;
 - 4. Ingot feed rate or material vaporisation rate;
 - 5. Time-temperature-pressure cycles;
 - 6. Beam and part manipulation;
 - 7. "Laser" parameters, as follows:
 - a. Wave length;
 - b. Power density;
 - c. Pulse length;
 - d. Repetition ratio;
 - e. Source;

TABLE - DEPOSITION TECHNIQUES - STATEMENT OF UNDERSTANDING

- 5. c. For Pack Cementation:
 - 1. Pack composition and formulation;
 - 2. Carrier gas composition;
 - 3. Time-temperature-pressure cycles;
 - d. For Plasma Spraying:
 - 1. Powder composition, preparation and size distributions;
 - 2. Feed gas composition and parameters;
 - 3. Substrate temperature;
 - 4. Gun power parameters;
 - 5. Spray distance;
 - 6. Spray angle;
 - 7. Cover gas composition, pressure and flow rates;
 - 8. Gun control and part manipulation;
 - e. For Sputter Deposition:
 - 1. Target composition and fabrication;
 - 2. Geometrical positioning of part and target;
 - 3. Reactive gas composition;
 - 4. Electrical bias;
 - 5. Time-temperature-pressure cycles;
 - 6. Triode power;
 - 7. Part manipulation;
 - f. For Ion Implantation:
 - 1. Beam control and part manipulation;
 - 2. Ion source design details;
 - 3. Control techniques for ion beam and deposition rate parameters;
 - 4. Time-temperature-pressure cycles;
 - g. For Ion Plating:
 - 1. Beam control and part manipulation;
 - 2. Ion source design details;
 - 3. Control techniques for ion beam and deposition rate parameters;
 - 4. Time-temperature-pressure cycles;
 - 5. Coating material feed rate and vaporisation rate;
 - 6. Substrate temperature;
 - 7. Substrate bias parameters.

3. A. SYSTEMS, EQUIPMENT AND COMPONENTS

- <u>Note 1</u> The control status of equipment and components described in 3.A., other than those described in 3.A.1.a.3. to 3.A.1.a.10. or 3.A.1.a.12., which are specially designed for or which have the same functional characteristics as other equipment is determined by the control status of the other equipment.
- <u>Note 2</u> The control status of integrated circuits described in 3.A.1.a.3. to 3.A.1.a.9. or 3.A.1.a.12. which are unalterably programmed or designed for a specific function for another equipment is determined by the control status of the other equipment.
 - <u>N.B.</u> When the manufacturer or applicant cannot determine the control status of the other equipment, the control status of the integrated circuits is determined in 3.A.1.a.3. to 3.A.1.a.9. and 3.A.1.a.12. If the integrated circuit is a silicon-based "microcomputer microcircuit" or microcontroller microcircuit described in 3.A.1.a.3. having an operand (data) word length of 8 bit or less, the control status of the integrated circuit is determined in 3.A.1.a.3.
- 3. A. 1. Electronic components, as follows:
 - a. General purpose integrated circuits, as follows:
 - <u>Note 1</u> The control status of wafers (finished or unfinished), in which the function has been determined, is to be evaluated against the parameters of 3.A.1.a.
 - <u>Note 2</u> Integrated circuits include the following types: "Monolithic integrated circuits"; "Hybrid integrated circuits"; "Multichip integrated circuits"; "Film type integrated circuits", including silicon-on-sapphire integrated circuits; "Optical integrated circuits".
- 3. A. 1. a. 1. Integrated circuits, designed or rated as radiation hardened to withstand any of the following:
 - a. A total dose of 5 x 10³ Gy (Si) or higher;
 - b. A dose rate upset of 5 x 10^6 Gy (Si)/s or higher; or
 - c. A fluence (integrated flux) of neutrons (1 MeV equivalent) of $5 \times 10^{13} \text{ n/cm}^2$ or higher on silicon, or its equivalent for other materials;
 - <u>Note</u> 3.A.1.a.1.c. does not apply to Metal Insulator Semiconductors (MIS).

- 3. A. 1. a. 2. "Microprocessor microcircuits", "microcomputer microcircuits", microcontroller microcircuits, storage integrated circuits manufactured from a compound semiconductor, analogue-to-digital converters, digital-to-analogue converters, electro-optical or "optical integrated circuits" designed for "signal processing", field programmable logic devices, neural network integrated circuits, custom integrated circuits for which either the function is unknown or the control status of the equipment in which the integrated circuit will be used is unknown, Fast Fourier Transform (FFT) processors, electrical erasable programmable read-only memories (EEPROMs), flash memories or static random-access memories (SRAMs), having any of the following:
 - a. Rated for operation at an ambient temperature above 398 K (+125°C);
 - b. Rated for operation at an ambient temperature below 218 K (-55°C); or
 - c. Rated for operation over the entire ambient temperature range from 218 K (-55°C) to 398 K (+125°C);
 - <u>Note</u> 3.A.1.a.2. does not apply to integrated circuits for civil automobile or railway train applications.
- 3. A. 1. a. 3. "Microprocessor microcircuits", "micro-computer microcircuits" and microcontroller microcircuits, manufactured from a compound semiconductor and operating at a clock frequency exceeding 40 MHz; <u>Note</u> 3.A.1.a.3. includes digital signal processors, digital array processors and digital coprocessors.
- 3. A. 1. a. 4. Storage integrated circuits manufactured from a compound semiconductor;

- 3. A. 1. a. 5. Analogue-to-digital and digital-to-analogue converter integrated circuits, as follows:
 - a. Analogue-to-digital converters having any of the following:
 - 1. A resolution of 8 bit or more, but less than 10 bit, with an output rate greater than 500 million words per second;
 - 2. A resolution of 10 bit or more, but less than 12 bit, with an output rate greater than 200 million words per second;
 - 3. A resolution of 12 bit with an output rate greater than 50 million words per second;
 - 4. A resolution of more than 12 bit but equal to or less than 14 bit with an output rate greater than 5 million words per second; or
 - 5. A resolution of more than 14 bit with an output rate greater than 1 million words per second.
 - b. Digital-to-analogue converters with a resolution of 12 bit or more, and a "settling time" of less than 10 ns;

Technical Notes

- 1. A resolution of n bit corresponds to a quantisation of 2^n levels.
- 2. The number of bits in the output word is equal to the resolution of the analogue-to-digital converter.
- 3. The output rate is the maximum output rate of the converter, regardless of architecture or oversampling. Vendors may also refer to the output rate as sampling rate, conversion rate or throughput rate. It is often specified in megahertz (MHz) or mega samples per second (MSPS).
- 4. For the purpose of measuring output rate, one output word per second is equivalent to one Hertz or one sample per second.
- 3. A. 1. a. 6. Electro-optical and "optical integrated circuits" designed for "signal processing" having all of the following:
 - a. One or more than one internal "laser" diode;
 - b. One or more than one internal light detecting element; and
 - c. Optical waveguides;
- 3. A. 1. a. 7. Field programmable logic devices having any of the following:
 - a. An equivalent usable gate count of more than 30,000 (2 input gates);
 - b. A typical "basic gate propagation delay time" of less than 0.1 ns; or
 - c. A toggle frequency exceeding 133 MHz;
 - <u>Note</u> 3.A.1.a.7.includes:
 - Simple Programmable Logic Devices (SPLDs)
 - Complex Programmable Logic Devices (CPLDs)
 - Field Programmable Gate Arrays (FPGAs)
 - Field Programmable Logic Arrays (FPLAs)
 - Field Programmable Interconnects (FPICs)
 - <u>N.B.</u> Field programmable logic devices are also known as field programmable gate or field programmable logic arrays.

- 3. A. 1. a. 8. Deleted
- 3. A. 1. a. 9. Neural network integrated circuits;
- 3. A. 1. a. 10. Custom integrated circuits for which the function is unknown, or the control status of the equipment in which the integrated circuits will be used is unknown to the manufacturer, having any of the following:
 - a. More than 1,000 terminals;
 - b. A typical "basic gate propagation delay time" of less than 0.1 ns; or
 - c. An operating frequency exceeding 3 GHz;
- 3. A. 1. a. 11. Digital integrated circuits, other than those described in 3.A.1.a.3 to 3.A.1.a.10. and 3.A.1.a.12., based upon any compound semiconductor and having any of the following:
 - a. An equivalent gate count of more than 3000 (2 input gates); or
 - b. A toggle frequency exceeding 1.2 GHz;
- 3. A. 1. a. 12. Fast Fourier Transform (FFT) processors having a rated execution time for an N-point complex FFT of less than (N log₂ N)/20,480 ms, where N is the number of points; <u>Technical Note</u> When N is equal to 1,024 points, the formula in 3.A.1.a.12. gives an execution time of 500 μs.
- 3. A. 1. b. Microwave or millimetre wave components, as follows:
 - 1. Electronic vacuum tubes and cathodes, as follows:
 - <u>Note 1</u> 3.A.1.b.1. does not control tubes designed or rated for operation in any frequency band which meets all of the following characteristics:
 - a. Does not exceed 31.8 GHz; and
 - b. Is "allocated by the ITU" for radio-communications services, but not for radio-determination.
 - <u>Note 2</u> 3.A.1.b.1. does not control non-"space-qualified" tubes which meet all of the following characteristics:
 - *a.* An average output power equal to or less than 50 W; <u>and</u>
 - b. Designed or rated for operation in any frequency band which meets all of the following characteristics:
 - 1. Exceeds 31.8 GHz but does not exceed 43.5 GHz; and
 - 2. Is "allocated by the ITU" for radio-communications services, but not for radio-determination;

- 3. A. 1. b. 1. a. Travelling wave tubes, pulsed or continuous wave, as follows:
 - 1. Operating at frequencies exceeding 31.8 GHz;
 - 2. Having a cathode heater element with a turn on time to rated RF power of less than 3 seconds;
 - 3. Coupled cavity tubes, or derivatives thereof, with a "fractional bandwidth" of more than 7% or a peak power exceeding 2.5 kW;
 - 4. Helix tubes, or derivatives thereof, with any of the following characteristics:
 - a. An "instantaneous bandwidth" of more than one octave, and average power (expressed in kW) times frequency (expressed in GHz) of more than 0.5;
 - b. An "instantaneous bandwidth" of one octave or less, and average power (expressed in kW) times frequency (expressed in GHz) of more than 1; or
 - c. Being "space qualified";
 - b. Crossed-field amplifier tubes with a gain of more than 17 dB;
 - c. Impregnated cathodes designed for electronic tubes producing a continuous emission current density at rated operating conditions exceeding 5 A/cm²;
- 3. A. 1. b. 2. Microwave monolithic integrated circuits (MMIC) power amplifiers having any of the following:
 - Rated for operation at frequencies exceeding 3.2 GHz up to and including 6 GHz and with an average output power greater than 4W (36 dBm) with a "fractional bandwidth" greater than 15%;
 - B. Rated for operation at frequencies exceeding 6 GHz up to and including 16 GHz and with an average output power greater than 1W (30 dBm) with a "fractional bandwidth" greater than 10%;
 - c. Rated for operation at frequencies exceeding 16 GHz up to and including 31.8 GHz and with an average output power greater than 0.8W (29 dBm) with a "fractional bandwidth" greater than 10%;
 - d. Rated for operation at frequencies exceeding 31.8 GHz up to and including 37.5 GHz;
 - e. Rated for operation at frequencies exceeding 37.5 GHz up to and including 43.5 GHz and with an average output power greater than 0.25W (24 dBm) with a "fractional bandwidth" greater than 10%; or
 - f. Rated for operation at frequencies exceeding 43.5 GHz.
 - <u>Note 1</u> 3.A.1.b.2. does not control broadcast satellite equipment designed or rated to operate in the frequency range of 40.5 to 42.5 GHz.
 - <u>Note 2</u> The control status of the MMIC whose rated operating frequency includes frequencies listed in more than one frequency range, as defined by 3.A.1.b.2.a. through 3.A.1.b.2.f., is determined by the lowest average output power control threshold.
 - <u>Note 3</u> Notes 1 and 2 in the chapeau to Category 3 mean that 3.A.1.b.2. does not control MMICs if they are specially designed for other applications, e.g., telecommunications, radar, automobiles.

- 3. A. 1. b. 3. Discrete microwave transistors having any of the following:
 - a. Rated for operation at frequencies exceeding 3.2 GHz up to and including 6 GHz and having an average output power greater than 60W (47.8 dBm);
 - b. Rated for operation at frequencies exceeding 6 GHz up to and including 31.8 GHz and having an average output power greater than 20W (43 dBm);
 - c. Rated for operation at frequencies exceeding 31.8 GHz up to and including 37.5 GHz and having an average output power greater than 0.5W (27 dBm);
 - d. Rated for operation at frequencies exceeding 37.5 GHz up to and including 43.5 GHz and having an average output power greater than 1W (30 dBm); or
 - e. Rated for operation at frequencies exceeding 43.5 GHz.
 - <u>Note</u> The control status of a transistor whose rated operating frequency includes frequencies listed in more than one frequency range, as defined by 3.A.1.b.3.a. through 3.A.1.b.3.e., is determined by the lowest average output power control threshold.
- 3. A. 1. b. 4. Microwave solid state amplifiers and microwave assemblies/modules containing microwave amplifiers having any of the following:
 - a. Rated for operation at frequencies exceeding 3.2 GHz up to and including 6 GHz and with an average output power greater than 60W (47.8 dBm) with a "fractional bandwidth" greater than 15%;
 - b. Rated for operation at frequencies exceeding 6 GHz up to and including 31.8 GHz and with an average output power greater than 15W (42 dBm) with a "fractional bandwidth" greater than 10%;
 - c. Rated for operation at frequencies exceeding 31.8 GHz up to and including 37.5 GHz;
 - Rated for operation at frequencies exceeding 37.5 GHz up to and including 43.5 GHz and with an average output power greater than 1W (30 dBm) with a "fractional bandwidth" greater than 10%;
 - e. Rated for operation at frequencies exceeding 43.5 GHz; or
 - f. Rated for operation at frequencies above 3.2 GHz and having all of the following:
 - 1. An average output power (in watts), P, greater than 150 divided by the maximum operating frequency (in GHz) squared [P>150 W*GHz²/f_{GHz}²];
 - 2. A fractional bandwidth of 5% or greater; and
 - 3. Any two sides perpendicular to one another with length d (in cm) equal to or less than 15 divided by the lowest operating frequency in GHz [d \leq 15cm*GHz/ f_{GHz}].

Technical Note

3.2 GHz should be used as the lowest operating frequency (f_{GHz}) in the formula in 3.A.1.b.4.f.3., for amplifiers that have a rated operation range extending downward to 3.2 GHz and below $[d \le 15 \text{ cm}^*\text{GHz}/3.2 \text{ GHz}]$.

- <u>N.B.</u> *MMIC* power amplifiers should be evaluated against the criteria in 3.A.1.b.2.
- <u>Note 1</u> 3.A.1.b.4. does not control broadcast satellite equipment designed or rated to operate in the frequency range of 40.5 to 42.5 GHz.
- <u>Note 2</u> The control status of an item whose rated operating frequency includes frequencies listed in more than one frequency range, as defined by 3.A.1.b.4.a. through 3.A.1.b.4.e., is determined by the lowest average output power control threshold.
- 3. A. 1. b. 5. Electronically or magnetically tunable band-pass or band-stop filters having more than 5 tunable resonators capable of tuning across a 1.5:1 frequency band (f_{max}/f_{min}) in less than 10 µs having any of the following:
 - a. A band-pass bandwidth of more than 0.5% of centre frequency; or
 - b. A band-stop bandwidth of less than 0.5% of centre frequency;
- 3. A. 1. b. 6. Deleted
 - 7. Mixers and converters designed to extend the frequency range of equipment described in 3.A.2.c., 3.A.2.e. or 3.A.2.f. beyond the limits stated therein;
 - 8. Microwave power amplifiers containing tubes controlled by 3.A.1.b. and having all of the following:
 - a. Operating frequencies above 3 GHz;
 - b. An average output power density exceeding 80 W/kg; and
 - c. A volume of less than 400 cm³;
 - <u>Note</u> 3.A.1.b.8. does not control equipment designed or rated for operation in any frequency band which is "allocated by the ITU" for radio-communications services, but not for radio-determination.
- 3. A. 1. c. Acoustic wave devices, as follows, and specially designed components therefor:
 - 1. Surface acoustic wave and surface skimming (shallow bulk) acoustic wave devices (i.e., "signal processing" devices employing elastic waves in materials), having any of the following:
 - a. A carrier frequency exceeding 2.5 GHz;

- 3. A. 1. c. 1. b. A carrier frequency exceeding 1 GHz, but not exceeding 2.5 GHz, and having any of the following:
 - 1. A frequency side-lobe rejection exceeding 55 dB;
 - 2. A product of the maximum delay time and the bandwidth (time in μ s and bandwidth in MHz) of more than 100;
 - 3. A bandwidth greater than 250 MHz; or
 - 4. A dispersive delay of more than 10 μ s; or
 - c. A carrier frequency of 1 GHz or less, having any of the following:
 - 1. A product of the maximum delay time and the bandwidth (time in μ s and bandwidth in MHz) of more than 100;
 - 2. A dispersive delay of more than $10 \ \mu s$; or
 - 3. A frequency side-lobe rejection exceeding 55 dB and a bandwidth greater than 50 MHz;
- 3. A. 1. c. 2. Bulk (volume) acoustic wave devices (i.e., "signal processing" devices employing elastic waves) which permit the direct processing of signals at frequencies exceeding 1 GHz;
 - 3. Acoustic-optic "signal processing" devices employing interaction between acoustic waves (bulk wave or surface wave) and light waves which permit the direct processing of signals or images, including spectral analysis, correlation or convolution;
- A. 1. d. Electronic devices and circuits containing components, manufactured from "superconductive" materials specially designed for operation at temperatures below the "critical temperature" of at least one of the "superconductive" constituents, with any of the following:
 - 1. Current switching for digital circuits using "superconductive" gates with a product of delay time per gate (in seconds) and power dissipation per gate (in watts) of less than 10^{-14} J; or
 - 2. Frequency selection at all frequencies using resonant circuits with Q-values exceeding 10,000;
- 3. A. 1. e. High energy devices, as follows:
 - 1. Batteries and photovoltaic arrays, as follows:
 - <u>Note</u> 3.A.1.e.1. does not control batteries with volumes equal to or less than 27 cm^3 (e.g., standard C-cells or R14 batteries).
 - a. Primary cells and batteries having an energy density exceeding 480 Wh/kg and rated for operation in the temperature range from below 243 K (-30°C) to above 343 K (70°C);
 - b. Rechargeable cells and batteries having an energy density exceeding 150 Wh/kg after 75 charge/discharge cycles at a discharge current equal to C/5 hours (C being the nominal capacity in ampere hours) when operating in the temperature range from below 253 K (-20°C) to above 333 K (60°C);

Technical Note

Energy density is obtained by multiplying the average power in watts (average voltage in volts times average current in amperes) by the duration of the discharge in hours to 75% of the open circuit voltage divided by the total mass of the cell (or battery) in kg.

- 3. A. 1. e. 1. c. "Space qualified" and radiation hardened photovoltaic arrays with a specific power exceeding 160 W/m² at an operating temperature of 301 K (28°C) under a tungsten illumination of 1 kW/m² at 2,800 K (2,527°C);
 - 2. High energy storage capacitors, as follows:
 - a. Capacitors with a repetition rate of less than 10 Hz (single shot capacitors) having all of the following:
 - 1. A voltage rating equal to or more than 5 kV;
 - 2. An energy density equal to or more than 250 J/kg; and
 - 3. A total energy equal to or more than 25 kJ;
 - b. Capacitors with a repetition rate of 10 Hz or more (repetition rated capacitors) having all of the following:
 - 1. A voltage rating equal to or more than 5 kV;
 - 2. An energy density equal to or more than 50 J/kg;
 - 3. A total energy equal to or more than 100 J; and
 - 4. A charge/discharge cycle life equal to or more than 10,000;
- 3. A. 1. e. 3. "Superconductive" electromagnets and solenoids specially designed to be fully charged or discharged in less than one second, having all of the following:
 - <u>Note</u> 3.A.1.e.3. does not control "superconductive" electromagnets or solenoids specially designed for Magnetic Resonance Imaging (MRI) medical equipment.
 - a. Energy delivered during the discharge exceeding 10 kJ in the first second;
 - b. Inner diameter of the current carrying windings of more than 250 mm; and
 - c. Rated for a magnetic induction of more than 8 T or "overall current density" in the winding of more than 300 A/mm²;
- 3. A. 1. f. Rotary input type shaft absolute position encoders having any of the following:
 - 1. A resolution of better than 1 part in 265,000 (18 bit resolution) of full scale; or
 - 2. An accuracy better than ± 2.5 seconds of arc.
- 3. A. 2. General purpose electronic equipment, as follows:
 - a. Recording equipment, as follows, and specially designed test tape therefor:
 - 1. Analogue instrumentation magnetic tape recorders, including those permitting the recording of digital signals (e.g., using a high density digital recording (HDDR) module), having any of the following:

- 3. A. 2. a. 1. a. A bandwidth exceeding 4 MHz per electronic channel or track;
 - b. A bandwidth exceeding 2 MHz per electronic channel or track and having more than 42 tracks; or
 - c. A time displacement (base) error, measured in accordance with applicable IRIG or EIA documents, of less than $\pm 0.1 \ \mu s$;
 - <u>Note</u> Analogue magnetic tape recorders specially designed for civilian video purposes are not considered to be instrumentation tape recorders.
 - 2. Digital video magnetic tape recorders having a maximum digital interface transfer rate exceeding 360 Mbit/s;
 - <u>Note</u> 3.A.2.a.2. does not control digital video magnetic tape recorders specially designed for television recording using a signal format, which may include a compressed signal format, standardised or recommended by the ITU, the IEC, the SMPTE, the EBU, the ETSI or the IEEE for civil television applications.
- 3. A. 2. a. 3. Digital instrumentation magnetic tape data recorders employing helical scan techniques or fixed head techniques, having any of the following:
 - a. A maximum digital interface transfer rate exceeding 175 Mbit/s; or
 - b. Being "space qualified";
 - <u>Note</u> 3.A.2.a.3 does not control analogue magnetic tape recorders equipped with HDDR conversion electronics and configured to record only digital data.
 - 4. Equipment, having a maximum digital interface transfer rate exceeding 175 Mbit/s, designed to convert digital video magnetic tape recorders for use as digital instrumentation data recorders;
 - 5. Waveform digitisers and transient recorders having all of the following:
 - a. Digitising rates equal to or more than 200 million samples per second and a resolution of 10 bits or more; and
 - b. A continuous throughput of 2 Gbit/s or more;

<u>Technical Note</u>

For those instruments with a parallel bus architecture, the continuous throughput rate is the highest word rate multiplied by the number of bits in a word.

Continuous throughput is the fastest data rate the instrument can output to mass storage without the loss of any information whilst sustaining the sampling rate and analogue-to-digital conversion.

- 6. Digital instrumentation data recorders, using magnetic disk storage technique, having all of the following:
 - a. Digitizing rate equal to or more than 100 million samples per second and a resolution of 8 bit or more; and
 - b. A continuous throughput of 1 Gbit/s or more;

- 3. A. 2. b. "Frequency synthesiser" "electronic assemblies" having a "frequency switching time" from one selected frequency to another of less than 1 ms;
 - c. Radio frequency "signal analysers", as follows:
 - 1. "Signal analysers" capable of analysing any frequencies exceeding 31.8 GHz but not exceeding 37.5 GHz and having a 3 dB resolution bandwidth (RBW) exceeding 10 MHz;
 - 2. "Signal analysers" capable of analyzing frequencies exceeding 43.5 GHz;
 - 3. "Dynamic signal analysers" having a "real-time bandwidth" exceeding 500 kHz;

- 3. A. 2. d. Frequency synthesised signal generators producing output frequencies, the accuracy and short term and long term stability of which are controlled, derived from or disciplined by the internal master frequency, and having any of the following:
 - 1. A maximum synthesised frequency exceeding 31.8 GHz but not exceeding 43.5 GHz and rated to generate a pulse duration of less than 100 ns;
 - 2. A maximum synthesised frequency exceeding 43.5 GHz;
 - 3. A "frequency switching time" from one selected frequency to another of less than 1 ms; or
 - 4. A single sideband (SSB) phase noise better than $-(126 + 20 \log_{10}F 20 \log_{10}f)$ in dBc/Hz, where F is the off-set from the operating frequency in Hz and f is the operating frequency in MHz;

Technical Note

For the purposes of 3.A.2.d.1., 'pulse duration' is defined as the time interval between the leading edge of the pulse achieving 90% of the peak and the trailing edge of the pulse achieving 10% of the peak.

- <u>Note</u> 3.A.2.d. does not control equipment in which the output frequency is either produced by the addition or subtraction of two or more crystal oscillator frequencies, or by an addition or subtraction followed by a multiplication of the result.
- 3. A. 2. e. Network analysers with a maximum operating frequency exceeding 43.5 GHz;
 - f. Microwave test receivers having all of the following:
 - 1. A maximum operating frequency exceeding 43.5 GHz; and
 - 2. Being capable of measuring amplitude and phase simultaneously;

3. A. 2. g. Atomic frequency standards having any of the following:

- 1. Long-term stability (aging) less (better) than $1 \ge 10^{-11}$ /month; or
- 2. Being "space qualified".
- <u>Note</u> 3.A.2.g.1. does not control non-"space qualified" rubidium standards.

<u>Note</u> 3.A.2.c.3. does not control those "dynamic signal analysers" using only constant percentage bandwidth filters (also known as octave or fractional octave filters).

3. A. 3. Spray cooling thermal management systems employing closed loop fluid handling and reconditioning equipment in a sealed enclosure where a dielectric fluid is sprayed onto electronic components using specially designed spray nozzles that are designed to maintain electronic components within their operating temperature range, and specially designed components therefor.

3. B. TEST, INSPECTION AND PRODUCTION EQUIPMENT

- 3. B. 1. Equipment for the manufacturing of semiconductor devices or materials, as follows, and specially designed components and accessories therefor:
 - a. Equipment designed for epitaxial growth, as follows:
 - 1. Equipment capable of producing a layer of any material other than silicon with a thickness uniform to less than $\pm 2.5\%$ across a distance of 75 mm or more;
 - 2. Metal organic chemical vapour deposition (MOCVD) reactors specially designed for compound semiconductor crystal growth by the chemical reaction between materials controlled by 3.C.3 or 3.C.4.;
 - 3. Molecular beam epitaxial growth equipment using gas or solid sources;
 - b. Equipment designed for ion implantation, having any of the following:
 - 1. A beam energy (accelerating voltage) exceeding 1 MeV;
 - 2. Being specially designed and optimised to operate at a beam energy (accelerating voltage) of less than 2 keV;
 - 3. Direct write capability; or
 - 4. A beam energy of 65 keV or more and a beam current of 45 mA or more for high energy oxygen implant into a heated semiconductor material "substrate";
 - c. Anisotropic plasma dry etching equipment, as follows:
 - 1. Equipment with cassette-to-cassette operation and load-locks, and having any of the following:
 - a. Designed or optimised to produce critical dimensions of 180 nm or less with $\pm 5\%$ 3 sigma precision; or
 - b. Designed for generating less than 0.04 particles/cm² with a measurable particle size greater than $0.1 \ \mu m$ in diameter;
 - 2. Equipment specially designed for equipment controlled by 3.B.1.e. and having any of the following:
 - a. Designed or optimised to produce critical dimensions of 180 nm or less with $\pm 5\%$ 3 sigma precision; or
 - b. Designed for generating less than 0.04 particles/cm² with a measurable particle size greater than $0.1 \,\mu\text{m}$ in diameter;
 - d. Plasma enhanced CVD equipment, as follows:
 - 1. Equipment with cassette-to-cassette operation and load-locks, and designed according to the manufacturer's specifications or optimised for use in the production of semiconductor devices with critical dimensions of 180 nm or less;

- 3. B. 1. d. 2. Equipment specially designed for equipment controlled by 3.B.1.e. and designed according to the manufacturer's specifications or optimised for use in the production of semiconductor devices with critical dimensions of 180 nm or less;
- 3. B. 1. e. Automatic loading multi-chamber central wafer handling systems, having all of the following:
 - 1. Interfaces for wafer input and output, to which more than two pieces of semiconductor processing equipment are to be connected; and
 - 2. Designed to form an integrated system in a vacuum environment for sequential multiple wafer processing;
 - <u>Note</u> 3.B.1.e. does not control automatic robotic wafer handling systems not designed to operate in a vacuum environment.
- 3. B. 1. f. Lithography equipment, as follows:
 - 1. Align and expose step and repeat (direct step on wafer) or step and scan (scanner) equipment for wafer processing using photo-optical or X-ray methods, having any of the following:
 - a. A light source wavelength shorter than 245 nm; or
 - b. Capable of producing a pattern with a minimum resolvable feature size of 180 nm or less; *Technical Note*

The minimum resolvable feature size is calculated by the following formula:

 $MRF = \frac{(an \ exposure \ light \ source \ wavelength \ in \ nm) \ x \ (Kfactor)}{numerical \ aperture}$

where the K factor = 0.45MRF = minimum resolvable feature size.

- 2. Equipment specially designed for mask making or semiconductor device processing using deflected focussed electron beam, ion beam or "laser" beam, having any of the following:
 - a. A spot size smaller than $0.2 \mu m$;
 - b. Being capable of producing a pattern with a feature size of less than 1 μ m; or
 - c. An overlay accuracy of better than $\pm 0.20 \ \mu m$ (3 sigma);
- 3. B. 1. g. Masks and reticles designed for integrated circuits controlled by 3.A.1.;
 - h. Multi-layer masks with a phase shift layer.
 - <u>Note</u> 3.B.1.h. does not control multi-layer masks with a phase shift layer designed for the fabrication of memory devices not controlled by 3.A.1.
- 3. B. 2. Test equipment, specially designed for testing finished or unfinished semiconductor devices, as follows, and specially designed components and accessories therefor:

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- a. For testing S-parameters of transistor devices at frequencies exceeding 31.8 GHz;
- b. Deleted
- c. For testing microwave integrated circuits controlled by 3.A.1.b.2.

3. C. MATERIALS

- 3. C. 1. Hetero-epitaxial materials consisting of a "substrate" having stacked epitaxially grown multiple layers of any of the following:
 - a. Silicon;
 - b. Germanium;
 - c. Silicon Carbide; or
 - d. III/V compounds of gallium or indium.

Technical Note

III/V compounds are polycrystalline or binary or complex monocrystalline products consisting of elements of groups IIIA and VA of Mendeleyev's periodic classification table (e.g., gallium arsenide, gallium-aluminium arsenide, indium phosphide).

- 3. C. 2. Resist materials, as follows, and "substrates" coated with controlled resists:
 - a. Positive resists designed for semiconductor lithography specially adjusted (optimised) for use at wavelengths below 350 nm;
 - b. All resists designed for use with electron beams or ion beams, with a sensitivity of 0.01 μ coulomb/mm² or better;
 - c. All resists designed for use with X-rays, with a sensitivity of 2.5 mJ/mm² or better;
 - d. All resists optimised for surface imaging technologies, including silylated resists.

<u>Technical Note</u>

Silulation techniques are defined as processes incorporating oxidation of the resist surface to enhance performance for both wet and dry developing.

- 3. C. 3. Organo-inorganic compounds, as follows:
 - a. Organo-metallic compounds of aluminium, gallium or indium having a purity (metal basis) better than 99.999%;
 - b. Organo-arsenic, organo-antimony and organo-phosphorus compounds having a purity (inorganic element basis) better than 99.999%.
 - <u>Note</u> 3.C.3. only controls compounds whose metallic, partly metallic or nonmetallic element is directly linked to carbon in the organic part of the molecule.
- C. 4. Hydrides of phosphorus, arsenic or antimony, having a purity better than 99.999%, even diluted in inert gases or hydrogen.
 <u>Note</u> 3.C.4. does not control hydrides containing 20% molar or more of inert gases or hydrogen.
- 3. D. SOFTWARE
- 3. D. 1. "Software" specially designed for the "development" or "production" of equipment controlled by 3.A.1.b. to 3.A.2.g. or 3.B.
- 3. D. 2. "Software" specially designed for the "use" of any of the following:
 - a. Equipment controlled by 3.B.1.a. to f.; or
 - b. Equipment controlled by 3.B.2.
- 3. D. 3. Physics-based simulation "software" specially designed for the "development" of lithographic, etching or deposition processes for translating masking patterns into specific topographical patterns in conductors, dielectrics or semiconductor materials.

Technical Note

'Physics-based' in 3.D.3. means using computations to determine a sequence of physical cause and effect events based on physical properties (e.g., temperature, pressure, diffusion constants and semiconductor materials properties).

- <u>Note</u> Libraries, design attributes or associated data for the design of semiconductor devices or integrated circuits are considered as "technology".
- 3. D. 4. "Software" specially designed for the "development" of the equipment controlled by 3.A.3.

3. E. <u>TECHNOLOGY</u>

- 3. E. 1. "Technology" according to the General Technology Note for the "development" or "production" of equipment or materials controlled by 3.A, 3.B or 3.C; <u>Note</u> 3.E.1. does not control "technology" for the "production" of equipment or components controlled by 3.A.3.
 - 2. "Technology" according to the General Technology Note other than that controlled in 3.E.1. for the "development" or "production" of "microprocessor microcircuits", "micro-computer microcircuits" and microcontroller microcircuits having a "composite theoretical performance" ("CTP") of 530 million theoretical operations per second (Mtops) or more and an arithmetic logic unit with an access width of 32 bits or more.
 - <u>Note</u> 3.E.1. and 3.E.2. do not control "technology" for the "development" or "production" of integrated circuits controlled by 3.A.1.a.3. to 3.A.1.a.12., having all of the following:
 - 1. Using "technology" of 0.5 µm or more; and
 - Not incorporating multi-layer structures. <u>Technical Note</u> The term multi-layer structures in Note b.2. above does not include devices incorporating a maximum of three metal layers and three polysilicon layers.
- 3. E. 3. Other "technology" for the "development" or "production" of:
 - a. Vacuum microelectronic devices;
 - b. Hetero-structure semiconductor devices such as high electron mobility transistors (HEMT), hetero-bipolar transistors (HBT), quantum well and super lattice devices;
 - <u>Note</u> 3.E.3.b does not control technology for high electron mobility transistors (HEMT) operating at frequencies lower than 31.8 GHz and hetero-junction bipolar transistors (HBT) operating at frequencies lower than 31.8 GHz.
 - c. "Superconductive" electronic devices;
 - d. Substrates of films of diamond for electronic components;
 - e. Substrates of silicon-on-insulator (SOI) for integrated circuits in which the insulator is silicon dioxide;
 - f. Substrates of silicon carbide for electronic components;
 - g. Electronic vacuum tubes operating at frequencies of 31.8 GHz or higher.

4. COMPUTERS

- <u>Note 1</u> Computers, related equipment and "software" performing telecommunications or "local area network" functions must also be evaluated against the performance characteristics of Category 5, Part 1 (Telecommunications).
- <u>Note 2</u> Control units which directly interconnect the buses or channels of central processing units, "main storage" or disk controllers are not regarded as telecommunications equipment described in Category 5, Part 1 (Telecommunications).

<u>N.B.</u> For the control status of "software" specially designed for packet switching, see Category 5.D.1. (Telecommunications).

<u>Note 3</u> Computers, related equipment and "software" performing cryptographic, cryptanalytic, certifiable multi-level security or certifiable user isolation functions, or which limit electromagnetic compatibility (EMC), must also be evaluated against the performance characteristics in Category 5, Part 2 ("Information Security").

4. A. SYSTEMS, EQUIPMENT AND COMPONENTS

- 4. A. 1. Electronic computers and related equipment, as follows, and "electronic assemblies" and specially designed components therefor:
 - a. Specially designed to have any of the following characteristics:
 - 1. Rated for operation at an ambient temperature below 228 K (-45°C) or above 358 K (85°C);
 - <u>Note</u> 4.A.1.a.1. does not apply to computers specially designed for civil automobile or railway train applications.
 - 2. Radiation hardened to exceed any of the following specifications:
 - a. Total Dose 5×10^3 Gy (Si);
 - b. Dose Rate Upset 5×10^6 Gy (Si)/s; or
 - c. Single Event Upset 1×10^{-7} Error/bit/day;
 - b. Having characteristics or performing functions exceeding the limits in Category 5, Part 2 ("Information Security").
 - <u>Note</u> 4.A.1.b. does not control electronic computers and related equipment when accompanying their user for the user's personal use.
- 4. A. 2. Deleted

- 4. A. 3. "Digital computers", "electronic assemblies", and related equipment therefor, as follows, and specially designed components therefor:
 - <u>Note 1</u> 4.A.3. includes the following:
 - a. Vector processors;
 - b. Array processors;
 - c. Digital signal processors;
 - d. Logic processors;
 - e. Equipment designed for "image enhancement";
 - f. Equipment designed for "signal processing".
 - <u>Note 2</u> The control status of the "digital computers" and related equipment described in 4.A.3 is determined by the control status of other equipment or systems provided:
 - a. The "digital computers" or related equipment are essential for the operation of the other equipment or systems;
 - b. The "digital computers" or related equipment are not a "principal element" of the other equipment or systems; <u>and</u>
 - <u>N.B.1</u> The control status of "signal processing" or "image enhancement" equipment specially designed for other equipment with functions limited to those required for the other equipment is determined by the control status of the other equipment even if it exceeds the "principal element" criterion.
 - <u>N.B.2</u> For the control status of "digital computers" or related equipment for telecommunications equipment, see Category 5, Part 1 (Telecommunications).
 - c. The "technology" for the "digital computers" and related equipment is determined by 4.E.
- 4. A. 3. a. Designed or modified for "fault tolerance";
 - <u>Note</u> For the purposes of 4.A.3.a., "digital computers" and related equipment are not considered to be designed or modified for "fault tolerance" if they utilise any of the following:
 - 1. Error detection or correction algorithms in "main storage";
 - 2. The interconnection of two "digital computers" so that, if the active central processing unit fails, an idling but mirroring central processing unit can continue the system's functioning;
 - 3. The interconnection of two central processing units by data channels or by using shared storage to permit one central processing unit to perform other work until the second central processing unit fails, at which time the first central processing unit takes over in order to continue the system's functioning; or
 - 4. The synchronisation of two central processing units by "software" so that one central processing unit recognises when the other central processing unit fails and recovers tasks from the failing unit.

- 4. A. 3. b. "Digital computers" having an "Adjusted Peak Performance" ("APP") exceeding 0.75 Weighted TeraFLOPS (WT);
- 4. A. 3. c. "Electronic assemblies" specially designed or modified for enhancing performance by aggregation of processors so that the "APP" of the aggregation exceeds the limit in 4.A.3.b.;
 - <u>Note 1</u> 4.A.3.c. applies only to "electronic assemblies" and programmable interconnections not exceeding the limit in 4.A.3.b. when shipped as unintegrated "electronic assemblies". It does not apply to "electronic assemblies" inherently limited by nature of their design for use as related equipment controlled by 4.A.3.e.
 - <u>Note 2</u> 4.A.3.c. does not control "electronic assemblies" specially designed for a product or family of products whose maximum configuration does not exceed the limit of 4.A.3.b.
 - d. Deleted
 - e. Equipment performing analogue-to-digital conversions exceeding the limits in 3.A.1.a.5;
 - f. Deleted
 - g. Equipment specially designed to provide external interconnection of "digital computers" or associated equipment which allows communications at data rates exceeding 1,25 Gbyte/s.
 - <u>Note</u> 4.A.3.g. does not control internal interconnection equipment (e.g., backplanes, buses), passive interconnection equipment, "network access controllers" or "communications channel controllers".
- 4. A. 4. Computers, as follows, and specially designed related equipment, "electronic assemblies" and components therefor:
 - a. "Systolic array computers";
 - b. "Neural computers";
 - c. "Optical computers".

4. B. TEST, INSPECTION AND PRODUCTION EQUIPMENT - None

4. C. <u>MATERIALS</u> – None

4. D. <u>SOFTWARE</u>

- <u>Note</u> The control status of "software" for the "development", "production", or "use" of equipment described in other Categories is dealt with in the appropriate Category. The control status of "software" for equipment described in this Category is dealt with herein.
- 4. D. 1. a. "Software" specially designed or modified for the "development", "production" or "use" of equipment or "software" controlled by 4.A. or 4.D.
 - b. "Software", other than that controlled by 4.D.1.a., specially designed or modified for the "development" or "production" of:
 - 1. "Digital computers" having an "Adjusted Peak Performance" ("APP") exceeding 0.04 Weighted TeraFLOPS (WT); or
 - 2. "Electronic assemblies" specially designed or modified for enhancing performance by aggregation of processors so that the "APP" of the aggregation exceeds the limit in 4.D.1.b.1.
 - 2. "Software" specially designed or modified to support "technology" controlled by 4.E.
 - 3. Specific "software", as follows:
 - a. Operating system "software", "software" development tools and compilers specially designed for "multi-data-stream processing" equipment, in "source code";
 - b. Deleted
 - c. "Software" having characteristics or performing functions exceeding the limits in Category 5, Part 2 ("Information Security");

d. Deleted

4. E. <u>TECHNOLOGY</u>

- 4. E. 1. a. "Technology" according to the General Technology Note, for the "development", "production" or "use" of equipment or "software" controlled by 4.A. or 4.D.
 - b. "Technology", other than that controlled by 4.E.1.a., specially designed or modified for the "development" or "production" of:
 - 1. "Digital computers" having an "Adjusted Peak Performance" ("APP") exceeding 0.04 Weighted TeraFLOPS (WT); or
 - 2. "Electronic assemblies" specially designed or modified for enhancing performance by aggregation of processors so that the "APP" of the aggregation exceeds the limit in 4.E.1.b.1.

<u>Note</u> 4.D.3.c. does not control "software" when accompanying its user for the user's personal use.

TECHNICAL NOTE ON "COMPOSITE THEORETICAL PERFORMANCE" ("CTP")

Abbreviations used in this Technical Note

"CE"	"computing element" (typically an arithmetic logical unit)	
FP	floating point	
XP	fixed point	
t	execution time	
XOR	exclusive OR	
CPU	central processing unit	
TP	theoretical performance (of a single "CE")	
"CTP"	"composite theoretical performance" (multiple "CEs")	
R	effective calculating rate	
WL	word length	
L	word length adjustment	
*	multiply	
	Execution time 't' is expressed in microseconds, TP and "CTP" are expressed in	
	millions of theoretical operations per second (Mtops) and WL is expressed in bits.	

Outline of "CTP" calculation method

"CTP" is a measure of computational performance given in Mtops. In calculating the "CTP" of an aggregation of "CEs" the following three steps are required:

- 1. Calculate the effective calculating rate R for each "CE";
- 2. Apply the word length adjustment (L) to the effective calculating rate (R), resulting in a Theoretical Performance (TP) for each "CE";
- 3. If there is more than one "CE", combine the TPs, resulting in a "CTP" for the aggregation.

Details for these steps are given in the following sections.

- <u>Note 1</u> For aggregations of multiple "CEs" which have both shared and unshared memory subsystems, the calculation of "CTP" is completed hierarchically, in two steps: first, aggregate the groups of "CEs" sharing memory; second, calculate the "CTP" of the groups using the calculation method for multiple "CEs" not sharing memory.
- <u>Note 2</u> "CEs" that are limited to input/output and peripheral functions (e.g., disk drive, communication and video display controllers) are not aggregated into the "CTP" calculation.

TECHNICAL NOTE ON "CTP"

The following table shows the method of calculating the Effective Calculating Rate R for each "CE":

Step 1: The effective calculating rate R

For "CEs" Implementing: <u>Note</u> Every "CE" must be evaluated	Effective calculating Rate, R
independently.	
XP only	$\frac{1}{3^* (t_{xp add})}$
(R _{xp)}	if no add is implemented use: $\frac{1}{(t_{xp mult})}$
	If neither add nor multiply is implemented use the fastest available arithmetic operation as follows:
	$\frac{1}{3 * t_{xp}}$ See Notes X & Z
FP only (R fp)	$\max \frac{1}{t_{\text{ fp add}}}, \frac{1}{t_{\text{ fp mult}}}$ See Notes X & Y
Both FP and XP (R)	Calculate both R _{xp} , R _{fp}
For simple logic processors not implementing any of the specified arithmetic operations.	$\frac{1}{3 * t_{log}}$
	Where t \log is the execute time of the XOR, or for
	logic hardware not implementing the XOR, the fastest simple logic operation. See Notes X & Z
For special logic processors not using any of the specified arithmetic or logic operations.	R = R' * WL/64 Where R' is the number of results per second, WL is the number of <u>bits</u> upon which the logic operation occurs, and 64 is a factor to normalize to a 64 bit operation.

TECHNICAL NOTE ON "CTP"

- <u>Note W</u> For a pipelined "CE" capable of executing up to one arithmetic or logic operation every clock cycle after the pipeline is full, a pipelined rate can be established. The effective calculating rate (R) for such a "CE" is the faster of the pipelined rate or non-pipelined execution rate.
- <u>Note X</u> For a "CE" which performs multiple operations of a specific type in a single cycle (e.g., two additions per cycle or two identical logic operations per cycle), the execution time t is given by:

"CEs" which perform different types of arithmetic or logic operations in a single machine cycle are to be treated as multiple separate "CEs" performing simultaneously (e.g., a "CE" performing an addition and a multiplication in one cycle is to be treated as two "CEs", the first performing an addition in one cycle and the second performing a multiplication in one cycle).

If a single "CE" has both scalar function and vector function, use the shorter execution time value.

<u>Note Y</u> For the "CE" that does not implement FP add or FP multiply, but that performs FP divide:

$$R_{fp} = \frac{1}{t_{fpdivide}}$$

If the "CE" implements FP reciprocal but not FP add, FP multiply or FP divide, then

$$R_{fp} = \frac{1}{t_{fpreciprocal}}$$

If none of the specified instructions is implemented, the effective FP rate is 0.

<u>Note Z</u> In simple logic operations, a single instruction performs a single logic manipulation of no more than two operands of given lengths.
 In complex logic operations, a single instruction performs multiple logic manipulations to produce one or more results from two or more operands.

t = the number of identical operations per machine cycle

TECHNICAL NOTE ON "CTP"

Note Z

Rates should be calculated for all supported operand lengths considering both pipelined operations (if supported), and non-pipelined operations using the fastest executing instruction for each operand length based on:

- 1. Pipelined or register-to-register operations. Exclude extraordinarily short execution times generated for operations on a predetermined operand or operands (for example, multiplication by 0 or 1). If no register-to-register operations are implemented, continue with (2).
- 2. The faster of register-to-memory or memory-to-register operations; if these also do not exist, then continue with (3).
- 3. Memory-to-memory.

In each case above, use the shortest execution time certified by the manufacturer.

Step 2: TP for each supported operand length WL

Adjust the effective rate R (or R') by the word length adjustment L as follows:

$$TP = R * L$$
,
where $L = (1/3 + WL/96)$

<u>Note</u> The word length WL used in these calculations is the operand length in bits. (If an operation uses operands of different lengths, select the largest word length.)

The combination of a mantissa ALU and an exponent ALU of a floating point processor or unit is considered to be one "CE" with a Word Length (WL) equal to the number of bits in the data representation (typically 32 or 64) for purposes of the "CTP" calculation.

This adjustment is not applied to specialized logic processors which do not use XOR instructions. In this case TP = R.

Select the maximum resulting value of TP for:

Each XP-only "CE" (R_{xp}) ; Each FP-only "CE" (R_{fp}) ; Each combined FP and XP "CE" (R); Each simple logic processor not implementing any of the specified arithmetic operations; <u>and</u> Each special logic processor not using any of the specified arithmetic or logic operations.

TECHNICAL NOTE ON "CTP"

Step 3: <u>"CTP" for aggregations of "CEs", including CPUs.</u>

For a CPU with a single "CE", "CTP" = TP (for "CEs" performing both fixed and floating point operations $TP = max (TP_{fp}, TP_{xp}))$

"CTP" for aggregations of multiple "CEs" operating simultaneously is calculated as follows:

- Note 1 For aggregations that do not allow all of the "CEs" to run simultaneously, the possible combination of "CEs" that provides the largest "CTP" should be used. The TP of each contributing "CE" is to be calculated at its maximum value theoretically possible before the "CTP" of the combination is derived.
 - <u>N.B.</u> To determine the possible combinations of simultaneously operating "CEs", generate an instruction sequence that initiates operations in multiple "CEs", beginning with the slowest "CE" (the one needing the largest number of cycles to complete its operation) and ending with the fastest "CE". At each cycle of the sequence, the combination of "CEs" that are in operation during that cycle is a possible combination. The instruction sequence must take into account all hardware and/or architectural constraints on overlapping operations.
- <u>Note 2</u> A single integrated circuit chip or board assembly may contain multiple "CEs".
- <u>Note 3</u> Simultaneous operations are assumed to exist when the computer manufacturer claims concurrent, parallel or simultaneous operation or execution in a manual or brochure for the computer.
- <u>Note 4</u> "CTP" values are not to be aggregated for "CE" combinations (inter)connected by "Local Area Networks", Wide Area Networks, I/O shared connections/devices, I/O controllers and any communication interconnection implemented by software.

TECHNICAL NOTE ON "CTP"

<u>Note 5</u> "CTP" values must be aggregated for multiple "CEs" specially designed to enhance performance by aggregation, operating simultaneously and sharing memory,- or multiple memory/"CE"-combinations operating simultaneously utilising specially designed hardware.

This aggregation does not apply to "electronic assemblies" described in 4.A.3.c.

 $"CTP" = TP_1 + C_2 * TP_2 + ... + C_n * TP_n,$

where the TPs are ordered by value, with TP_1 being the highest, TP_2 being the second highest, ..., and TP_n being the lowest. C_i is a coefficient determined by the strength of the interconnection between "CEs", as follows:

For multiple "CEs" operating simultaneously and sharing memory:

$$C_2 = C_3 = C_4 = \dots = C_n = 0.75$$

<u>Note 1</u> When the "CTP" calculated by the above method does not exceed 194 Mtops, the following formula may be used to calculate C_i:

$$C_i = \frac{0.75}{\sqrt{m}}$$
 (i = 2, ..., n)

where m = the number of "CEs" or groups of "CEs" sharing access.

provided:

- 1. The TP_i of each "CE" or group of "CEs" does not exceed 30 Mtops;
- 2. The "CEs" or groups of "CEs" share access to main memory (excluding cache memory) over a single channel; and
- 3. Only one "CE" or group of "CEs" can have use of the channel at any given time.

<u>N.B.</u> This does not apply to items controlled under Category 3.

<u>Note 2</u> "CEs" share memory if they access a common segment of solid state memory. This memory may include cache memory, main memory or other internal memory. Peripheral memory devices such as disk drives, tape drives or RAM disks are not included.

TECHNICAL NOTE ON "CTP"

For Multiple "CEs" or groups of "CEs" not sharing memory, interconnected by one or more data channels:

 $\begin{array}{rll} C_i &=& 0.75 \ * \ k_i & (i \ = \ 2, \ \ldots, \ 32) \ (\text{see Note below}) \\ &=& 0.60 \ * \ k_i & (i \ = \ 33, \ \ldots, \ 64) \\ &=& 0.45 \ * \ k_i & (i \ = \ 65, \ \ldots, \ 256) \\ &=& 0.30 \ * \ k_i & (i \ > \ 256) \end{array}$

The value of C_i is based on the number of "CEs", not the number of nodes.

where $k_i = \min(S_i/K_r, 1)$, and

- $K_r =$ normalizing factor of 20 MByte/s.
- $S_i = \begin{array}{ll} \mbox{sum of the maximum data rates (in units of MByte/s) for all data channels connected to the i^{th} "CE" or group of "CEs" sharing memory. \end{array}$

When calculating a C_i for a group of "CEs", the number of the first "CE" in a group determines the proper limit for C_i . For example, in an aggregation of groups consisting of 3 "CEs" each, the 22nd group will contain "CE"₆₄, "CE"₆₅ and "CE"₆₆. The proper limit for C_i for this group is 0.60.

Aggregation (of "CEs" or groups of "CEs") should be from the fastest-to-slowest; i.e.:

 $\text{TP}_1 \geq \text{TP}_2 \geq \ldots \geq \text{TP}_n$, and

in the case of TP_i = TP_{i + 1}, from the largest to smallest; i.e.: $C_i \ge C_{i+1}$

<u>Note</u> The k_i factor is not to be applied to "CEs" 2 to 12 if the TP_i of the "CE" or group of "CEs" is more than 50 Mtops; i.e., C_i for "CEs" 2 to 12 is 0.75.

TECHNICAL NOTE ON "AJUSTED PEAK PERFORMANCE" ("APP")

"APP" is an adjusted peak rate at which "digital computers" perform 64-bit or larger floating point additions and multiplications.

Abbreviations used in this Technical Note

- n number of processors in the "digital computer"
- i processor number (i,...n)
- t_i processor cycle time ($t_i = 1/F_i$)
- F_i processor frequency
- R_i peak floating point calculating rate
- W_i architecture adjustment factor

"APP" is expressed in Weighted TeraFLOPS (WT), in units of 10^{12} adjusted floating point operations per second.

Outline of "APP" calculation method

1. For each processor i, determine the peak number of 64-bit or larger floating point operations, FPO_i, performed per cycle for each processor in the "digital computer".

- <u>Note</u> In determining FPO, include only 64-bit or larger floating point additions and/or multiplications. All floating point operations must be expressed in operations per processor cycle; operations requiring multiple cycles may be expressed in fractional results per cycle. For processors not capable of performing calculations on floating point operands of 64-bits or more, the effective calculating rate R is zero.
- 2. Calculate the floating point rate R for each processor $R_i = FPO_i/t_i$
- 3. Calculate "APP" as "APP" = $W_1 \times R_1 + W_2 \times R_2 + ... + W_n \times R_n$.
- 4. For "vector processors", $W_i = 0.9$. For non-"vector processors", $W_i = 0.3$.
- <u>Note 1</u> For processors that perform compound operations in a cycle, such as addition and multiplication, each operation is counted.
- <u>Note 2</u> For a pipelined processor the effective calculating rate R is the faster of the pipelined rate, once the pipeline is full, or the non-pipelined rate.
- <u>Note 3</u> The calculating rate R of each contributing processor is to be calculated at its maximum value theoretically possible before the "APP" of the combination is derived. Simultaneous operations are assumed to exist when the computer manufacturer claims concurrent, parallel, or simultaneous operation or execution in a manual or brochure for the computer.

DUAL-USE LIST - CATEGORY 4 - COMPUTERS

TECHNICAL NOTE ON "AJUSTED PEAK PERFORMANCE" ("APP")

- <u>Note 4</u> Do not include processors that are limited to input/output and peripheral functions (e.g., disk drive, communication and video display) when calculating "APP".
- <u>Note 5</u> "APP" values are not to be calculated for processor combinations (inter)connected by "Local Area Networks", Wide Area Networks, I/O shared connections/devices, I/O controllers and any communication interconnection implemented by "software".
- <u>Note 6</u> "APP" values must be calculated for 1) processor combinations containing processors specially designed to enhance performance by aggregation, operating simultaneously and sharing memory; or 2) multiple memory/processor combinations operating simultaneously utilizing specially designed hardware.
- <u>Note 7</u> A "vector processor" is defined as a processor with built-in instructions that perform multiple calculations on floating-point vectors (one-dimensional arrays of 64-bit or larger numbers) simultaneously, having at least 2 vector functional units and at least 8 vector registers of at least 64 elements each.

Part 1 - TELECOMMUNICATIONS

- <u>Note 1</u> The control status of components, "lasers", test and "production" equipment and "software" therefor which are specially designed for telecommunications equipment or systems is determined in Category 5, Part 1.
- <u>Note 2</u> "Digital computers", related equipment or "software", when essential for the operation and support of telecommunications equipment described in this Category, are regarded as specially designed components, provided they are the standard models customarily supplied by the manufacturer. This includes operation, administration, maintenance, engineering or billing computer systems.

5. A. 1. SYSTEMS, EQUIPMENT AND COMPONENTS

- a. Any type of telecommunications equipment having any of the following characteristics, functions or features:
 - 1. Specially designed to withstand transitory electronic effects or electromagnetic pulse effects, both arising from a nuclear explosion;
 - 2. Specially hardened to withstand gamma, neutron or ion radiation; or
 - Specially designed to operate outside the temperature range from 218 K (-55°C) to 397 K (124°C).
 <u>Note</u> 5.A.1.a.3. applies only to electronic equipment.
 - <u>Note</u> 5.A.1.a.2. and 5.A.1.a.3. do not control equipment designed or modified for use on board satellites.
- 5. A. 1. b. Telecommunication transmission equipment and systems, and specially designed components and accessories therefor, having any of the following characteristics, functions or features:
 - 1. Being underwater communications systems having any of the following characteristics:
 - a. An acoustic carrier frequency outside the range from 20 kHz to 60 kHz;
 - b. Using an electromagnetic carrier frequency below 30 kHz; or
 - c. Using electronic beam steering techniques;
- 5. A. 1. b. 2. Being radio equipment operating in the 1.5 MHz to 87.5 MHz band and having any of the following characteristics:
 - a. Incorporating adaptive techniques providing more than 15 dB suppression of an interfering signal; <u>or</u>
 - b. Having all of the following:
 - 1. Automatically predicting and selecting frequencies and "total digital transfer rates" per channel to optimise the transmission; and

- 5. A. 1. b. 2. Incorporating a linear power amplifier configuration having a b. 2. capability to support multiple signals simultaneously at an output power of 1 kW or more in the frequency range of 1.5 MHz or more but less than 30 MHz, or 250 W or more in the frequency range of 30 MHz or more but not exceeding 87.5 MHz, over an "instantaneous bandwidth" of one octave or more and with an output harmonic and distortion content of better than -80 dB;
- Being radio equipment employing "spread spectrum" techniques, 5. A. 1. b. 3. including "frequency hopping" techniques, not controlled in 5.A.1.b.4., having any of the following characteristics:
 - User programmable spreading codes; or a.
 - b. A total transmitted bandwidth which is 100 or more times the bandwidth of any one information channel and in excess of 50 kHz:
 - Note 5.A.1.b.3.b. does not control radio equipment specially with civil cellular radiodesigned for use communications systems.
 - Note 5.A.1.b.3. does not control equipment designed to operate at an output power of 1.0 Watt or less.
- 5. A. 1. b. 4. Being radio equipment employing ultra-wideband modulation techniques having user programmable channelizing codes, scrambling codes or network identification codes, having any of the following characteristics:
 - A bandwidth exceeding 500 MHz; or a.
 - A "fractional bandwidth" of 20% or more. h
- 5. A. 1. b. 5. Being digitally controlled radio receivers having all of the following:
 - More than 1,000 channels; a.
 - b. A "frequency switching time" of less than 1 ms;
 - Automatic searching or scanning of a part of the c. electromagnetic spectrum; and
 - d. Identification of the received signals or the type of transmitter; or
 - 5.A.1.b.5. does not control radio equipment specially Note designed for use with civil cellular radio-communications systems.
- Employing functions of digital "signal processing" to provide voice 5. A. 1. b. 6. coding output at rates of less than 2,400 bit/s. Technical Notes

- For variable rate voice coding, 5.A.1.b.6. applies to the voice 1. coding output of continuous speech.
- For the purpose of 5.A.1.b.6., 'voice coding' is defined as the 2. technique to take samples of human voice and then convert these samples into a digital signal, taking into account specific characteristics of human speech.

- 5. A. 1. c. Optical fibre communication cables, optical fibres and accessories, as follows:
 - 1. Optical fibres of more than 500 m in length, specified by the manufacturer as being capable of withstanding a proof test tensile stress of 2×10^9 N/m² or more;

<u>Technical Note</u>

Proof Test: on-line or off-line production screen testing that dynamically applies a prescribed tensile stress over a 0.5 to 3 m length of fibre at a running rate of 2 to 5 m/s while passing between capstans approximately 150 mm in diameter. The ambient temperature is a nominal 293 K and relative humidity 40%. Equivalent national standards may be used for executing the proof test.

- 2. Optical fibre cables and accessories designed for underwater use.
 - <u>Note</u> 5.A.1.c.2. does not control standard civil telecommunication cables and accessories.
 - <u>N.B.1</u> For underwater umbilical cables, and connectors therefor, see 8.A.2.a.3.
 - <u>N.B.2</u> For fibre-optic hull penetrators or connectors, see 8.A.2.c.
- 5. A. 1. d. "Electronically steerable phased array antennae" operating above 31.8 GHz. <u>Note</u> 5.A.1.d. does not control "electronically steerable phased array antennae" for landing systems with instruments meeting ICAO standards covering microwave landing systems (MLS).
- 5. A. 1. e. Radio direction finding equipment operating at frequencies above 30 MHz and having all of the following characteristics, and specially designed components therefor:
 - 1. "Instantaneous bandwidth" of 10 MHz or more; and
 - 2. Capable of finding a line of bearing (LOB) to non-cooperating radio transmitters with a signal duration of less than 1ms.
- 5. A. 1. f. Jamming equipment specially designed or modified to intentionally and selectively interfere with, deny, inhibit, degrade or seduce cellular mobile telecommunication services, having any of the following characteristics, and specially designed components therefor:
 - 1. Simulating the functions of Radio Access Network (RAN) equipment; or
 - 2. Detecting and exploiting specific characteristics of the mobile telecommunications protocol employed (eg., GSM).
 - <u>N.B.</u> For GNSS jamming equipment see the Munitions List.

5. B. 1. TEST, INSPECTION AND PRODUCTION EQUIPMENT

- 5. B. 1. a. Equipment and specially designed components or accessories therefor, specially designed for the "development", "production" or "use" of equipment, functions or features controlled by Category 5 Part 1. <u>Note</u> 5.B.1.a. does not control optical fibre characterization equipment.
- 5. B. 1. b. Equipment and specially designed components or accessories therefor, specially designed for the "development" of any of the following telecommunication transmission or switching equipment:
 - 1. Equipment employing digital techniques designed to operate at a "total digital transfer rate" exceeding 15 Gbit/s; *Technical Note*

For switching equipment the "total digital transfer rate" is measured at the highest speed port or line.

- 2. Equipment employing a "laser" and having any of the following:
 - a. A transmission wavelength exceeding 1750 nm;
 - b. Performing "optical amplification";
 - c. Employing coherent optical transmission or coherent optical detection techniques (also called optical heterodyne or homodyne techniques); or
 - d. Employing analogue techniques and having a bandwidth exceeding 2.5 GHz; Note 5.B.1.b.2.d. does not control equipment specially designed

Note 5.B.1.b.2.d. does not control equipment specially designed for the "development" of commercial TV systems.

- 3. Equipment employing "optical switching";
- 4. Radio equipment employing quadrature-amplitude-modulation (QAM) techniques above level 256; <u>or</u>
- 5. Equipment employing "common channel signalling" operating in nonassociated mode of operation.

5. C. 1. MATERIALS - None

5. D. 1. SOFTWARE

- 5. D. 1. a. "Software" specially designed or modified for the "development", "production" or "use" of equipment, functions or features controlled by Category 5 - Part 1.
 - b. "Software" specially designed or modified to support "technology" controlled by 5.E.1.
 - c. Specific "software" specially designed or modified to provide characteristics, functions or features of equipment controlled by 5.A.1. or 5.B.1.
- 5. D. 1. d. "Software" specially designed or modified for the "development" of any of the following telecommunication transmission or switching equipment:
 - Equipment employing digital techniques designed to operate at a "total digital transfer rate" exceeding 15 Gbit/s; <u>Technical Note</u> For switching equipment the "total digital transfer rate" is measured
 - 2. Equipment employing a "laser" and having any of the following:
 - a. A transmission wavelength exceeding 1750 nm; or
 - b. Employing analogue techniques and having a bandwidth exceeding 2.5 GHz;
 - <u>Note</u> 5.D.1.d.2.b. does not control "software" specially designed or modified for the "development" of commercial TV systems.
 - 3. Equipment employing "optical switching"; or

at the highest speed port or line.

4. Radio equipment employing quadrature-amplitude-modulation (QAM) techniques above level 256.

5. E. 1. <u>TECHNOLOGY</u>

5. E. 1. a. "Technology" according to the General Technology Note for the "development", "production" or "use" (excluding operation) of equipment, functions or features or "software" controlled by Category 5 - Part 1.

- 5. E. 1. b. Specific "technologies", as follows:
 - 1. "Required" "technology" for the "development" or "production" of telecommunications equipment specially designed to be used on board satellites;
 - 2. "Technology" for the "development" or "use" of "laser" communication techniques with the capability of automatically acquiring and tracking signals and maintaining communications through exoatmosphere or sub-surface (water) media;
 - 3. "Technology" for the "development" of digital cellular radio base station receiving equipment whose reception capabilities that allow multi-band, multi-channel, multi-mode, multi-coding algorithm or multi-protocol operation can be modified by changes in "software";
 - 4. "Technology" for the "development" of "spread spectrum" techniques, including "frequency hopping" techniques.
- 5. E. 1. c. "Technology" according to the General Technology Note for the "development" or "production" of any of the following telecommunication transmission or switching equipment, functions or features:
 - Equipment employing digital techniques designed to operate at a "total digital transfer rate" exceeding 15 Gbit/s; <u>Technical Note</u> For switching equipment the "total digital transfer rate" is measured

for switching equipment the "total digital transfer rate" is measured at the highest speed port or line.

- 2. Equipment employing a "laser" and having any of the following:
 - a. A transmission wavelength exceeding 1750 nm;
 - b. Performing "optical amplification" using praseodymium-doped fluoride fibre amplifiers (PDFFA);
 - c. Employing coherent optical transmission or coherent optical detection techniques (also called optical heterodyne or homodyne techniques);
 - d. Employing wavelength division multiplexing techniques exceeding 8 optical carriers in a single optical window; <u>or</u>
 - e. Employing analogue techniques and having a bandwidth exceeding 2.5 GHz;
 - <u>Note</u> 5.E.1.c.2.e. does not control "technology" for the "development" or "production" of commercial TV systems.
- 3. Equipment employing "optical switching";

- 5. E. 1. c. 4. Radio equipment having any of the following:
 - a. Quadrature-amplitude-modulation (QAM) techniques above level 256; or
 - b. Operating at input or output frequencies exceeding 31.8 GHz; or
 - <u>Note</u> 5.E.1.c.4.b. does not control "technology" for the "development" or "production" of equipment designed or modified for operation in any frequency band which is "allocated by the ITU" for radio-communications services, but not for radio-determination.
 - 5. Equipment employing "common channel signalling" operating in nonassociated mode of operation.

Part 2 - "INFORMATION SECURITY"

- <u>Note 1</u> The control status of "information security" equipment, "software", systems, application specific "electronic assemblies", modules, integrated circuits, components or functions is determined in Category 5, Part 2 even if they are components or "electronic assemblies" of other equipment.
- <u>Note 2</u> Category 5 Part 2 does not control products when accompanying their user for the user's personal use.
- <u>Note 3</u> <u>Cryptography Note</u>
 - 5.A.2. and 5.D.2. do not control items that meet all of the following:
 - a. Generally available to the public by being sold, without restriction, from stock at retail selling points by means of any of the following:
 - 1. Over-the-counter transactions;
 - 2. Mail order transactions;
 - *3. Electronic transactions;* <u>or</u>
 - 4. Telephone call transactions;
 - b. The cryptographic functionality cannot easily be changed by the user;
 - *c.* Designed for installation by the user without further substantial support by the supplier; <u>and</u>
 - *d. Deleted;*
 - e. When necessary, details of the items are accessible and will be provided, upon request, to the appropriate authority in the exporter's country in order to ascertain compliance with conditions described in paragraphs a. to c. above.

Technical Note

In Category 5 - Part 2, parity bits are not included in the key length.

5. A. 2. SYSTEMS, EQUIPMENT AND COMPONENTS

- a. Systems, equipment, application specific "electronic assemblies", modules and integrated circuits for "information security", as follows, and other specially designed components therefor:
- <u>N.B.</u> For the control of global navigation satellite systems receiving equipment containing or employing decryption (i.e. GPS or GLONASS), see 7.A.5.
- 5. A. 2. a. 1. Designed or modified to use "cryptography" employing digital techniques performing any cryptographic function other than authentication or digital signature having any of the following:

Technical Notes

- 1. Authentication and digital signature functions include their associated key management function.
- 2. Authentication includes all aspects of access control where there is no encryption of files or text except as directly related to the protection of passwords, Personal Identification Numbers (PINs) or similar data to prevent unauthorised access.
- 3. "Cryptography" does not include "fixed" data compression or coding techniques.
- <u>Note</u> 5.A.2.a.1. includes equipment designed or modified to use "cryptography" employing analogue principles when implemented with digital techniques.
- 5. A. 2. a. 1. a. A "symmetric algorithm" employing a key length in excess of 56 bits; or
 - b. An "asymmetric algorithm" where the security of the algorithm is based on any of the following:
 - 1. Factorisation of integers in excess of 512 bits (e.g., RSA);
 - 2. Computation of discrete logarithms in a multiplicative group of a finite field of size greater than 512 bits (e.g., Diffie-Hellman over Z/pZ); or
 - 3. Discrete logarithms in a group other than mentioned in 5.A.2.a.1.b.2. in excess of 112 bits (e.g., Diffie-Hellman over an elliptic curve);
 - 2. Designed or modified to perform cryptanalytic functions;
 - 3. Deleted;
 - 4. Specially designed or modified to reduce the compromising emanations of information-bearing signals beyond what is necessary for health, safety or electromagnetic interference standards;
 - 5. Designed or modified to use cryptographic techniques to generate the spreading code for "spread spectrum" systems, not controlled in 5.A.2.a.6., including the hopping code for "frequency hopping" systems;
 - 6. Designed or modified to use cryptographic techniques to generate channelizing codes, scrambling codes or network identification codes, for systems using ultra-wideband modulation techniques, having any of the following characteristics:
 - a. A bandwidth exceeding 500MHz; or
 - b. A "fractional bandwidth" of 20% or more.
 - 7. Deleted
 - 8. Communications cable systems designed or modified using mechanical, electrical or electronic means to detect surreptitious intrusion.

5. A. 2. a. 9. Designed or modified to use "quantum cryptography". <u>Technical Note</u> "Quantum cryptography" is also known as quantum key distribution (QKD).

<u>Note</u> 5.A.2. does not control:

- a. "Personalised smart cards":
 - 1. Where the cryptographic capability is restricted for use in equipment or systems excluded from control under entries b. to f. of this Note; or
 - 2. For general public-use applications where the cryptographic capability is not user-accessible and it is specially designed and limited to allow protection of personal data stored within.
 - <u>N.B.</u> If a "personalised smart card" has multiple functions, the control status of each function is assessed individually.
 - b. Receiving equipment for radio broadcast, pay television or similar restricted audience broadcast of the consumer type, without digital encryption except that exclusively used for sending the billing or programme-related information back to the broadcast providers.
 - c. Equipment where the cryptographic capability is not useraccessible and which is specially designed and limited to allow any of the following:
 - 1. Execution of copy-protected software;
 - 2. Access to any of the following:
 - a. Copy-protected contents stored on read-only media; or
 - b. Information stored in encrypted form on media (e.g. in connection with the protection of intellectual property rights) when the media is offered for sale in identical sets to the public;
 - 3. Copying control of copyright protected audio/video data; or
 - 4. Encryption and/or decryption for protection of libraries, design attributes, or associated data for the design of semiconductor devices or integrated circuits;
 - *d. Cryptographic equipment specially designed and limited for banking use or money transactions.* <u>*Technical Note*</u>

'Money transactions' in 5.A.2. Note d. includes the collection and settlement of fares or credit functions.

- e. Portable or mobile radiotelephones for civil use (e.g., for use with commercial civil cellular radiocommunications systems) that are not capable of end-to-end encryption.
- f. Cordless telephone equipment not capable of end-to-end encryption where the maximum effective range of unboosted cordless operation (i.e., a single, unrelayed hop between terminal and home basestation) is less than 400 metres according to the manufacturer's specifications.

5. B. 2. TEST, INSPECTION AND PRODUCTION EQUIPMENT

- a. Equipment specially designed for:
 - 1. The "development" of equipment or functions controlled by Category 5 Part 2, including measuring or test equipment;
 - 2. The "production" of equipment or functions controlled by Category 5 Part 2, including measuring, test, repair or production equipment.
- b. Measuring equipment specially designed to evaluate and validate the "information security" functions controlled by 5.A.2. or 5.D.2.

5. C. 2. <u>MATERIALS</u> - None

5. D. 2. SOFTWARE

- a. "Software" specially designed or modified for the "development", "production" or "use" of equipment or "software" controlled by Category 5 - Part 2;
- b. "Software" specially designed or modified to support "technology" controlled by 5.E.2.;
- c. Specific "software", as follows:
 - 1. "Software" having the characteristics, or performing or simulating the functions of the equipment controlled by 5.A.2. or 5.B.2.;
 - 2. "Software" to certify "software" controlled by 5.D.2.c.1.

<u>Note</u> 5.D.2. does not control:

- a. "Software" required for the "use" of equipment excluded from control under the Note to 5.A.2.;
- b. "Software" providing any of the functions of equipment excluded from control under the Note to 5.A.2.

5. E. 2. <u>TECHNOLOGY</u>

a. "Technology" according to the General Technology Note for the "development", "production" or "use" of equipment or "software" controlled by Category 5 - Part 2.

6. A. SYSTEMS, EQUIPMENT AND COMPONENTS

6. A. 1. ACOUSTICS

- 6. A. 1. a. Marine acoustic systems, equipment and specially designed components therefor, as follows:
 - 1. Active (transmitting or transmitting-and-receiving) systems, equipment and specially designed components therefor, as follows: *Note* 6.A.1.a.1. does not control:
 - a. Depth sounders operating vertically below the apparatus, not including a scanning function exceeding $\pm 20^{\circ}$, and limited to measuring the depth of water, the distance of submerged or buried objects or fish finding;
 - b. Acoustic beacons, as follows:
 - 1. Acoustic emergency beacons;
 - 2. Pingers specially designed for relocating or returning to an underwater position.
- 6. A. 1. a. 1. a. Wide-swath bathymetric survey systems designed for sea bed topographic mapping, having all of the following:
 - 1. Being designed to take measurements at an angle exceeding 20° from the vertical;
 - 2. Being designed to measure depths exceeding 600 m below the water surface; and
 - 3. Being designed to provide any of the following:
 - a. Incorporation of multiple beams any of which is less than 1.9°; or
 - b. Data accuracies of better than 0.3% of water depth across the swath averaged over the individual measurements within the swath;
- 6. A. 1. a. 1. b. Object detection or location systems having any of the following:
 - 1. A transmitting frequency below 10 kHz;
 - Sound pressure level exceeding 224 dB (reference 1 μPa at 1 m) for equipment with an operating frequency in the band from 10 kHz to 24 kHz inclusive;
 - 3. Sound pressure level exceeding 235 dB (reference 1μ Pa at 1 m) for equipment with an operating frequency in the band between 24 kHz and 30 kHz;
 - 4. Forming beams of less than 1° on any axis and having an operating frequency of less than 100 kHz;
 - 5. Designed to operate with an unambiguous display range exceeding 5,120 m; or
 - 6. Designed to withstand pressure during normal operation at depths exceeding 1,000 m and having transducers with any of the following:
 - a. Dynamic compensation for pressure; or
 - b. Incorporating other than lead zirconate titanate as the transduction element;
- 6. A. 1. a. 1. c. Acoustic projectors, including transducers, incorporating piezoelectric, magnetostrictive, electrostrictive, electrodynamic or

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hydraulic elements operating individually or in a designed combination, having any of the following:

- <u>Note 1</u> The control status of acoustic projectors, including transducers, specially designed for other equipment is determined by the control status of the other equipment.
- <u>Note 2</u> 6.A.1.a.1.c. does not control electronic sources which direct the sound vertically only, or mechanical (e.g., air gun or vapour-shock gun) or chemical (e.g., explosive) sources.
- A. 1. a. 1. c. 1. An instantaneous radiated acoustic power density exceeding 0.01 mW/mm²/Hz for devices operating at frequencies below 10 kHz;
 - A continuously radiated acoustic power density exceeding 0.001 mW/mm²/Hz for devices operating at frequencies below 10 kHz; or

Technical Note

Acoustic power density is obtained by dividing the output acoustic power by the product of the area of the radiating surface and the frequency of operation.

- 3. Side-lobe suppression exceeding 22 dB;
- 6. A. 1. a. 1. d. Acoustic systems, equipment and specially designed components for determining the position of surface vessels or underwater vehicles designed to operate at a range exceeding 1,000 m with a positioning accuracy of less than 10 m rms (root mean square) when measured at a range of 1,000 m;

<u>Note</u> 6.A.1.a.1.d. includes:

- a. Equipment using coherent "signal processing" between two or more beacons and the hydrophone unit carried by the surface vessel or underwater vehicle;
- b. Equipment capable of automatically correcting speed-of-sound propagation errors for calculation of a point.

- 6. A. 1. a. 2. Passive (receiving, whether or not related in normal application to separate active equipment) systems, equipment and specially designed components therefor, as follows:
 - a. Hydrophones having any of the following characteristics:
 - <u>Note</u> The control status of hydrophones specially designed for other equipment is determined by the control status of the other equipment.
 - 1. Incorporating continuous flexible sensing elements;
 - 2. Incorporating flexible assemblies of discrete sensing elements with either a diameter or length less than 20 mm and with a separation between elements of less than 20 mm;
 - 3. Having any of the following sensing elements:
 - a. Optical fibres;
 - b. Piezoelectric polymer films other than polyvinylidenefluoride (PVDF) and its co-polymers {P(VDF-TrFE) and P(VDF-TFE)}; <u>or</u>
 - c. Flexible piezoelectric composites;
 - 4. A hydrophone sensitivity better than -180 dB at any depth with no acceleration compensation;
 - 5. When designed to operate at depths exceeding 35 m with acceleration compensation; or
 - 6. Designed for operation at depths exceeding 1,000 m;

Technical Notes

- 1. 'Piezoelectric polymer film' sensing elements consist of polarized polymer film that is stretched over and attached to a supporting frame or spool (mandrel).
- 2. 'Flexible piezoelectric composite' sensing elements consist of piezoelectric ceramic particles or fibres combined with an electrically insulating, acoustically transparent rubber, polymer or epoxy compound, where the compound is an integral part of the sensing elements.
- 3. Hydrophone sensitivity is defined as twenty times the logarithm to the base 10 of the ratio of rms output voltage to a 1 V rms reference, when the hydrophone sensor, without a pre-amplifier, is placed in a plane wave acoustic field with an rms pressure of 1 μ Pa. For example, a hydrophone of -160 dB (reference 1 V per μ Pa) would yield an output voltage of 10⁻⁸ V in such a field, while one of -180 dB sensitivity would yield only 10⁻⁹ V output. Thus, -160 dB is better than -180 dB.
- 6. A. 1. a. 2. b. Towed acoustic hydrophone arrays having any of the following:
 - 1. Hydrophone group spacing of less than 12.5 m or able to be modified to have hydrophone group spacing of less than 12.5 m;

6.	A.	1.	a.	2.	b.	 Designed or able to be modified to operate at depths exceeding 35 m; <u>Technical Note</u> 'Able to be modified' in 6.A.1.a.2.b. means having provisions to allow a change of the wiring or interconnections to alter hydrophone group spacing or operating depth limits. These provisions are: spare wiring exceeding 10% of the number of wires, hydrophone group spacing adjustment blocks or internal depth limiting devices that are adjustable or that control more than one hydrophone group. Heading sensors controlled by 6.A.1.a.2.d.; Longitudinally reinforced array hoses; An assembled array of less than 40 mm in diameter; Multiplexed hydrophone group signals designed to operate at depths exceeding 35 m or having an adjustable or removable depth sensing device in order to operate at depths exceeding 35 m; or Hydrophone characteristics specified in 6.A.1.a.2.a.;
6.	A.	1.	a.	2.	c.	Processing equipment, specially designed for towed acoustic hydrophone arrays, having "user accessible programmability" and time or frequency domain processing and correlation, including spectral analysis, digital filtering and beamforming using Fast Fourier or other transforms or processes;
6.	A.	1.	a.	2.	d.	 Heading sensors having all of the following: 1. An accuracy of better than ± 0.5°; and 2. Designed to operate at depths exceeding 35 m or having an adjustable or removable depth sensing device in order to operate at depths exceeding 35 m;
6.	A.	1.	a.	2.	e.	 Bottom or bay cable systems having any of the following: Incorporating hydrophones specified in 6.A.1.a.2.a.; or Incorporating multiplexed hydrophone group signal modules having all of the following characteristics: a. Designed to operate at depths exceeding 35 m or having an adjustable or removable depth sensing device in order to operate at depths exceeding 35 m; and b. Capable of being operationally interchanged with towed acoustic hydrophone array modules;
6.	A.	1.	a.	2.	f.	Processing equipment, specially designed for bottom or bay cable systems, having "user accessible programmability" and time or frequency domain processing and correlation, including spectral analysis, digital filtering and beamforming using Fast Fourier or other transforms or processes;
6.	A.	1.	b.	hori	zontal	n-velocity sonar log equipment designed to measure the speed of the equipment carrier relative to the sea bed at distances he carrier and the sea bed exceeding 500 m.

6. A. 2. OPTICAL SENSORS

a. Optical detectors, as follows:

Note 6.A.2.a. does not control germanium or silicon photodevices.

- *N.B.* Silicon and other material based microbolometer non "spacequalified" "focal plane arrays" are only specified in 6.A.2.a.3.f.
- 6. A. 2. a. 1. "Space-qualified" solid-state detectors, as follows:
 - a. "Space-qualified" solid-state detectors, having all of the following:
 - 1. A peak response in the wavelength range exceeding 10 nm but not exceeding 300 nm; and
 - 2. A response of less than 0.1% relative to the peak response at a wavelength exceeding 400 nm;
 - b. "Space-qualified" solid-state detectors, having all of the following:
 - 1. A peak response in the wavelength range exceeding 900 nm but not exceeding 1,200 nm; and
 - 2. A response "time constant" of 95 ns or less;
 - c. "Space-qualified" solid-state detectors having a peak response in the wavelength range exceeding 1,200 nm but not exceeding 30,000 nm;
- 6. A. 2. a. 2. Image intensifier tubes and specially designed components therefor, as follows:
 - a. Image intensifier tubes having all of the following:
 - 1. A peak response in the wavelength range exceeding 400 nm but not exceeding 1,050 nm;
 - 2. A microchannel plate for electron image amplification with a hole pitch (centre-to-centre spacing) of $12 \ \mu m$ or less; and
 - 3. Any of the following photocathodes:
 - a. S-20, S-25 or multialkali photocathodes with a luminous sensitivity exceeding $350 \,\mu$ A/lm;
 - b. GaAs or GaInAs photocathodes; or
 - c. Other III-V compound semiconductor photocathodes;
 - <u>Note</u> 6.A.2.a.2.a.3.c. does not apply to compound semiconductor photocathodes with a maximum radiant sensitivity of 10 mA/W or less.
 - b. Specially designed components, as follows:
 - 1. Microchannel plates having a hole pitch (centre-to-centre spacing) of 12 μm or less;
 - 2. GaAs or GaInAs photocathodes;
 - 3. Other III-V compound semiconductor photocathodes;
 - <u>Note</u> 6.A.2.a.2.b.3. does not control compound semiconductor photocathodes with a maximum radiant sensitivity of 10 mA/W or less.

- 6. A. 2. a. 3. Non-"space-qualified" "focal plane arrays", as follows:
 - N.B. Silicon and other material based microbolometer non "spacequalified" "focal plane arrays" are only specified in 6.A.2.a.3.f.

Technical Notes

- 1. Linear or two-dimensional multi-element detector arrays are referred to as "focal plane arrays";
- 2. For the purposes of 6.A.2.a.3. 'cross scan direction' is defined as the axis parallel to the linear array of detector elements and the 'scan direction' is defined as the axis perpendicular to the linear array of detector elements.
- <u>Note 1</u> 6.A.2.a.3. includes photoconductive arrays and photovoltaic arrays.
- <u>Note 2</u> 6.A.2.a.3. does not control:
 - a. Multi-element (not to exceed 16 elements) encapsulated photoconductive cells using either lead sulphide or lead selenide;
 - b. Pyroelectric detectors using any of the following:
 - 1. Triglycine sulphate and variants;
 - 2. Lead-lanthanum-zirconium titanate and variants;
 - 3. Lithium tantalate;
 - 4. Polyvinylidene fluoride and variants; or
 - 5. Strontium barium niobate and variants.
- 6. A. 2. a. 3. a. Non-"space-qualified" "focal plane arrays", having all of the following:
 - 1. Individual elements with a peak response within the wavelength range exceeding 900 nm but not exceeding 1,050 nm; and
 - 2. A response "time constant" of less than 0.5 ns;
 - b. Non-"space-qualified" "focal plane arrays", having all of the following:
 - 1. Individual elements with a peak response in the wavelength range exceeding 1,050 nm but not exceeding 1,200 nm; and
 - 2. A response "time constant" of 95 ns or less;
 - c. Non-"space-qualified" non-linear (2-dimensional) "focal plane arrays", having individual elements with a peak response in the wavelength range exceeding 1,200 nm but not exceeding 30,000 nm;
 - N.B. Silicon and other material based microbolometer non "space-qualified" "focal plane arrays" are only specified in 6.A.2.a.3.f.

- 6. A. 2. a. 3. Non-"space-qualified" linear (1-dimensional) "focal plane d. arrays", having all of the following : 1. Individual elements with a peak response in the wavelength range exceeding 1,200 nm but not exceeding 2,500 nm; and 2. Any of the following : A ratio of scan direction dimension of the detector a. element to the cross-scan direction dimension of the detector element of less than 3.8; or Signal processing in the element (SPRITE); b. Non-"space-qualified" linear (1-dimensional) "focal plane arrays", 6. A. 2. a. 3. e. having individual elements with a peak response in the wavelength range exceeding 2,500 nm but not exceeding 30,000 nm. 6. A. 2. Non-"space-qualified" non-linear (2-dimensional) infrared "focal a. 3. f. plane arrays" based on micro-bolometer material having individual elements with an unfiltered response in the wavelength range equal to or exceeding 8,000 nm but not exceeding 14,000 nm. Technical Note For the purposes of 6.A.2.a.3.f. 'micro-bolometer' is defined as a thermal imaging detector that, as a result of a temperature change in the detector caused by the absorption of infrared radiation, is used to generate any usable signal. 6. A. 2 "Monospectral imaging sensors" and "multispectral imaging sensors" b.
 - 5. A. 2 b. "Monospectral imaging sensors" and "multispectral imaging sensors" designed for remote sensing applications, having any of the following:
 - 1. An Instantaneous-Field-Of-View (IFOV) of less than 200 µrad (microradians); or
 - 2. Being specified for operation in the wavelength range exceeding 400 nm but not exceeding 30,000 nm and having all the following;
 - a. Providing output imaging data in digital format; and
 - b. Being any of the following:
 - 1. "Space-qualified"; <u>or</u>
 - 2. Designed for airborne operation, using other than silicon detectors, and having an IFOV of less than 2.5 mrad (milliradians).
- 6. A. 2 c. Direct view imaging equipment operating in the visible or infrared spectrum, incorporating any of the following:
 - 1. Image intensifier tubes having the characteristics listed in 6.A.2.a.2.a.; or
 - 2. "Focal plane arrays" having the characteristics listed in 6.A.2.a.3.

Technical Note

'Direct view' refers to imaging equipment, operating in the visible or infrared spectrum, that presents a visual image to a human observer without converting the image into an electronic signal for television display, and that cannot record or store the image photographically, electronically or by any other means.

<u>Note</u> 6.A.2.c. does not control the following equipment incorporating other than GaAs or GaInAs photocathodes:

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- a. Industrial or civilian intrusion alarm, traffic or industrial movement control or counting systems;
- *b. Medical equipment;*
- c. Industrial equipment used for inspection, sorting or analysis of the properties of materials;
- d. Flame detectors for industrial furnaces;
- e. Equipment specially designed for laboratory use.
- 6. A. 2. d. Special support components for optical sensors, as follows:
 - 1. "Space-qualified" cryocoolers;
 - 2. Non-"space-qualified" cryocoolers, having a cooling source temperature below 218 K (-55°C), as follows:
 - a. Closed cycle type with a specified Mean-Time-To-Failure (MTTF), or Mean-Time-Between-Failures (MTBF), exceeding 2,500 hours;
 - b. Joule-Thomson (JT) self-regulating minicoolers having bore (outside) diameters of less than 8 mm;
 - 3. Optical sensing fibres specially fabricated either compositionally or structurally, or modified by coating, to be acoustically, thermally, inertially, electromagnetically or nuclear radiation sensitive.
- 6. A. 2. e. "Space qualified" "focal plane arrays" having more than 2,048 elements per array and having a peak response in the wavelength range exceeding 300 nm but not exceeding 900 nm.
- 6. A. 3. <u>CAMERAS</u>
 - <u>N.B.</u> For cameras specially designed or modified for underwater use, see 8.A.2.d. and 8.A.2.e.
- 6. A. 3. a. Instrumentation cameras and specially designed components therefor, as follows:
 - <u>Note</u> Instrumentation cameras, controlled by 6.A.3.a.3. to 6.A.3.a.5., with modular structures should be evaluated by their maximum capability, using plug-ins available according to the camera manufacturer's specifications.
 - 1. High-speed cinema recording cameras using any film format from 8 mm to 16 mm inclusive, in which the film is continuously advanced throughout the recording period, and that are capable of recording at framing rates exceeding 13,150 frames/s;

<u>Note</u> 6.A.3.a.1. does not control cinema recording cameras designed for civil purposes.

- 2. Mechanical high speed cameras, in which the film does not move, capable of recording at rates exceeding 1,000,000 frames/s for the full framing height of 35 mm film, or at proportionately higher rates for lesser frame heights, or at proportionately lower rates for greater frame heights;
- 3. Mechanical or electronic streak cameras having writing speeds exceeding 10 mm/µs;
- 4. Electronic framing cameras having a speed exceeding 1,000,000 frames/s;
- 6. A. 3. a. 5. Electronic cameras, having all of the following:

- a. An electronic shutter speed (gating capability) of less than 1 µs per full frame; and
- b. A read out time allowing a framing rate of more than 125 full frames per second.
- 6. Plug-ins, having all of the following characteristics:
 - a. Specially designed for instrumentation cameras which have modular structures and which are controlled by 6.A.3.a.; and
 - b. Enabling these cameras to meet the characteristics specified in 6.A.3.a.3., 6.A.3.a.4. or 6.A.3.a.5., according to the manufacturer's specifications.
- 6. A. 3. b. Imaging cameras, as follows:

- 1. Video cameras incorporating solid state sensors, having a peak response in the wavelength range exceeding 10 nm, but not exceeding 30,000 nm and having all of the following:
 - a. Having any of the following:
 - 1. More than 4×10^6 "active pixels" per solid state array for monochrome (black and white) cameras;
 - 2. More than 4×10^6 "active pixels" per solid state array for colour cameras incorporating three solid state arrays; or
 - 3. More than 12×10^6 "active pixels" for solid state array colour cameras incorporating one solid state array; and
 - b. Having any of the following:
 - 1. Optical mirrors controlled by 6.A.4.a.;
 - 2. Optical control equipment controlled by 6.A.4.d.; or
 - 3. The capability for annotating internally generated camera tracking data.

Technical Notes

- 1. For the purpose of this entry, digital video cameras should be evaluated by the maximum number of "active pixels" used for capturing moving images.
- 2. For the purpose of this entry, camera tracking data is the information necessary to define camera line of sight orientation with respect to the earth. This includes: 1) the horizontal angle the camera line of sight makes with respect to the earth's magnetic field direction and; 2) the vertical angle between the camera line of sight and the earth's horizon.
- 6. A. 3. b. 2. Scanning cameras and scanning camera systems, having all of the following:
 - a. A peak response in the wavelength range exceeding 10 nm, but not exceeding 30,000 nm;
 - b. Linear detector arrays with more than 8,192 elements per array; <u>and</u>c. Mechanical scanning in one direction;
- 6. A. 3. b. 3. Imaging cameras incorporating image intensifier tubes having the characteristics listed in 6.A.2.a.2.a.;
- 6. A. 3. b. 4. Imaging cameras incorporating "focal plane arrays" having any of the following:

<u>Note</u> 6.A.3.b. does not control television or video cameras specially designed for television broadcasting.

- a. Incorporating "focal plane arrays" controlled by 6.A.2.a.3.a. to 6.A.2.a.3.e.; <u>or</u>
- b. Incorporating "focal plane arrays" controlled by 6.A.2.a.3.f.
- <u>Note 1</u> 'Imaging cameras' described in 6.A.3.b.4 include "focal plane arrays" combined with sufficient signal processing electronics, beyond the read out integrated circuit, to enable as a minimum the output of an analogue or digital signal once power is supplied.
- <u>Note 2</u> 6.A.3.b.4.a. does not control imaging cameras incorporating linear "focal plane arrays" with twelve elements or fewer, not employing time-delay-and-integration within the element, designed for any of the following:
 - a. Industrial or civilian intrusion alarm, traffic or industrial movement control or counting systems;
 - b. Industrial equipment used for inspection or monitoring of heat flows in buildings, equipment or industrial processes;
 - c. Industrial equipment used for inspection, sorting or analysis of the properties of materials;
 - d. Equipment specially designed for laboratory use; or
 - e. Medical equipment.
- <u>Note 3</u> 6.A.3.b.4.b. does not control imaging cameras having any of the following characteristics:
 - a. A maximum frame rate equal to or less than 9 Hz;
 - b. Having all of the following:
 - 1. Having a minimum horizontal or vertical Instantaneous-Field-of-View (IFOV) of at least 10 mrad/pixel (milliradians/pixel);
 - 2. Incorporating a fixed focal-length lens that is not designed to be removed;
 - 3. Not incorporating a direct view display; <u>and</u> <u>Technical Note</u>:

'Direct view' refers to an imaging camera operating in the infrared spectrum that presents a visual image to a human observer using a near-to-eye micro display incorporating any light-security mechanism.

- 4. Having any of the following:
 - a. No facility to obtain a viewable image of the detected field-of-view; <u>or</u>
 - b. The camera is designed for a single kind of application and designed not to be user modified; <u>or</u>

Technical Note

Instantaneous Field of View (IFOV) specified in Note 3.b. is the lesser figure of the Horizontal FOV or the Vertical FOV.

Horizontal IFOV = horizontal Field of View (FOV)/number of horizontal detector elements

Vertical IFOV= vertical Field of View (FOV)/number of vertical detector elements.

- c. Where the camera is specially designed for installation into a civilian passenger land vehicle of less than three tonnes (gross vehicle weight) and having all of the following:
 - Is only operable when installed in any of the following:
 a. The civilian passenger land vehicle for which it was intended; or
 - b. A specially designed, authorized maintenance test facility; <u>and</u>
 - 2. Incorporates an active mechanism that forces the camera not to function when it is removed from the vehicle for which it was intended.

<u>Note</u>: When necessary, details of the item will be provided, upon request, to the appropriate authority in the exporter's country in order to ascertain compliance with the conditions described in Note 3.b.4. and Note 3.c. above.

6. A. 4. <u>OPTICS</u>

- a. Optical mirrors (reflectors), as follows:
 - 1. "Deformable mirrors" having either continuous or multi-element surfaces, and specially designed components therefor, capable of dynamically repositioning portions of the surface of the mirror at rates exceeding 100 Hz;
 - 2. Lightweight monolithic mirrors having an average "equivalent density" of less than 30 kg/m² and a total mass exceeding 10 kg;
 - Lightweight "composite" or foam mirror structures having an average "equivalent density" of less than 30 kg/m² and a total mass exceeding 2 kg;
 - 4. Beam steering mirrors more than 100 mm in diameter or length of major axis, which maintain a flatness of lambda/2 or better (lambda is equal to 633 nm) having a control bandwidth exceeding 100 Hz.
- 6. A. 4. b. Optical components made from zinc selenide (ZnSe) or zinc sulphide (ZnS) with transmission in the wavelength range exceeding 3,000 nm but not exceeding 25,000 nm and having any of the following:
 - 1. Exceeding 100 cm^3 in volume; <u>or</u>
 - 2. Exceeding 80 mm in diameter or length of major axis and 20 mm in thickness (depth).

- 6. A. 4. c. "Space-qualified" components for optical systems, as follows:
 - 1. Lightweighted to less than 20% "equivalent density" compared with a solid blank of the same aperture and thickness;
 - 2. Raw substrates, processed substrates having surface coatings (singlelayer or multi-layer, metallic or dielectric, conducting, semiconducting or insulating) or having protective films;
 - 3. Segments or assemblies of mirrors designed to be assembled in space into an optical system with a collecting aperture equivalent to or larger than a single optic 1 m in diameter;
 - 4. Manufactured from "composite" materials having a coefficient of linear thermal expansion equal to or less than 5×10^{-6} in any coordinate direction.
- 6. A. 4. d. Optical control equipment, as follows:
 - 1. Specially designed to maintain the surface figure or orientation of the "space-qualified" components controlled by 6.A.4.c.1. or 6.A.4.c.3.;
 - 2. Having steering, tracking, stabilisation or resonator alignment bandwidths equal to or more than 100 Hz and an accuracy of 10 μrad (microradians) or less;
 - 3. Gimbals having all of the following:
 - a. A maximum slew exceeding 5° ;
 - b. A bandwidth of 100 Hz or more;
 - c. Angular pointing errors of 200 µrad (microradians) or less; and
 - d. Having any of the following:
 - Exceeding 0.15 m but not exceeding 1 m in diameter or major axis length and capable of angular accelerations exceeding 2 rad (radians)/s²; or
 - 2. Exceeding 1 m in diameter or major axis length and capable of angular accelerations exceeding 0.5 rad (radians)/s²;
 - 4. Specially designed to maintain the alignment of phased array or phased segment mirror systems consisting of mirrors with a segment diameter or major axis length of 1 m or more.
- 6. A. 4. e. Aspheric optical elements having all of the following characteristics:
 - 1. The largest dimension of the optical-aperture is greater than 400 mm;
 - 2. The surface roughness is less than 1 nm (rms) for sampling lengths equal to or greater than 1 mm; and
 - 3. The coefficient of linear thermal expansion's absolute magnitude is less than 3×10^{-6} /K at 25 ° C;

Technical Notes

- 1. An 'aspheric optical element' is any element used in an optical system whose imaging surface or surfaces are designed to depart from the shape of an ideal sphere.
- 2. *Manufacturers are not required to measure the surface roughness listed in 6.A.4.e.2. unless the optical element was designed or manufactured with the intent to meet, or exceed, the control parameter.*
- <u>Note</u> 6.A.4.e. does not control aspheric optical elements having any of the following:
 - a. A largest optical-aperture dimension less than 1 m and a focal length to aperture ratio equal to or greater than 4.5:1;

- b. A largest optical-aperture dimension equal to or greater than 1 m and a focal length to aperture ratio equal to or greater than 7:1;
- c. Being designed as Fresnel, flyeye, stripe, prism or diffractive optical elements;
- *d.* Being fabricated from borosilicate glass having a coefficient of linear thermal expansion greater than 2.5x10⁻⁶ /K at 25 °C; <u>or</u>
- e. Being an x-ray optical element having inner mirror capabilities (e.g. tube-type mirrors).
- <u>N.B.</u> For aspheric optical elements specially designed for lithography equipment, see Item 3.B.1.

LASERS

- 6. A. 5. "Lasers", components and optical equipment, as follows:
 - <u>Note 1</u> Pulsed "lasers" include those that run in a continuous wave (CW) mode with pulses superimposed.
 - <u>Note 2</u> Pulse-excited "lasers" include those that run in a continuously excited mode with pulse excitation superimposed.
 - <u>Note 3</u> The control status of Raman "lasers" is determined by the parameters of the pumping source "lasers". The pumping source "lasers" can be any of the "lasers" described below.
- 6. A. 5. a. Gas "lasers", as follows:
 - 1. Excimer "lasers", having any of the following:
 - a. An output wavelength not exceeding 150 nm and having any of the following:
 - 1. An output energy exceeding 50 mJ per pulse; or
 - 2. An average output power exceeding 1 W;
 - b. An output wavelength exceeding 150 nm but not exceeding 190 nm and having any of the following:
 - 1. An output energy exceeding 1.5 J per pulse; or
 - 2. An average output power exceeding 120 W;
 - c. An output wavelength exceeding 190 nm but not exceeding 360 nm and having any of the following:
 - 1. An output energy exceeding 10 J per pulse; or
 - 2. An average output power exceeding 500 W; or
 - d. An output wavelength exceeding 360 nm and having any of the following:
 - 1. An output energy exceeding 1.5 J per pulse; or
 - 2. An average output power exceeding 30 W;
 - <u>N.B.</u> For excimer "lasers" specially designed for lithography equipment, see 3.B.1.

6.	A.	5.	a.	2.	 Metal vapour "lasers", as follows: a. Copper (Cu) "lasers" having an average output power exceeding 20 W; b. Gold (Au) "lasers" having an average output power exceeding 5 W; c. Sodium (Na) "lasers" having an output power exceeding 5 W; d. Barium (Ba) "lasers" having an average output power exceeding 2 W;
6.	A.	5.	a.	3.	 Carbon monoxide (CO) "lasers" having any of the following: a. An output energy exceeding 2 J per pulse and a pulsed "peak power" exceeding 5 kW; or b. An average or CW output power exceeding 5 kW;
6.	A.	5.	a.	4.	 Carbon dioxide (CO₂) "lasers" having any of the following: a. A CW output power exceeding 15 kW; b. A pulsed output having a "pulse duration" exceeding 10 µs and having any of the following: An average output power exceeding 10 kW; or A pulsed "peak power" exceeding 100 kW; or c. A pulsed output having a "pulse duration" equal to or less than 10 µs; and having any of the following: A pulse energy exceeding 5 J per pulse; or An average output power exceeding 2.5 kW;
6.	A.	5.	a.	5.	 "Chemical lasers", as follows: a. Hydrogen Fluoride (HF) "lasers"; b. Deuterium Fluoride (DF) "lasers"; c. "Transfer lasers", as follows: Oxygen Iodine (O2-I) "lasers"; Deuterium Fluoride-Carbon dioxide (DF-CO2) "lasers";
6.	А.	5.	a.	6.	 Krypton ion or argon ion "lasers" having any of the following: a. An output energy exceeding 1.5 J per pulse and a pulsed "peak power" exceeding 50 W; or b. An average or CW output power exceeding 50 W;
6.	A.	5.	a.	7.	 Other gas "lasers", having any of the following: <u>Note</u> 6.A.5.a.7. does not control nitrogen "lasers". a. An output wavelength not exceeding 150 nm and having any of the following: An output energy exceeding 50 mJ per pulse and a pulsed "peak power" exceeding 1 W; or An average or CW output power exceeding 1 W; b. An output wavelength exceeding 150 nm but not exceeding
					800 nm and having any of the following: 1. An output energy exceeding 1.5 J per pulse and a pulsed

 An output energy exceeding 1.55 per pulse and a "peak power" exceeding 30 W; or
 An average or CW output power exceeding 30 W;

- 6. A. 5. a. 7. c. An output wavelength exceeding 800 nm but not exceeding 1,400 nm and having any of the following:
 - 1. An output energy exceeding 0.25 J per pulse and a pulsed "peak power" exceeding 10 W; or
 - 2. An average or CW output power exceeding 10 W; or
 - d. An output wavelength exceeding 1,400 nm and an average or CW output power exceeding 1 W.
- 6. A. 5. b. Semiconductor "lasers", as follows:
 - <u>Note 1</u> 6.A.5.b. includes semiconductor "lasers" having optical output connectors (e.g. fibre optic pigtails).
 - <u>Note 2</u> The control status of semiconductor "lasers" specially designed for other equipment is determined by the control status of the other equipment.
 - 1. Individual single-transverse mode semiconductor "lasers", having any of the following:
 - a. A wavelength equal to or less than 1510 nm, and having an average or CW output power exceeding 1.5 W; or
 - b. A wavelength greater than 1510 nm, and having an average or CW output power exceeding 500 mW;
 - 2. Individual, multiple-transverse mode semiconductor "lasers", having any of the following:
 - a. A wavelength of less than 1400 nm, and having an average or CW output power exceeding 10W;
 - b. A wavelength equal to or greater than 1400 nm and less than 1900 nm, and having an average or CW output power exceeding 2.5 W; or
 - c. A wavelength equal to or greater than 1900 nm and having an average or CW output power exceeding 1 W.
 - 3. Individual semiconductor "laser" arrays, having any of the following:
 - a. A wavelength of less than 1400 nm, and having an average or CW output power exceeding 80 W;
 - b. A wavelength equal to or greater than 1400 nm and less than 1900 nm, and having an average or CW output power exceeding 25 W; or
 - c. A wavelength equal to or greater than 1900 nm, and having an average or CW output power exceeding 10 W.
 - 4. Array stacks of semiconductor "lasers" containing at least one array that is controlled under 6.A.5.b.3.

Technical Notes

- 1. Semiconductor "lasers" are commonly called "laser" diodes.
- 2. An 'array' consists of multiple semiconductor "laser" emitters fabricated as a single chip so that the centres of the emitted light beams are on parallel paths.
- 3. An 'array stack' is fabricated by stacking, or otherwise assembling, 'arrays' so that the centres of the emitted light beams are on parallel paths.

- 6. A. 5. c. Solid state "lasers", as follows:
 - 1. "Tunable" "lasers" having any of the following:
 - <u>Note</u> 6.A.5.c.1. includes titanium sapphire(Ti: Al₂O₃), thulium -YAG (Tm: YAG), thulium - YSGG (Tm: YSGG), alexandrite (Cr: BeAl₂O₄) and colour centre "lasers".
 - a. An output wavelength less than 600 nm and having any of the following:
 - 1. An output energy exceeding 50 mJ per pulse and a pulsed "peak power" exceeding 1 W; or
 - 2. An average or CW output power exceeding 1 W;
 - b. An output wavelength of 600 nm or more but not exceeding 1,400 nm and having any of the following:
 - 1. An output energy exceeding 1 J per pulse and a pulsed "peak power" exceeding 20 W; or
 - 2. An average or CW output power exceeding 20 W; or
 - c. An output wavelength exceeding 1,400 nm and having any of the following:
 - 1. An output energy exceeding 50 mJ per pulse and a pulsed "peak power" exceeding 1 W; or
 - 2. An average or CW output power exceeding 1 W;
- 6. A. 5. c. 2. Non-"tunable" "lasers", as follows:

<u>Note</u> 6.A.5.c.2. includes atomic transition solid state "lasers".

- a. Neodymium glass "lasers", as follows:
 - 1. "Q-switched lasers" having any of the following:
 - a. An output energy exceeding 20 J but not exceeding 50 J per pulse and an average output power exceeding 10 W; or
 - b. An output energy exceeding 50 J per pulse;
 - 2. Non-"Q-switched lasers" having any of the following:
 - a. An output energy exceeding 50 J but not exceeding 100 J per pulse and an average output power exceeding 20 W; or
 - b. An output energy exceeding 100 J per pulse;
- 6. A. 5. c. 2. b. Neodymium-doped (other than glass) "lasers", having an output wavelength exceeding 1,000 nm but not exceeding 1,100 nm, as follows:
 - <u>N.B.</u> For neodymium-doped (other than glass) "lasers" having an output wavelength not exceeding 1,000 nm or exceeding 1,100 nm, see 6.A.5.c.2.c.

- 6. A. 5. c. 2. b. 1. Pulse-excited, mode-locked, "Q-switched lasers" having a "pulse duration" of less than 1 ns and having any of the following:
 - a. A "peak power" exceeding 5 GW;
 - b. An average output power exceeding 10 W; or
 - c. A pulsed energy exceeding 0.1 J;
 - 2. Pulse-excited, "Q-switched lasers" having a pulse duration equal to or more than 1 ns, and having any of the following:
 - a. A single-transverse mode output having:
 - 1. A "peak power" exceeding 100 MW;
 - 2. An average output power exceeding 20 W; or
 - 3. A pulsed energy exceeding 2 J; or
 - b. A multiple-transverse mode output having:
 - 1. A "peak power" exceeding 400 MW;
 - 2. An average output power exceeding 2 kW; or
 - 3. A pulsed energy exceeding 2 J;
 - 3. Pulse-excited, non-"Q-switched lasers", having:
 - a. A single-transverse mode output having:
 - 1. A "peak power" exceeding 500 kW; or
 - 2. An average output power exceeding 150 W; or
 - b. A multiple-transverse mode output having:
 - 1. A "peak power" exceeding 1 MW; or
 - 2. An average power exceeding 2 kW;
 - 4. Continuously excited "lasers" having:

a.

- A single-transverse mode output having:
 - 1. A "peak power" exceeding 500 kW; or
- 2. An average or CW output power exceeding 150 W; or
- b. A multiple-transverse mode output having:
 - 1. A "peak power" exceeding 1 MW; or
 - 2. An average or CW output power exceeding 2 kW;
- 6. A. 5. c. 2. c.
 - c. Other non-"tunable" "lasers", having any of the following:
 - 1. A wavelength less than 150 nm and having any of the following:
 - a. An output energy exceeding 50 mJ per pulse and a pulsed "peak power" exceeding 1 W; or
 - b. An average or CW output power exceeding 1 W;
 - 2. A wavelength of 150 nm or more but not exceeding 800 nm and having any of the following:
 - a. An output energy exceeding 1.5 J per pulse and a pulsed "peak power" exceeding 30 W; or
 - b. An average or CW output power exceeding 30 W;

6. A. 5. c. 2. c. 3. A wavelength exceeding 800 nm but not exceeding 1,400 nm, as follows:

- a. "Q-switched lasers" having:
 - 1. An output energy exceeding 0.5 J per pulse and a pulsed "peak power" exceeding 50 W; or
 - 2. An average output power exceeding:
 - a. 10 W for single-transverse mode "lasers";
 - b. 30 W for multiple-transverse mode "lasers";
 - Non-"Q-switched lasers" having:
 - 1. An output energy exceeding 2 J per pulse and a pulsed "peak power" exceeding 50 W; or
 - 2. An average or CW output power exceeding 50 W; or
- 4. A wavelength exceeding 1,400 nm and having any of the following:
 - a. An output energy exceeding 100 mJ per pulse and a pulsed "peak power" exceeding 1 W; or
 - b. An average or CW output power exceeding 1 W;
- 6. A. 5. d. Dye and other liquid "lasers", having any of the following:

b.

- 1. A wavelength less than 150 nm and:
 - a. An output energy exceeding 50 mJ per pulse and a pulsed "peak power" exceeding 1 W; or
 - b. An average or CW output power exceeding 1 W;
- 2. A wavelength of 150 nm or more but not exceeding 800 nm and having any of the following:
 - a. An output energy exceeding 1.5 J per pulse and a pulsed "peak power" exceeding 20 W;
 - b. An average or CW output power exceeding 20 W; or
 - c. A pulsed single longitudinal mode oscillator having an average output power exceeding 1 W and a repetition rate exceeding 1 kHz if the "pulse duration" is less than 100 ns;
- 3. A wavelength exceeding 800 nm but not exceeding 1,400 nm and having any of the following:
 - a. An output energy exceeding 0.5 J per pulse and a pulsed "peak power" exceeding 10 W; or
 - b. An average or CW output power exceeding 10 W; or
- 4. A wavelength exceeding 1,400 nm and having any of the following:
 - a. An output energy exceeding 100 mJ per pulse and a pulsed "peak power" exceeding 1 W; or
 - b. An average or CW output power exceeding 1 W;

- 6. A. 5. e. Components, as follows:
 - 1. Mirrors cooled either by active cooling or by heat pipe cooling; *Technical Note*

Active cooling is a cooling technique for optical components using flowing fluids within the subsurface (nominally less than 1 mm below the optical surface) of the optical component to remove heat from the optic.

2. Optical mirrors or transmissive or partially transmissive optical or electro-optical components specially designed for use with controlled "lasers";

6. A. 5. f. Optical equipment, as follows:

- <u>N.B.</u> For shared aperture optical elements, capable of operating in "Super-High Power Laser" ("SHPL") applications, see Item 19. Note 2. d. on the Munitions List.^{*}
- 1. Dynamic wavefront (phase) measuring equipment capable of mapping at least 50 positions on a beam wavefront having any of the following:
 - a. Frame rates equal to or more than 100 Hz and phase discrimination of at least 5% of the beam's wavelength; <u>or</u>
 - b. Frame rates equal to or more than 1,000 Hz and phase discrimination of at least 20% of the beam's wavelength;
- 2. "Laser" diagnostic equipment capable of measuring "SHPL" system angular beam steering errors of equal to or less than 10 µrad;
- 3. Optical equipment and components specially designed for a phasedarray "SHPL" system for coherent beam combination to an accuracy of lambda/10 at the designed wavelength, or $0.1 \,\mu$ m, whichever is the smaller;
- 4. Projection telescopes specially designed for use with "SHPL" systems.

MAGNETIC AND ELECTRIC FIELD SENSORS

- 6. A. 6. "Magnetometers", "magnetic gradiometers", "intrinsic magnetic gradiometers", underwater electric field sensors, and compensation systems, and specially designed components therefor, as follows:
 - <u>Note</u> 6.A.6. does not control instruments specially designed for fishery applications or biomagnetic measurements for medical diagnostics.

^{*} France, the Russian Federation and Ukraine view this list as a reference list drawn up to help in the selection of dual-use goods which could contribute to the indigenous development, production or enhancement of conventional munitions capabilities.

- 6. A. 6. a. "Magnetometers" and subsystems, as follows:
 - 1. Using "superconductive" (SQUID) "technology" and having any of the following characteristics:
 - a. SQUID systems designed for stationary operation, without specially designed subsystems designed to reduce in-motion noise, and having a "noise level" (sensitivity) equal to or lower (better) than 50 fT (rms) per square root Hz at a frequency of 1 Hz; or
 - b. SQUID systems having an in-motion-magnetometer "noise level" (sensitivity) lower (better) than 20 pT (rms) per square root Hz at a frequency of 1 Hz and specially designed to reduce in-motion noise;
 - 2. Using optically pumped or nuclear precession (proton/Overhauser) "technology" having a "noise level" (sensitivity) lower (better) than 20 pT (rms) per square root Hz;
 - 3. Using fluxgate "technology" having a "noise level" (sensitivity) equal to or lower (better) than 10 pT (rms) per square root Hz at a frequency of 1 Hz;
 - 4. Induction coil "magnetometers" having a "noise level" (sensitivity) lower (better) than any of the following:
 - a. 0.05 nT (rms)/square root Hz at frequencies of less than 1 Hz;
 - b. 1 x 10⁻³ nT (rms)/square root Hz at frequencies of 1 Hz or more but not exceeding 10 Hz; or
 - c. 1×10^{-4} nT (rms)/square root Hz at frequencies exceeding 10 Hz;
 - 5. Fibre optic "magnetometers" having a "noise level" (sensitivity) lower (better) than 1 nT (rms) per square root Hz;
- 6. A. 6. b. Underwater Electric Field Sensors having a "noise level" (sensitivity) lower (better) than 8 nanovolt per meter per square root Hz when measured at 1 Hz.
- 6. A. 6. c. Magnetic gradiometers, as follows:
 - 1. "Magnetic gradiometers" using multiple "magnetometers" controlled by 6.A.6.a.;
 - 2. Fibre optic "intrinsic magnetic gradiometers" having a magnetic gradient field "noise level" (sensitivity) lower (better) than 0.3 nT/m (rms) per square root Hz;
 - 3. "Intrinsic magnetic gradiometers", using "technology" other than fibre-optic "technology", having a magnetic gradient field "noise level" (sensitivity) lower (better) than 0.015 nT/m (rms) per square root Hz;

6. A. 6. d. Compensation systems for magnetic or underwater electric field sensors resulting in a performance equal to or better than the control parameters of 6.A.6.a., 6.A.6.b., or 6.A.6.c.

GRAVIMETERS

- 6. A. 7. Gravity meters (gravimeters) and gravity gradiometers, as follows:
 - Gravity meters designed or modified for ground use having a static a. accuracy of less (better) than 10 µgal;
 - 6.A.7.a. does not control ground gravity meters of the quartz Note element (Worden) type.
 - Gravity meters designed for mobile platforms, having all of the following: b.
 - A static accuracy of less (better) than 0.7 mgal; and 1.
 - An in-service (operational) accuracy of less (better) than 0.7 mgal 2. having a time-to-steady-state registration of less than 2 minutes under any combination of attendant corrective compensations and motional influences;
 - c. Gravity gradiometers.

RADAR

- 6. A. 8. Radar systems, equipment and assemblies having any of the following characteristics, and specially designed components therefor: Note
 - 6.A.8. does not control:
 - Secondary surveillance radar (SSR); a.
 - *b. Car radar designed for collision prevention;*
 - Displays or monitors used for air traffic control (ATC) having no с. more than 12 resolvable elements per mm;
 - *d*. Meteorological (weather) radar.
- a. Operating at frequencies from 40 GHz to 230 GHz and having an average 6. A. 8. output power exceeding 100 mW;
 - b. Having a tunable bandwidth exceeding $\pm 6.25\%$ of the centre operating frequency;

Technical Note

The centre operating frequency equals one half of the sum of the highest plus the lowest specified operating frequencies.

- c. Capable of operating simultaneously on more than two carrier frequencies;
- d. Capable of operating in synthetic aperture (SAR), inverse synthetic aperture (ISAR) radar mode, or sidelooking airborne (SLAR) radar mode;
- Incorporating "electronically steerable phased array antennae"; e.
- 6. A. 8. f. Capable of heightfinding non-cooperative targets;

<u>Note</u> 6.A.8.f. does not control precision approach radar (PAR) equipment conforming to ICAO standards.

- g. Specially designed for airborne (balloon or airframe mounted) operation and having Doppler "signal processing" for the detection of moving targets;
- h. Employing processing of radar signals using any of the following:
 - 1. "Radar spread spectrum" techniques; or
 - 2. "Radar frequency agility" techniques;
- i. Providing ground-based operation with a maximum "instrumented range" exceeding 185 km;

<u>Note</u> 6.A.8.i. does not control:

- a. Fishing ground surveillance radar;
- b. Ground radar equipment specially designed for enroute air traffic control, provided that all the following conditions are met:
 - 1. It has a maximum "instrumented range" of 500 km or less;
 - 2. It is configured so that radar target data can be transmitted only one way from the radar site to one or more civil ATC centres;
 - 3. It contains no provisions for remote control of the radar scan rate from the enroute ATC centre; <u>and</u>
 - 4. It is to be permanently installed.
- c. Weather balloon tracking radars.
- 6. A. 8. j. Being "laser" radar or Light Detection and Ranging (LIDAR) equipment, having any of the following:
 - 1. "Space-qualified"; or
 - 2. Employing coherent heterodyne or homodyne detection techniques and having an angular resolution of less (better) than 20 μrad (microradians);
 - <u>Note</u> 6.A.8.j. does not control LIDAR equipment specially designed for surveying or for meteorological observation.
 - k. Having "signal processing" sub-systems using "pulse compression", with any of the following:
 - 1. A "pulse compression" ratio exceeding 150; or
 - 2. A pulse width of less than 200 ns; or
 - 1. Having data processing sub-systems with any of the following:
 - 1. "Automatic target tracking" providing, at any antenna rotation, the predicted target position beyond the time of the next antenna beam passage;

<u>Note</u> 6.A.8.1.1. does not control conflict alert capability in ATC systems, or marine or harbour radar.

2. Calculation of target velocity from primary radar having non-periodic (variable) scanning rates;

- A. 8. 1. 3. Processing for automatic pattern recognition (feature extraction) and comparison with target characteristic data bases (waveforms or imagery) to identify or classify targets; or
 - 4. Superposition and correlation, or fusion, of target data from two or more "geographically dispersed" and "interconnected radar sensors" to enhance and discriminate targets.
 - <u>Note</u> 6.A.8.l.4. does not control systems, equipment and assemblies used for marine traffic control.

6. B. TEST, INSPECTION AND PRODUCTION EQUIPMENT

- 6. B. 1. ACOUSTICS None
- 6. B. 2. <u>OPTICAL SENSORS</u> None
- 6. B. 3. <u>CAMERAS</u> None

OPTICS

- 6. B. 4. Optical equipment, as follows:
 - a. Equipment for measuring absolute reflectance to an accuracy of $\pm 0.1\%$ of the reflectance value;
- 6. B. 4. b. Equipment other than optical surface scattering measurement equipment, having an unobscured aperture of more than 10 cm, specially designed for the non-contact optical measurement of a non-planar optical surface figure (profile) to an "accuracy" of 2 nm or less (better) against the required profile.
 - <u>Note</u> 6.B.4. does not control microscopes.
- 6. B. 5. <u>LASERS</u> None

6. B. 6. MAGNETIC AND ELECTRIC FIELD SENSORS - None

GRAVIMETERS

6. B. 7. Equipment to produce, align and calibrate land-based gravity meters with a static accuracy of better than 0.1 mgal.

<u>RADAR</u>

6. B. 8. Pulse radar cross-section measurement systems having transmit pulse widths of 100 ns or less and specially designed components therefor.

6. C. MATERIALS

6. C. 1. <u>ACOUSTICS</u> - None

OPTICAL SENSORS

- 6. C. 2. Optical sensor materials, as follows:
 - a. Elemental tellurium (Te) of purity levels of 99.9995% or more;
 - b. Single crystals (including epitaxial wafers) of any of the following:
 - 1. Cadmium zinc telluride (CdZnTe) with zinc content of less than 6% by mole fraction;
 - 2. Cadmium telluride (CdTe) of any purity level; or
 - 3. Mercury cadmium telluride (HgCdTe) of any purity level.

Technical Note

Mole fraction is defined as the ratio of moles of ZnTe to the sum of the moles of CdTe and ZnTe present in the crystal.

6. C. 3. <u>CAMERAS</u> - None

OPTICS

- 6. C. 4. Optical materials, as follows:
 - a. Zinc selenide (ZnSe) and zinc sulphide (ZnS) "substrate blanks" produced by the chemical vapour deposition process, having any of the following:
 - 1. A volume greater than 100 cm^3 ; or
 - 2. A diameter greater than 80 mm having a thickness of 20 mm or more;
 - b. Boules of the following electro-optic materials:
 - 1. Potassium titanyl arsenate (KTA);
 - 2. Silver gallium selenide (AgGaSe₂);
 - 3. Thallium arsenic selenide (Tl3AsSe3, also known as TAS);
 - c. Non-linear optical materials, having all of the following:
 - 1. Third order susceptibility (chi 3) of 10^{-6} m²/V² or more; and
 - 2. A response time of less than 1 ms;
 - d. "Substrate blanks" of silicon carbide or beryllium beryllium (Be/Be) deposited materials exceeding 300 mm in diameter or major axis length;

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- 6. C. 4. e. Glass, including fused silica, phosphate glass, fluorophosphate glass, zirconium fluoride (ZrF4) and hafnium fluoride (HfF4), having all of the following:
 - 1. A hydroxyl ion (OH-) concentration of less than 5 ppm;
 - 2. Integrated metallic purity levels of less than 1 ppm; and
 - 3. High homogeneity (index of refraction variance) less than 5×10^{-6} ;
 - f. Synthetically produced diamond material with an absorption of less than 10^{-5} cm⁻¹ for wavelengths exceeding 200 nm but not exceeding 14,000 nm.

LASERS

- 6. C. 5. Synthetic crystalline "laser" host material in unfinished form, as follows:
 - a. Titanium doped sapphire;
 - b. Alexandrite.
- 6. C. 6. MAGNETIC AND ELECTRIC FIELD SENSORS None
- 6. C. 7. <u>GRAVIMETERS</u> None
- 6. C. 8. <u>RADAR</u> None

6. D. <u>SOFTWARE</u>

- 1. "Software" specially designed for the "development" or "production" of equipment controlled by 6.A.4, 6.A.5., 6.A.8 or 6.B.8.
- 2. "Software" specially designed for the "use" of equipment controlled by 6.A.2.b., 6.A.8 or 6.B.8.
- 3. Other "software", as follows:

ACOUSTICS

- 6. D. 3. a. "Software", as follows:
 - 1. "Software" specially designed for acoustic beam forming for the "real time processing" of acoustic data for passive reception using towed hydrophone arrays;
 - 2. "Source code" for the "real time processing" of acoustic data for passive reception using towed hydrophone arrays;
 - 3. "Software" specially designed for acoustic beam forming for the "real time processing" of acoustic data for passive reception using bottom or bay cable systems;
 - 4. "Source code" for the "real time processing" of acoustic data for passive reception using bottom or bay cable systems;

DUAL-USE LIST - CATEGORY 6 - SENSORS AND "LASERS"

6. D. 3. b. OPTICAL SENSORS - None

- c. <u>CAMERAS</u> None
- d. <u>OPTICS</u> None
- e. <u>LASERS</u> None

MAGNETIC AND ELECTRIC FIELD SENSORS

- f. "Software", as follows:
 - 1. "Software" specially designed for magnetic and electric field compensation systems for magnetic sensors designed to operate on mobile platforms;
 - 2. "Software" specially designed for magnetic and electric field anomaly detection on mobile platforms;

GRAVIMETERS

6. D. 3. g. "Software" specially designed to correct motional influences of gravity meters or gravity gradiometers;

RADAR

- 6. D. 3. h. "Software", as follows:
 - 1. Air Traffic Control "software" application "programmes" hosted on general purpose computers located at Air Traffic Control centres and capable of any of the following:
 - a. Processing and displaying more than 150 simultaneous "system tracks"; or
 - b. Accepting radar target data from more than four primary radars;
 - 2. "Software" for the design or "production" of radomes which:
 - a. Are specially designed to protect the "electronically steerable phased array antennae" controlled by 6.A.8.e.; and
 - b. Result in an antenna pattern having an 'average side lobe level' more than 40 dB below the peak of the main beam level. *Technical Note*

'Average side lobe level' in 6.D.3.h.2.b. is measured over the entire array excluding the angular extent of the main beam and the first two side lobes on either side of the main beam.

DUAL-USE LIST - CATEGORY 6 - SENSORS AND "LASERS"

6. E. <u>TECHNOLOGY</u>

- 6. E. 1. "Technology" according to the General Technology Note for the "development" of equipment, materials or "software" controlled by 6.A., 6.B., 6.C. or 6.D.
- 6. E. 2. "Technology" according to the General Technology Note for the "production" of equipment or materials controlled by 6.A., 6.B. or 6.C.
- 6. E. 3. Other "technology", as follows:
 - a. <u>ACOUSTICS</u> None
 - b. <u>OPTICAL SENSORS</u> None
 - c. <u>CAMERAS</u> None

OPTICS

- 6. E. 3. d. "Technology", as follows:
 - 1. Optical surface coating and treatment "technology" "required" to achieve uniformity of 99.5% or better for optical coatings 500 mm or more in diameter or major axis length and with a total loss (absorption and scatter) of less than 5×10^{-3} ; *N.B.* See also 2.E.3.f.
 - 2. Optical fabrication "technology" using single point diamond turning techniques to produce surface finish accuracies of better than 10 nm rms on non-planar surfaces exceeding 0.5 m²;

LASERS

6. E. 3. e. "Technology" "required" for the "development", "production" or "use" of specially designed diagnostic instruments or targets in test facilities for "SHPL" testing or testing or evaluation of materials irradiated by "SHPL" beams;

MAGNETIC AND ELECTRIC FIELD SENSORS

- 6. E. 3. f. Deleted
- 6. E. 3. g. <u>GRAVIMETERS</u> None
- 6. E. 3. h. <u>RADAR</u> None

7. A. SYSTEMS, EQUIPMENT AND COMPONENTS

<u>N.B</u> For automatic pilots for underwater vehicles, see Category 8. For radar, see Category 6.

- 7. A. 1. Linear accelerometers designed for use in inertial navigation or guidance systems and having any of the following characteristics, and specially designed components therefor:
 - a. A "bias" "stability" of less (better) than 130 micro g with respect to a fixed calibration value over a period of one year;
 - b. A "scale factor" "stability" of less (better) than 130 ppm with respect to a fixed calibration value over a period of one year; <u>or</u>
 - c. Specified to function at linear acceleration levels exceeding 100 g.

<u>N.B.</u> For angular or rotational accelerometers, see 7.A.2.

- 7. A. 2. Gyros, and angular or rotational accelerometers, having any of the following characteristics, and specially designed components therefor:
 - a. A "drift rate" "stability", when measured in a 1 g environment over a period of one month and with respect to a fixed calibration value, of:
 - 1. Less (better) than 0.1 degree per hour when specified to function at linear acceleration levels below 12 g; or
 - 2. Less (better) than 0.5 degree per hour when specified to function at linear acceleration levels from 12 g to 100 g inclusive;
 - b. An angle random walk of less (better) than or equal to 0.0035 degree per square root hour; or
 - <u>Note</u> 7.A.2.b. does not control spinning mass gyros (spinning mass gyros are gyros which use a continually rotating mass to sense angular motion).

Technical Note

For the purpose of 7.A.2.b., 'angle random walk' is the angular error buildup with time that is due to white noise in angular rate. (IEEE STD 528-2001)

- c. Specified to function at linear acceleration levels exceeding 100 g.
- 7. A. 3. Inertial Systems and specially designed components, as follows:
 - a. Inertial Navigation Systems (INS) (gimballed or strapdown) and inertial equipment designed for "aircraft", land vehicles, vessels (surface or underwater) or "spacecraft", for attitude, guidance or control, having any of the following characteristics, and specially designed components therefor:
 - 1. Navigation error (free inertial) subsequent to normal alignment of 0.8 nautical mile per hour (nm/hr) Circular Error Probable (CEP) or less (better); or
 - 2. Specified to function at linear acceleration levels exceeding 10 g.
 - b. Hybrid Inertial Navigation Systems embedded with Global Navigation Satellite System(s) (GNSS) or with "Data-Based Referenced Navigation" ("DBRN") System(s) for attitude, guidance or control, subsequent to normal alignment, having an INS navigation position accuracy, after loss of GNSS or "DBRN" for a period of up to 4 minutes, of less (better) than 10 meters CEP.

- 7. A. 3. c. Inertial Equipment for Azimuth, Heading, or North Pointing having any of the following characteristics, and specially designed components therefor:
 - 1. Designed to have an Azimuth, Heading, or North Pointing accuracy equal to, or less (better) than 6 arc minutes RMS at 45 degrees latitude; <u>or</u>
 - 2. Designed to have a non-operating shock level of 900 g or greater at a duration of 1-msec, or greater.
 - <u>Note 1</u> The parameters of 7.A.3.a. and 7.A.3.b. are applicable with any of the following environmental conditions:
 - 1. Input random vibration with an overall magnitude of 7.7 g rms in the first half hour and a total test duration of one and one half hour per axis in each of the three perpendicular axes, when the random vibration meets the following:
 - a. A constant power spectral density (PSD) value of 0.04 g^2/Hz over a frequency interval of 15 to 1,000 Hz; and
 - b. The PSD attenuates with frequency from $0.04 g^2/Hz$ to $0.01 g^2/Hz$ over a frequency interval from 1,000 to 2,000 Hz;
 - 2. A roll and yaw rate of equal to or more than +2.62 rad (radians)/s (150 deg/s); or
 - 3. According to national standards equivalent to 1. or 2. above.
 - <u>Note 2</u> 7.A.3. does not control inertial navigation systems which are certified for use on "civil aircraft" by civil authorities of a participating state.
 - <u>Note 3</u> 7.A.3.c.1 does not control theodolite systems incorporating inertial equipment specially designed for civil surveying purposes.

Technical Notes

- 1. 7.A.3.b. refers to systems in which an INS and other independent navigation aids are built into a single unit (embedded) in order to achieve improved performance.
- 2. 'Circular Error Probable' ('CEP') In a circular normal distribution, the radius of the circle containing 50 percent of the individual measurements being made, or the radius of the circle within which there is a 50 percent probability of being located.
- 7. A. 4. Gyro-astro compasses, and other devices which derive position or orientation by means of automatically tracking celestial bodies or satellites, with an azimuth accuracy of equal to or less (better) than 5 seconds of arc.
- 7. A. 5. Global navigation satellite systems (i.e., GPS or GLONASS) receiving equipment having any of the following characteristics, and specially designed components therefor:
 - a. Employing decryption; or
 - b. A null-steerable antenna.

- 7. A. 6. Airborne altimeters operating at frequencies other than 4.2 to 4.4 GHz inclusive, having any of the following characteristics:
 - a. "Power management"; or
 - b. Using phase shift key modulation.
- 7. A. 7. Deleted

7. B. TEST, INSPECTION AND PRODUCTION EQUIPMENT

7. B. 1. Test, calibration or alignment equipment specially designed for equipment controlled by 7.A.

Technical Notes

1. <u>Maintenance Level I</u>

The failure of an inertial navigation unit is detected on the aircraft by indications from the control and display unit (CDU) or by the status message from the corresponding sub-system. By following the manufacturer's manual, the cause of the failure may be localised at the level of the malfunctioning line replaceable unit (LRU). The operator then removes the LRU and replaces it with a spare.

2. <u>Maintenance Level II</u>

The defective LRU is sent to the maintenance workshop (the manufacturer's or that of the operator responsible for level II maintenance). At the maintenance workshop, the malfunctioning LRU is tested by various appropriate means to verify and localise the defective shop replaceable assembly (SRA) module responsible for the failure. This SRA is removed and replaced by an operative spare. The defective SRA (or possibly the complete LRU) is then shipped to the manufacturer. Maintenance Level II does not include the removal of controlled accelerometers or gyro sensors from the SRA.

- 7. B. 2. Equipment, as follows, specially designed to characterize mirrors for ring "laser" gyros:
 - a. Scatterometers having a measurement accuracy of 10 ppm or less (better);
 - b. Profilometers having a measurement accuracy of 0.5 nm (5 angstrom) or less (better).
- 7. B. 3. Equipment specially designed for the "production" of equipment controlled by 7.A.
 - <u>Note</u> 7.B.3 includes:
 - a. Gyro tuning test stations;
 - b. Gyro dynamic balance stations;
 - c. Gyro run-in/motor test stations;
 - d. Gyro evacuation and fill stations;
 - e. Centrifuge fixtures for gyro bearings;
 - f. Accelerometer axis align stations.

<u>Note</u> 7.B.1. does not control test, calibration or alignment equipment for Maintenance Level I or Maintenance Level II.

7. C. MATERIALS - None

7. D. SOFTWARE

- "Software" specially designed or modified for the "development" or 7. D. 1. "production" of equipment controlled by 7.A. or 7.B.
- 7. D. 2. "Source code" for the "use" of any inertial navigation equipment, including inertial equipment not controlled by 7.A.3. or 7.A.4., or Attitude and Heading Reference Systems (AHRS).

7.D.2. does not control "source code" for the "use" of gimballed AHRS. Note

Technical Note

AHRS generally differ from inertial navigation systems (INS) in that an AHRS provides attitude and heading information and normally does not provide the acceleration, velocity and position information associated with an INS.

- 7. D. 3. Other "software", as follows:
 - "Software" specially designed or modified to improve the operational a performance or reduce the navigational error of systems to the levels specified in 7.A.3. or 7.A.4.;
 - b. "Source code" for hybrid integrated systems which improves the operational performance or reduces the navigational error of systems to the level specified in 7.A.3. by continuously combining inertial data with any of the following:
 - 1. Doppler radar velocity data;
 - Global navigation satellite systems (i.e., GPS or GLONASS) 2. reference data: or
 - 3. Data from "Data-Based Referenced Navigation" ("DBRN") systems;
 - "Source code" for integrated avionics or mission systems which combine c. sensor data and employ "expert systems";
 - d. "Source code" for the "development" of any of the following:
 - Digital flight management systems for "total control of flight"; 1.
 - 2. Integrated propulsion and flight control systems;
 - Fly-by-wire or fly-by-light control systems; 3.
 - Fault-tolerant or self-reconfiguring "active flight control systems"; 4.
 - Airborne automatic direction finding equipment; 5.
 - Air data systems based on surface static data; or 6.
 - 7. Raster-type head-up displays or three dimensional displays;
 - e. Computer-aided-design (CAD) "software" specially designed for the "development" of "active flight control systems", helicopter multi-axis flyby-wire or fly-by-light controllers or helicopter "circulation controlled antitorque or circulation-controlled direction control systems" whose "technology" is controlled in 7.E.4.b., 7.E.4.c.1. or 7.E.4.c.2.

7. E. <u>TECHNOLOGY</u>

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- 1. "Technology" according to the General Technology Note for the "development" of equipment or "software" controlled by 7.A., 7.B. or 7.D.
- 7. E. 2. "Technology" according to the General Technology Note for the "production" of equipment controlled by 7.A. or 7.B.
- 7. E. 3. "Technology" according to the General Technology Note for the repair, refurbishing or overhaul of equipment controlled by 7.A.1. to 7.A.4.
 - <u>Note</u> 7.E.3. does not control maintenance "technology" directly associated with calibration, removal or replacement of damaged or unserviceable LRUs and SRAs of a "civil aircraft" as described in Maintenance Level I or Maintenance Level II. N.B. See Technical Notes to 7.B.1.
- 7. E. 4. Other "technology", as follows:
 - a. "Technology" for the "development" or "production" of:
 - 1. Airborne automatic direction finding equipment operating at frequencies exceeding 5 MHz;
 - 2. Air data systems based on surface static data only, i.e., which dispense with conventional air data probes;
 - 3. Raster-type head-up displays or three dimensional displays for "aircraft";
 - 4. Inertial navigation systems or gyro-astro compasses containing accelerometers or gyros controlled by 7.A.1. or 7.A.2.;
 - 5. Electric actuators (i.e., electromechanical, electrohydrostatic and integrated actuator package) specially designed for "primary flight control";
 - 6. "Flight control optical sensor array" specially designed for implementing "active flight control systems";
- 7. E. 4. b. "Development" "technology", as follows, for "active flight control systems" (including fly-by-wire or fly-by-light):
 - 1. Configuration design for interconnecting multiple microelectronic processing elements (on-board computers) to achieve "real time processing" for control law implementation;
 - 2. Control law compensation for sensor location or dynamic airframe loads, i.e., compensation for sensor vibration environment or for variation of sensor location from the centre of gravity;
 - 3. Electronic management of data redundancy or systems redundancy for fault detection, fault tolerance, fault isolation or reconfiguration;
 - <u>Note</u> 7.E.4.b.3. does not control" technology" for the design of physical redundancy.

- 7. E. 4. b. 4. Flight controls which permit inflight reconfiguration of force and moment controls for real time autonomous air vehicle control;
 - 5. Integration of digital flight control, navigation and propulsion control data into a digital flight management system for "total control of flight";
 - <u>Note</u> 7.E.4.b.5. does not control:
 - 1. "Development" "technology" for integration of digital flight control, navigation and propulsion control data into a digital flight management system for "flight path optimisation";
 - 2. "Development" "technology" for "aircraft" flight instrument systems integrated solely for VOR, DME, ILS or MLS navigation or approaches.
 - 6. Full authority digital flight control or multisensor mission management systems employing "expert systems";
 - <u>N.B.</u> For "technology" for Full Authority Digital Engine Control ("FADEC"), see 9.E.3.a.9.
- 7. E. 4. c. "Technology" for the "development" of helicopter systems, as follows:
 - 1. Multi-axis fly-by-wire or fly-by-light controllers which combine the functions of at least two of the following into one controlling element:
 - a. Collective controls;
 - b. Cyclic controls;
 - c. Yaw controls;
 - 2. "Circulation-controlled anti-torque or circulation-controlled directional control systems";
 - 3. Rotor blades incorporating "variable geometry airfoils" for use in systems using individual blade control.

8. A. SYSTEMS, EQUIPMENT AND COMPONENTS

- 8. A. 1. Submersible vehicles and surface vessels, as follows:
 - <u>N.B.</u> For the control status of equipment for submersible vehicles, see: Category 5, Part 2 "Information Security" for encrypted communication equipment; Category 6 for sensors; Categories 7 and 8 for navigation equipment; Category 8.A. for underwater equipment.
- 8. A. 1. a. Manned, tethered submersible vehicles designed to operate at depths exceeding 1,000 m;
- 8. A. 1. b. Manned, untethered submersible vehicles, having any of the following:
 - 1. Designed to operate autonomously and having a lifting capacity of all the following:
 - a. 10% or more of their weight in air; and
 - b. 15 kN or more;
 - 2. Designed to operate at depths exceeding 1,000 m; or
 - 3. Having all of the following:
 - a. Designed to carry a crew of 4 or more;
 - b. Designed to operate autonomously for 10 hours or more;
 - c. Having a range of 25 nautical miles or more; and
 - d. Having a length of 21 m or less;

Technical Notes

- 1. For the purposes of 8.A.1.b., operate autonomously means fully submerged, without snorkel, all systems working and cruising at minimum speed at which the submersible can safely control its depth dynamically by using its depth planes only, with no need for a support vessel or support base on the surface, sea-bed or shore, and containing a propulsion system for submerged or surface use.
- 2. For the purposes of 8.A.1.b., range means half the maximum distance a submersible vehicle can cover.
- 8. A. 1. c. Unmanned, tethered submersible vehicles designed to operate at depths exceeding 1,000 m, having any of the following:
 - 1. Designed for self-propelled manoeuvre using propulsion motors or thrusters controlled by 8.A.2.a.2.; or
 - 2. Having a fibre optic data link;

- 8. A. 1. d. Unmanned, untethered submersible vehicles, having any of the following:
 - 1. Designed for deciding a course relative to any geographical reference without real-time human assistance;
 - 2. Having an acoustic data or command link; or
 - 3. Having a fibre optic data or command link exceeding 1,000 m;
- 8. A. 1. e. Ocean salvage systems with a lifting capacity exceeding 5 MN for salvaging objects from depths exceeding 250 m and having any of the following:
 - 1. Dynamic positioning systems capable of position keeping within 20 m of a given point provided by the navigation system; <u>or</u>
 - 2. Seafloor navigation and navigation integration systems for depths exceeding 1,000 m with positioning accuracies to within 10 m of a predetermined point;
- 8. A. 1. f. Surface-effect vehicles (fully skirted variety) having all of the following characteristics:
 - 1. A maximum design speed, fully loaded, exceeding 30 knots in a significant wave height of 1.25 m (Sea State 3) or more;
 - 2. A cushion pressure exceeding 3,830 Pa; and
 - 3. A light-ship-to-full-load displacement ratio of less than 0.70;
- 8. A. 1. g. Surface-effect vehicles (rigid sidewalls) with a maximum design speed, fully loaded, exceeding 40 knots in a significant wave height of 3.25 m (Sea State 5) or more;
- 8. A. 1. h. Hydrofoil vessels with active systems for automatically controlling foil systems, with a maximum design speed, fully loaded, of 40 knots or more in a significant wave height of 3.25 m (Sea State 5) or more;
- 8. A. 1. i. Small waterplane area vessels having any of the following:
 - 1. A full load displacement exceeding 500 tonnes with a maximum design speed, fully loaded, exceeding 35 knots in a significant wave height of 3.25 m (Sea State 5) or more; or
 - 2. A full load displacement exceeding 1,500 tonnes with a maximum design speed, fully loaded, exceeding 25 knots in a significant wave height of 4 m (Sea State 6) or more.

Technical Note

A small waterplane area vessel is defined by the following formula: waterplane area at an operational design draft less than 2x (displaced volume at the operational design draft)^{2/3}.

8. A. 2. Systems and equipment, as follows:

- <u>N.B.</u> For underwater communications systems, see Category 5, Part 1 -Telecommunications.
- 8. A. 2. a. Systems and equipment, specially designed or modified for submersible vehicles, designed to operate at depths exceeding 1,000 m, as follows:
 - 1. Pressure housings or pressure hulls with a maximum inside chamber diameter exceeding 1.5 m;
 - 2. Direct current propulsion motors or thrusters;
 - 3. Umbilical cables, and connectors therefor, using optical fibre and having synthetic strength members;
- 8. A. 2. b. Systems specially designed or modified for the automated control of the motion of submersible vehicles controlled by 8.A.1. using navigation data and having closed loop servo-controls:
 - 1. Enabling a vehicle to move within 10 m of a predetermined point in the water column;
 - 2. Maintaining the position of the vehicle within 10 m of a predetermined point in the water column; or
 - 3. Maintaining the position of the vehicle within 10 m while following a cable on or under the seabed;
- 8. A. 2. c. Fibre optic hull penetrators or connectors;
- 8. A. 2. d. Underwater vision systems, as follows:
 - 1. Television systems and television cameras, as follows:
 - a. Television systems (comprising camera, monitoring and signal transmission equipment) having a limiting resolution when measured in air of more than 800 lines and specially designed or modified for remote operation with a submersible vehicle;
 - b. Underwater television cameras having a limiting resolution when measured in air of more than 1,100 lines;
 - c. Low light level television cameras specially designed or modified for underwater use containing all of the following:
 - 1. Image intensifier tubes controlled by 6.A.2.a.2.a.; and
 - 2. More than 150,000 "active pixels" per solid state area array;

Technical Note

Limiting resolution in television is a measure of horizontal resolution usually expressed in terms of the maximum number of lines per picture height discriminated on a test chart, using IEEE Standard 208/1960 or any equivalent standard.

8. A. 2. d. 2. Systems, specially designed or modified for remote operation with an underwater vehicle, employing techniques to minimise the effects of back scatter, including range-gated illuminators or "laser" systems;

- 8. A. 2. e. Photographic still cameras specially designed or modified for underwater use below 150 m having a film format of 35 mm or larger, and having any of the following:
 - 1. Annotation of the film with data provided by a source external to the camera;
 - 2. Automatic back focal distance correction; or
 - 3. Automatic compensation control specially designed to permit an underwater camera housing to be usable at depths exceeding 1,000 m;

 A. 2. f. Electronic imaging systems, specially designed or modified for underwater use, capable of storing digitally more than 50 exposed images; <u>Note</u> 8.A.2.f. does not control digital cameras specially designed for

51e 8.A.2.J. does not control algital cameras specially designed for consumer purposes, other than those employing electronic image multiplication techniques.

- 8. A. 2. g. Light systems, as follows, specially designed or modified for underwater use:
 - 1. Stroboscopic light systems capable of a light output energy of more than 300 J per flash and a flash rate of more than 5 flashes per second;
 - 2. Argon arc light systems specially designed for use below 1,000 m;
- 8. A. 2. h. "Robots" specially designed for underwater use, controlled by using a dedicated computer, having any of the following:
 - 1. Systems that control the "robot" using information from sensors which measure force or torque applied to an external object, distance to an external object, or tactile sense between the "robot" and an external object; or
 - The ability to exert a force of 250 N or more or a torque of 250 Nm or more and using titanium based alloys or "fibrous or filamentary" "composite" materials in their structural members;
- 8. A. 2. i. Remotely controlled articulated manipulators specially designed or modified for use with submersible vehicles, having any of the following:
 - 1. Systems which control the manipulator using the information from sensors which measure the torque or force applied to an external object, or tactile sense between the manipulator and an external object; <u>or</u>
 - 2. Controlled by proportional master-slave techniques or by using a dedicated computer, and having 5 degrees of freedom of movement or more;
 - <u>Note</u> Only functions having proportional control using positional feedback or by using a dedicated computer are counted when determining the number of degrees of freedom of movement.

- 8. A. 2. j. Air independent power systems, specially designed for underwater use, as follows:
 - 1. Brayton or Rankine cycle engine air independent power systems having any of the following:
 - a. Chemical scrubber or absorber systems specially designed to remove carbon dioxide, carbon monoxide and particulates from recirculated engine exhaust;
 - b. Systems specially designed to use a monoatomic gas;
 - c. Devices or enclosures specially designed for underwater noise reduction in frequencies below 10 kHz, or special mounting devices for shock mitigation; or
 - d. Systems specially designed:
 - 1. To pressurise the products of reaction or for fuel reformation;
 - 2. To store the products of the reaction; and
 - 3. To discharge the products of the reaction against a pressure of 100 kPa or more;
- 8. A. 2. j. 2. Diesel cycle engine air independent systems, having all of the following:
 - a. Chemical scrubber or absorber systems specially designed to remove carbon dioxide, carbon monoxide and particulates from recirculated engine exhaust;
 - b. Systems specially designed to use a monoatomic gas;
 - c. Devices or enclosures specially designed for underwater noise reduction in frequencies below 10 kHz or special mounting devices for shock mitigation; and
 - d. Specially designed exhaust systems that do not exhaust continuously the products of combustion;
- 8. A. 2. j. 3. Fuel cell air independent power systems with an output exceeding 2 kW having any of the following:
 - a. Devices or enclosures specially designed for underwater noise reduction in frequencies below 10 kHz or special mounting devices for shock mitigation; or
 - b. Systems specially designed:
 - 1. To pressurise the products of reaction or for fuel reformation;
 - 2. To store the products of the reaction; and
 - 3. To discharge the products of the reaction against a pressure of 100 kPa or more;
- 8. A. 2. j. 4. Stirling cycle engine air independent power systems, having all of the following:
 - a. Devices or enclosures specially designed for underwater noise reduction in frequencies below 10 kHz or special mounting devices for shock mitigation; and
 - b. Specially designed exhaust systems which discharge the products of combustion against a pressure of 100 kPa or more;
- 8. A. 2. k. Skirts, seals and fingers, having any of the following:

- 1. Designed for cushion pressures of 3,830 Pa or more, operating in a significant wave height of 1.25 m (Sea State 3) or more and specially designed for surface effect vehicles (fully skirted variety) controlled by 8.A.1.f.; or
- 2. Designed for cushion pressures of 6,224 Pa or more, operating in a significant wave height of 3.25 m (Sea State 5) or more and specially designed for surface effect vehicles (rigid sidewalls) controlled by 8.A.1.g.;
- 8. A. 2. 1. Lift fans rated at more than 400 kW specially designed for surface effect vehicles controlled by 8.A.1.f. or 8.A.1.g.;
- 8. A. 2. m. Fully submerged subcavitating or supercavitating hydrofoils specially designed for vessels controlled by 8.A.1.h.;
- 8. A. 2. n. Active systems specially designed or modified to control automatically the sea-induced motion of vehicles or vessels controlled by 8.A.1.f., 8.A.1.g., 8.A.1.h. or 8.A.1.i.;
- 8. A. 2. o. Propellers, power transmission systems, power generation systems and noise reduction systems, as follows:
 - 1. Water-screw propeller or power transmission systems, as follows, specially designed for surface effect vehicles (fully skirted or rigid sidewall variety), hydrofoils or small waterplane area vessels controlled by 8.A.1.f., 8.A.1.g., .8.A.1.h. or 8.A.1.i.:
 - a. Supercavitating, super-ventilated, partially-submerged or surface piercing propellers rated at more than 7.5 MW;
 - b. Contrarotating propeller systems rated at more than 15 MW;
 - c. Systems employing pre-swirl or post-swirl techniques for smoothing the flow into a propeller;
 - d. Light-weight, high capacity (K factor exceeding 300) reduction gearing;
 - e. Power transmission shaft systems, incorporating "composite" material components, capable of transmitting more than 1 MW;
 - 2. Water-screw propeller, power generation systems or transmission systems designed for use on vessels, as follows:
 - a. Controllable-pitch propellers and hub assemblies rated at more than 30 MW;
 - b. Internally liquid-cooled electric propulsion engines with a power output exceeding 2.5 MW;
 - c. "Superconductive" propulsion engines, or permanent magnet electric propulsion engines, with a power output exceeding 0.1 MW;
 - d. Power transmission shaft systems, incorporating "composite" material components, capable of transmitting more than 2 MW;
 - e. Ventilated or base-ventilated propeller systems rated at more than 2.5 MW;
- 8. A. 2. o. 3. Noise reduction systems designed for use on vessels of 1,000 tonnes displacement or more, as follows:

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- a. Systems that attenuate underwater noise at frequencies below 500 Hz and consist of compound acoustic mounts for the acoustic isolation of diesel engines, diesel generator sets, gas turbines, gas turbine generator sets, propulsion motors or propulsion reduction gears, specially designed for sound or vibration isolation, having an intermediate mass exceeding 30% of the equipment to be mounted;
- b. Active noise reduction or cancellation systems, or magnetic bearings, specially designed for power transmission systems, and incorporating electronic control systems capable of actively reducing equipment vibration by the generation of anti-noise or anti-vibration signals directly to the source;
- 8. A. 2. p. Pumpjet propulsion systems having a power output exceeding 2.5 MW using divergent nozzle and flow conditioning vane techniques to improve propulsive efficiency or reduce propulsion-generated underwater-radiated noise;
- 8. A. 2. q. Self-contained, closed or semi-closed circuit (rebreathing) diving and underwater swimming apparatus.
 <u>Note</u> 8.A.2.q. does not control an individual apparatus for personal use when accompanying its user.

8. B. TEST, INSPECTION AND PRODUCTION EQUIPMENT

B. 1. Water tunnels, having a background noise of less than 100 dB (reference 1 μPa, 1 Hz) in the frequency range from 0 to 500 Hz, designed for measuring acoustic fields generated by a hydro-flow around propulsion system models.

8. C. MATERIALS

- 8. C. 1. Syntactic foam designed for underwater use, having all of the following:
 - a. Designed for marine depths exceeding 1,000 m; and
 - b. A density less than 561 kg/m³.

Technical Note

Syntactic foam consists of hollow spheres of plastic or glass embedded in a resin matrix.

8. D. SOFTWARE

- 8. D. 1. "Software" specially designed or modified for the "development", "production" or "use" of equipment or materials controlled by 8.A., 8.B. or 8.C.
- 8. D. 2. Specific "software" specially designed or modified for the "development", "production", repair, overhaul or refurbishing (re-machining) of propellers specially designed for underwater noise reduction.

8. E. <u>TECHNOLOGY</u>

- 8. E. 1. "Technology" according to the General Technology Note for the "development" or "production" of equipment or materials controlled by 8.A., 8.B. or 8.C.
- 8. E. 2. Other "technology", as follows:
 - a. "Technology" for the "development", "production", repair, overhaul or refurbishing (re-machining) of propellers specially designed for underwater noise reduction;
 - b. "Technology" for the overhaul or refurbishing of equipment controlled by 8.A.1., 8.A.2.b., 8.A.2.j., 8.A.2.o. or 8.A.2.p.

9. A. SYSTEMS, EQUIPMENT AND COMPONENTS

<u>N.B.</u> For propulsion systems designed or rated against neutron or transient ionizing radiation, see the Munitions List.^{*}

- 9. A. 1. Aero gas turbine engines having any of the following:
 - a. Incorporating any of the technologies controlled by 9.E.3.a.; or
 - <u>Note</u> 9.A.1.a. does not control aero gas turbine engines which meet all of the following:
 - 1. Certified by the civil aviation authority in a Participating State; <u>and</u>
 - 2. Intended to power non-military manned aircraft for which one of the following has been issued by a Participating State for the aircraft with this specific engine type:
 - a. A civil Type Certificate; or
 - b. An equivalent document recognised by the International Civil Aviation Organisation (ICAO).
 - b. Designed to power an aircraft designed to cruise at Mach 1 or higher for more than 30 minutes.
- 9. A. 2. Marine gas turbine engines with an ISO standard continuous power rating of 24,245 kW or more and a specific fuel consumption not exceeding 0.219 kg/kWh in the power range from 35 to 100%, and specially designed assemblies and components therefor.
 - <u>Note</u> The term 'marine gas turbine engines' includes those industrial, or aero-derivative, gas turbine engines adapted for a ship's electric power generation or propulsion.
- 9. A. 3. Specially designed assemblies and components, incorporating any of the "technologies" controlled by 9.E.3.a., for the following gas turbine engine propulsion systems:
 - a. Controlled by 9.A.1.;
 - b. Whose design or production origins are either non-participating states or unknown to the manufacturer.
- 9. A. 4. Space launch vehicles and "spacecraft".

Note

9.A.4. does not control payloads.

- <u>N.B.</u> For the control status of products contained in "spacecraft" payloads, see the appropriate Categories.
- 9. A. 5. Liquid rocket propulsion systems containing any of the systems or components controlled by 9.A.6.
- 9. A. 6. Systems and components specially designed for liquid rocket propulsion systems, as follows:

^{*} France, the Russian Federation and Ukraine view this list as reference drawn up to help in the selection of dual-use goods which could contribute to the indigenous development, production or enhancement of conventional munitions capabilities.

- 9. A. 6. a. Cryogenic refrigerators, flightweight dewars, cryogenic heat pipes or cryogenic systems specially designed for use in space vehicles and capable of restricting cryogenic fluid losses to less than 30% per year;
 - b. Cryogenic containers or closed-cycle refrigeration systems capable of providing temperatures of 100 K (-173°C) or less for "aircraft" capable of sustained flight at speeds exceeding Mach 3, launch vehicles or "spacecraft";
 - c. Slush hydrogen storage or transfer systems;
 - d. High pressure (exceeding 17.5 MPa) turbo pumps, pump components or their associated gas generator or expander cycle turbine drive systems;
 - e. High-pressure (exceeding 10.6 MPa) thrust chambers and nozzles therefor;
 - f. Propellant storage systems using the principle of capillary containment or positive expulsion (i.e., with flexible bladders);
 - g. Liquid propellant injectors, with individual orifices of 0.381 mm or smaller in diameter (an area of 1.14 x 10⁻³ cm² or smaller for non-circular orifices) specially designed for liquid rocket engines;
 - h. One-piece carbon-carbon thrust chambers or one-piece carbon-carbon exit cones with densities exceeding 1.4 g/cm³ and tensile strengths exceeding 48 MPa.
- 9. A. 7. Solid rocket propulsion systems with any of the following:
 - a. Total impulse capacity exceeding 1.1 MNs;
 - b. Specific impulse of 2.4 kNs/kg or more when the nozzle flow is expanded to ambient sea level conditions for an adjusted chamber pressure of 7 MPa;
 - c. Stage mass fractions exceeding 88% and propellant solid loadings exceeding 86%;
 - d. Any of the components controlled by 9.A.8.; or
 - e. Insulation and propellant bonding systems using direct-bonded motor designs to provide a strong mechanical bond or a barrier to chemical migration between the solid propellant and case insulation material. *Technical Note*

For the purposes of 9.A.7.e., a strong mechanical bond means bond strength equal to or more than propellant strength.

- 9. A. 8. Components, as follows, specially designed for solid rocket propulsion systems:
 - Insulation and propellant bonding systems using liners to provide a strong mechanical bond or a barrier to chemical migration between the solid propellant and case insulation material; <u>Technical Note</u>

For the purposes of 9.A.8.a., a strong mechanical bond means bond strength equal to or more than propellant strength.

 b. Filament-wound "composite" motor cases exceeding 0.61 m in diameter or having structural efficiency ratios (PV/W) exceeding 25 km. <u>Technical Note</u>

The structural efficiency ratio (PV/W) is the burst pressure (P) multiplied by the vessel volume (V) divided by the total pressure vessel weight (W).

- c. Nozzles with thrust levels exceeding 45 kN or nozzle throat erosion rates of less than 0.075 mm/s;
- 9. A. 8. d. Movable nozzle or secondary fluid injection thrust vector control systems capable of any of the following:

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- 1. Omni-axial movement exceeding $\pm 5^{\circ}$;
- 2. Angular vector rotations of 20°/s or more; or
- 3. Angular vector accelerations of $40^{\circ}/s^2$ or more.
- 9. A. 9. Hybrid rocket propulsion systems with:
 - a. Total impulse capacity exceeding 1.1 MNs; or
 - b. Thrust levels exceeding 220 kN in vacuum exit conditions.
- 9. A. 10. Specially designed components, systems and structures for launch vehicles, launch vehicle propulsion systems or "spacecraft", as follows:
 - a. Components and structures each exceeding 10 kg, specially designed for launch vehicles manufactured using metal "matrix", "composite", organic "composite", ceramic "matrix" or intermetallic reinforced materials controlled by 1.C.7. or 1.C.10.;

<u>Note</u> The weight cut-off is not relevant for nose cones.

- b. Components and structures specially designed for launch vehicle propulsion systems controlled by 9.A.5 to 9.A.9. manufactured using metal matrix, composite, organic composite, ceramic matrix or intermetallic reinforced materials controlled by 1.C.7. or 1.C.10.;
- c. Structural components and isolation systems specially designed to control actively the dynamic response or distortion of "spacecraft" structures;
- d. Pulsed liquid rocket engines with thrust-to-weight ratios equal to or more than 1 kN/kg and a response time (the time required to achieve 90% of total rated thrust from start-up) of less than 30 ms.
- 9. A. 11. Ramjet, scramjet or combined cycle engines and specially designed components therefor.
- 9. A. 12. "Unmanned Aerial Vehicles" ("UAVs"), associated systems, equipment and components as follows:
 - a. "UAVs" having any of the following:
 - 1. An autonomous flight control and navigation capability (e.g. an autopilot with an Inertial Navigation System); or
 - 2. Capability of controlled flight out of the direct visual range involving a human operator (e.g., televisual remote control).
 - b. Associated systems, equipment and components as follows:
 - 1. Equipment specially designed for remotely controlling the "UAVs" controlled by 9.A.12.a.;
 - Guidance or control systems, other than those controlled in Category 7, specially designed for integration into "UAVs" controlled by 9.A.12.a.;
 - 3. Equipment and components specially designed to convert a manned "aircraft" to a "UAV" controlled by 9.A.12.a.
 - <u>Note</u> 9.A.12. does not control model aircraft.

9. B. TEST, INSPECTION AND PRODUCTION EQUIPMENT

- 9. B. 1. Specially designed equipment, tooling and fixtures, as follows, for manufacturing gas turbine blades, vanes or tip shroud castings:
 - a. Directional solidification or single crystal casting equipment;
 - b. Ceramic cores or shells.
- 9. B. 2. On-line (real time) control systems, instrumentation (including sensors) or automated data acquisition and processing equipment, specially designed for the "development" of gas turbine engines, assemblies or components incorporating "technologies" controlled by 9.E.3.a.
- 9. B. 3. Equipment specially designed for the "production" or test of gas turbine brush seals designed to operate at tip speeds exceeding 335 m/s, and temperatures in excess of 773 K (500°C), and specially designed components or accessories therefor.
- 9. B. 4. Tools, dies or fixtures for the solid state joining of "superalloy", titanium or intermetallic airfoil-to-disk combinations described in 9.E.3.a.3. or 9.E.3.a.6. for gas turbines.
- 9. B. 5. On-line (real time) control systems, instrumentation (including sensors) or automated data acquisition and processing equipment, specially designed for use with any of the following wind tunnels or devices:
 - a. Wind tunnels designed for speeds of Mach 1.2 or more, except those specially designed for educational purposes and having a test section size (measured laterally) of less than 250 mm;
 <u>Technical Note</u>
 Test section size: the diameter of the circle, or the side of the square, or the

Test section size: the diameter of the circle, or the side of the square, or the longest side of the rectangle, at the largest test section location.

- b. Devices for simulating flow-environments at speeds exceeding Mach 5, including hot-shot tunnels, plasma arc tunnels, shock tubes, shock tunnels, gas tunnels and light gas guns; or
- c. Wind tunnels or devices, other than two-dimensional sections, capable of simulating Reynolds number flows exceeding 25×10^6 .
- 9. B. 6. Acoustic vibration test equipment capable of producing sound pressure levels of 160 dB or more (referenced to 20 μPa) with a rated output of 4 kW or more at a test cell temperature exceeding 1,273 K (1,000°C), and specially designed quartz heaters therefor.
- 9. B. 7. Equipment specially designed for inspecting the integrity of rocket motors using non-destructive test (NDT) techniques other than planar X-ray or basic physical or chemical analysis.
- 9. B. 8. Transducers specially designed for the direct measurement of the wall skin friction of the test flow with a stagnation temperature exceeding 833 K (560°C).

- 9. B. 9. Tooling specially designed for producing turbine engine powder metallurgy rotor components capable of operating at stress levels of 60% of ultimate tensile strength (UTS) or more and metal temperatures of 873 K (600°C) or more.
- 9. B. 10. Equipment specially designed for the production of "UAVs" and associated systems, equipment and components controlled by 9.A.12.
- 9. C. MATERIALS None

9. D. SOFTWARE

- 9. D. 1. "Software" specially designed or modified for the "development" of equipment or "technology" controlled by 9.A., 9.B. or 9.E.3.
- 9. D. 2. "Software" specially designed or modified for the "production" of equipment controlled by 9.A. or 9.B.
- 9. D. 3. "Software" specially designed or modified for the "use" of full authority digital electronic engine controls (FADEC) for propulsion systems controlled by 9.A. or equipment controlled by 9.B., as follows:
 - a. "Software" in digital electronic controls for propulsion systems, aerospace test facilities or air breathing aero-engine test facilities;
 - b. Fault-tolerant "software" used in "FADEC" systems for propulsion systems and associated test facilities.
- 9. D. 4. Other "software", as follows:
 - a. 2D or 3D viscous "software" validated with wind tunnel or flight test data required for detailed engine flow modelling;
 - b. "Software" for testing aero gas turbine engines, assemblies or components, specially designed to collect, reduce and analyse data in real time, and capable of feedback control, including the dynamic adjustment of test articles or test conditions, as the test is in progress;
 - c. "Software" specially designed to control directional solidification or single crystal casting;
 - d. "Software" in "source code", "object code" or machine code required for the "use" of active compensating systems for rotor blade tip clearance control.
 - <u>Note</u> 9.D.4.d. does not control "software" embedded in uncontrolled equipment or required for maintenance activities associated with the calibration or repair or updates to the active compensating clearance control system.
 - e. "Software" specially designed or modified for the "use" of "UAVs" and associated systems, equipment and components controlled by 9.A.12.

9. E. <u>TECHNOLOGY</u>

- 9. E. 1. "Technology" according to the General Technology Note for the "development" of equipment or "software" controlled by 9.A.1.c., 9.A.4. to 9.A.12., 9.B. or 9.D.
- 9. E. 2. "Technology" according to the General Technology Note for the "production" of equipment controlled by 9.A.1.c., 9.A.4. to 9.A.11. or 9.B.
 - <u>N.B.</u> For "technology" for the repair of controlled structures, laminates or materials, see 1.E.2.f.
 - <u>Note</u> "Development" or "production" "technology" controlled by 9.E. for gas turbine engines remains controlled when used as "use" "technology" for repair, rebuild and overhaul. Excluded from control are: technical data, drawings or documentation for maintenance activities directly associated with calibration, removal or replacement of damaged or unserviceable line replaceable units, including replacement of whole engines or engine modules.
- 9. E. 3. Other "technology", as follows:
 - a. "Technology" "required" for the "development" or "production" of any of the following gas turbine engine components or systems:
 - 1. Gas turbine blades, vanes or tip shrouds made from directionally solidified (DS) or single crystal (SC) alloys having (in the 001 Miller Index Direction) a stress-rupture life exceeding 400 hours at 1,273 K (1,000°C) at a stress of 200 MPa, based on the average property values;
 - 2. Multiple domed combustors operating at average burner outlet temperatures exceeding 1,813 K (1,540°C) or combustors incorporating thermally decoupled combustion liners, non-metallic liners or non-metallic shells;
 - 3. Components manufactured from any of the following:
 - a. Organic "composite" materials designed to operate above 588 K (315°C);
 - b. Metal "matrix" "composite", ceramic "matrix", intermetallic or intermetallic reinforced materials controlled by 1.C.7.; or
 - c. "Composite" material controlled by 1.C.10. and manufactured with resins controlled by 1.C.8.
 - 4. Uncooled turbine blades, vanes, tip-shrouds or other components designed to operate at gas path temperatures of 1,323 K (1,050°C) or more;

- 9. E. 3. a. 5. Cooled turbine blades, vanes or tip-shrouds, other than those described in 9.E.3.a.1., exposed to gas path temperatures of 1,643 K (1,370°C) or more;
 - 6. Airfoil-to-disk blade combinations using solid state joining;
 - 7. Gas turbine engine components using "diffusion bonding" "technology" controlled by 2.E.3.b.;
 - 8. Damage tolerant gas turbine engine rotating components using powder metallurgy materials controlled by 1.C.2.b.;
 - 9. "FADEC" for gas turbine and combined cycle engines and their related diagnostic components, sensors and specially designed components;
 - 10. Adjustable flow path geometry and associated control systems for:
 - a. Gas generator turbines;
 - b. Fan or power turbines;
 - c. Propelling nozzles; or
 - <u>Note 1</u> Adjustable flow path geometry and associated control systems in 9.E.3.a.10. do not include inlet guide vanes, variable pitch fans, variable stators or bleed valves for compressors.
 - <u>Note 2</u> 9.E.3.a.10. does not control "development" or "production" "technology" for adjustable flow path geometry for reverse thrust.
 - 11. Hollow fan blades;
- 9. E. 3. b. "Technology" "required" for the "development" or "production" of any of the following:
 - 1. Wind tunnel aero-models equipped with non-intrusive sensors capable of transmitting data from the sensors to the data acquisition system; or
 - 2. "Composite" propeller blades or propfans capable of absorbing more than 2,000 kW at flight speeds exceeding Mach 0.55;
- 9. E. 3. c. "Technology" "required" for the "development" or "production" of gas turbine engine components using "laser", water jet, ECM or EDM hole drilling processes to produce holes having any of the following sets of characteristics:

- 9. E. 3. c. 1. All of the following:
 - a. Depths more than four times their diameter;
 - b. Diameters less than 0.76 mm; and
 - c. Incidence angles equal to or less than 25° ; or
 - 2. All of the following:
 - a. Depths more than five times their diameter;
 - b. Diameters less than 0.4 mm; and
 - c. Incidence angles of more than 25°;

Technical Note

For the purposes of 9.E.3.c., incidence angle is measured from a plane tangential to the airfoil surface at the point where the hole axis enters the airfoil surface.

- 9. E. 3. d. "Technology" "required" for the "development" or "production" of helicopter power transfer systems or tilt rotor or tilt wing "aircraft" power transfer systems;
- 9. E. 3. e. "Technology" for the "development" or "production" of reciprocating diesel engine ground vehicle propulsion systems having all of the following:
 - 1. A box volume of 1.2 m^3 or less;
 - 2. An overall power output of more than 750 kW based on 80/1269/EEC, ISO 2534 or national equivalents; and
 - 3. A power density of more than 700 kW/m³ of box volume;

Technical Note

Box volume: the product of three perpendicular dimensions is measured in the following way:

<u>Length</u>: The length of the crankshaft from front flange to flywheel face;

- *Width:* The widest of the following:
 - a. The outside dimension from valve cover to valve cover;
 - b. The dimensions of the outside edges of the cylinder heads; <u>or</u>
 - c. The diameter of the flywheel housing;

<u>Height</u>: The largest of the following:

- *a.* The dimension of the crankshaft centre-line to the top plane of the valve cover (or cylinder head) plus twice the stroke; <u>or</u>
- b. The diameter of the flywheel housing.

- 9. E. 3. f. "Technology" "required" for the "production" of specially designed components, as follows, for high output diesel engines:
 - 1. "Technology" "required" for the "production" of engine systems having all of the following components employing ceramics materials controlled by 1.C.7:
 - a. Cylinder liners;
 - b. Pistons;
 - c. Cylinder heads; <u>and</u>
 - d. One or more other components (including exhaust ports, turbochargers, valve guides, valve assemblies or insulated fuel injectors);
- 9. E. 3. f. 2. "Technology" "required" for the "production" of turbocharger systems, with single-stage compressors having all of the following:
 - a. Operating at pressure ratios of 4:1 or higher;
 - b. A mass flow in the range from 30 to 130 kg per minute; and
 - c. Variable flow area capability within the compressor or turbine sections;
- 9. E. 3. f. 3. "Technology" "required" for the "production" of fuel injection systems with a specially designed multifuel (e.g., diesel or jet fuel) capability covering a viscosity range from diesel fuel (2.5 cSt at 310.8 K (37.8°C)) down to gasoline fuel (0.5 cSt at 310.8 K (37.8°C)), having both of the following:
 - a. Injection amount in excess of 230 mm³ per injection per cylinder; and
 - b. Specially designed electronic control features for switching governor characteristics automatically depending on fuel property to provide the same torque characteristics by using the appropriate sensors;
- 9. E. 3. g. "Technology" "required" for the "development" or "production" of high output diesel engines for solid, gas phase or liquid film (or combinations thereof) cylinder wall lubrication, permitting operation to temperatures exceeding 723 K (450°C), measured on the cylinder wall at the top limit of travel of the top ring of the piston. Technology Note

Technical Note

High output diesel engines: diesel engines with a specified brake mean effective pressure of 1.8 MPa or more at a speed of 2,300 r.p.m., provided the rated speed is 2,300 r.p.m. or more.

THE SENSITIVE LIST OF DUAL-USE GOODS AND TECHNOLOGIES

<u>N.B.</u> Where abbreviated entries are used, see the List of Dual-Use Goods and Technologies for full details. Text that differs from that in the List of Dual-Use Goods and Technologies is shaded.

Category 1

1.A.2.	"Composite" structures or laminates		
1.C.1.	Materials specially designed for use as absorbers of electromagnetic waves		
1.C.7.c. & 1.C.7.d. 1.C.10.c. & 1.C.10.d. 1.C.12.	Ceramic-ceramic "composite" materials Fibrous or filamentary materials Materials as follows		
1.D. 2	"Software" for the "development" of organic "matrix", metal "matrix" or carbon "matrix" laminates or "composites" listed on this List.		
1.E.1.	"Technology" according to the General Technology Note for the "development" or "production" of equipment and materials in 1.A.2. or 1.C. of this List.		
1.E. 2.e. & 1.E.2.f.	Other "technology"		
Category 2			
2.B.1.a. 2.B.1.b. 2.B.1.d. 2.B.1.f. 2.B.3.	Deleted Deleted Deleted Deleted		
2.D.1.	"Software", other than that controlled by 2.D.2., specially designed for the "development" or "production" of the following equipment:		
	 a. Machine tools for turning, having all of the following characteristics: 1. Positioning accuracy with "all compensations available" equal to or less (better) than 3.6 μm according to ISO 230/2 (1997) or national equivalents along any linear axis; and 2. Two or more axes which can be coordinated simultaneously for "contouring control". 		

Category 2 contd.

2.D.1.	b.	 Machine tools for milling, having any of the following characteristics: 1.a. Positioning accuracy with "all compensations available" equal to or less (better) than 3.6 µm according to ISO 230/2 (1997) or national equivalents along any linear axis; and b. Three linear axes plus one rotary axis which can be coordinated simultaneously for "contouring control";
		2. Five or more axes which can be coordinated simultaneously for "contouring control" and have a positioning accuracy with "all compensations available" equal to or less (better) than $3.6 \mu\text{m}$ according to ISO 230/2 (1997) or national equivalents along any linear axis; or
		3. A positioning accuracy for jig boring machines, with "all compensations available", equal to or less (better) than $3 \mu m$ according to ISO 230/2 (1997) or national equivalents along any linear axis;
	c.	Electrical discharge machines (EDM)
	d.	Deep-hole-drilling machines
	e.	"Numerically controlled" or manual machine tools
2.E.1.	"de	echnology" according to the General Technology Note for the evelopment" of "software" in 2.D. of this List or for the evelopment" of the following equipment:
	a.	 Machine tools for turning, having all of the following characteristics: Positioning accuracy with "all compensations available" equal to or less (better) than 3.6 µm according to ISO 230/2 (1997) or national equivalents along any linear axis; and Two or more axes which can be coordinated simultaneously for "contouring control".

Category 2 contd.

2.E.1.	b.	 Machine tools for milling, having any of the following characteristics: 1.a. Positioning accuracy with "all compensations available" equal to or less (better) than 3.6 µm according to ISO 230/2 (1997) or national equivalents along any linear axis; and b. Three linear axes plus one rotary axis which can be coordinated simultaneously for "contouring control";
		2. Five or more axes which can be coordinated simultaneously for "contouring control" and have a positioning accuracy with "all compensations available" equal to or less (better) than $3.6 \mu\text{m}$ according to ISO 230/2 (1997) or national equivalents along any linear axis; or
		3. A positioning accuracy for jig boring machines, with "all compensations available", equal to or less (better) than $3 \mu m$ according to ISO 230/2 (1997) or national equivalents along any linear axis;
	c.	Electrical discharge machines (EDM)
	d.	Deep-hole-drilling machines
	e.	"Numerically controlled" or manual machine tools
2.E.2.		echnology" according to the General Technology Note for the roduction" of the following equipment:
	a.	 Machine tools for turning, having all of the following characteristics: Positioning accuracy with "all compensations available" equal to or less (better) than 3.6 µm according to ISO 230/2 (1997) or national equivalents along any linear axis; and Two or more axes which can be coordinated simultaneously for "contouring control".

Category 2 contd.

2.E.2.	b.	 Machine tools for milling, having any of the following characteristics: 1.a. Positioning accuracy with "all compensations available" equal to or less (better) than 3.6 µm according to ISO 230/2 (1997) or national equivalents along any linear axis; and b. Three linear axes plus one rotary axis which can be coordinated simultaneously for "contouring control"; or
		2. Five or more axes which can be coordinated simultaneously for "contouring control" and have a positioning accuracy with "all compensations available" equal to or less (better) than $3.6 \mu\text{m}$ according to ISO 230/2 (1997) or national equivalents along any linear axis; or
		3. A positioning accuracy for jig boring machines, with "all compensations available", equal to or less (better) than $3 \mu m$ according to ISO 230/2 (1997) or national equivalents along any linear axis;
	c.	Electrical discharge machines (EDM)
	d.	Deep-hole-drilling machines
	e.	"Numerically controlled" or manual machine tools
Category 3		
3.A.2.g.2. 3.B.1.a.2. 3.D.1. 3.E.1.	Me "Se "pi "T	omic frequency standards etal organic chemical vapour deposition reactors oftware" specially designed for the "development" or roduction" of equipment in 3.A.2.g. or 3.B. of this List. echnology" according to the General Technology Note for the evelopment" or "production" of equipment in 3.A. or 3.B. of this st.

Category 4

4.A.1.a.2. 4.A.3.b. 4.A.3.c.	Electronic computersradiation hardened; Deleted Deleted
4.D.1.	"Software" specially designed for the "development" or "production" of equipment in 4.A. of this List or for the "development" or "production" of "digital computers" having an "Adjusted Peak Performance" ("APP") exceeding 0.1 Weighted TeraFLOPS (WT).
4.E.1.	 "Technology" according to the General Technology Note for the "development" or "production" of the following equipment or "software": Equipment in 4.A. of this List; "Digital computers" having an "Adjusted Peak Performance" ("APP") exceeding 0.1 Weighted TeraFLOPS (WT); or "Software" in 4.D. of this List.
Category 5 - Part 1	
5.A.1.b.3. 5.A.1.b.5.	Being radio equipment Being digitally controlled radio receivers
5.B.1.a.	Equipment and specially designed components or accessories therefor, specially designed for the "development", "production" or "use" of equipment, functions or features in Category 5 - Part 1 of this List.
5.D.1.a.	"Software" specially designed for the "development" or "production" of equipment, functions or features in Category 5 - Part 1 of this List.
5.D.1.b.	"Software" specially designed or modified to support "technology" listed under 5.E.1. of this List.
5.E.1.a.	"Technology" according to the General Technology Note for the "development" or "production" of equipment, functions, features or "software" in Category 5 - Part 1 of this List.
Category 5 - Part 2	- None

Category 6	
6.A.1.a.1.b.	 Object detection or location systems having any of the following: 1. A transmitting frequency below 5 kHz or a sound pressure level exceeding 224 dB (reference 1 μPa at 1 m) for equipment with an operating frequency in the band from 5 kHz to 10 kHz inclusive; 2. Sound pressure level exceeding 224 dB (reference 1 μPa at 1 m) for equipment with an operating frequency in the band from 10 kHz to 24 kHz inclusive; 3. Sound pressure level; 4. Forming beams of; 5. Designed to operate 6. Designed to withstand;
6.A.1.a.2.a.1.	HydrophonesIncorporating
6.A.1.a.2.a.2.	HydrophonesIncorporating flexible assemblies
6.A.1.a.2.a.3.	HydrophonesHaving any
6.A.1.a.2.a.5.	HydrophonesWhen designed
6.A.1.a.2.a.6.	HydrophonesDesigned for
6.A.1.a.2.b.	Towed acoustic hydrophone arrays
6.A.1.a.2.c.	Processing equipment, specially designed for real time application with towed acoustic hydrophone arrays, having "user accessible programmability" and time or frequency domain processing and correlation, including spectral analysis, digital filtering and beamforming using Fast Fourier or other transforms or processes;
6.A.1.a.2.d.	Heading sensors
6.A.1.a.2.e.	 Bottom or bay cable systems having any of the following: 1. Incorporating hydrophones or 2. Incorporating multiplexed hydrophone group signal modules;
6.A.1.a.2.f.	Processing equipment, specially designed for real time application with bottom or bay cable systems, having "user accessible programmability" and time or frequency domain processing and correlation, including spectral analysis, digital filtering and beamforming using Fast Fourier or other transforms or processes;
6.A.2.a.1.a., b., and c.	"Space-qualified" solid-state detectors

Category 6 contd.	
6.A.2.a.2.a.	 Image intensifier tubes A peak response A microchannel plate Photocathodes, as follows: a. S-20, S-25 or multialkali photocathodes with a luminous sensitivity exceeding 700 μA/lm; b. GaAs or GaInAs photocathodes; c. Other III-V compound semiconductor photocathodes.
6.A.2.a.3.	 Non-space qualified "focal plane arrays"; <u>Note 3</u> In 6.A.2.a.3. the following "focal plane arrays" are not included in this List: a. Platinum Silicide (PtSi) "focal plane arrays" having less than 10,000 elements; b. Iridium Silicide (IrSi) "focal plane arrays". <u>Note 4</u> In 6.A.2.a.3. the following "focal plane arrays" are not included in
	 <i>in O.N.2.a.s. the following 'focul plane arrays' are not included in this List:</i> <i>a. Indium Antimonide (InSb) or Lead Selenide (PbSe) "focal plane arrays" having less than 256 elements;</i> <i>b. Indium Arsenide (InAs) "focal plane arrays";</i> <i>c. Lead Sulphide (PbS) "focal plane arrays";</i> <i>d. Indium Gallium Arsenide (InGaAs) "focal plane arrays".</i>
	 <u>Note 5</u> In 6.A.2.a.3. Mercury Cadmium Telluride (HgCdTe) "focal plane arrays" as follows are not included in this List: a. Scanning Arrays having any of the following: 30 elements or less; <u>or</u> Incorporating time delay-and-integration within the element and having 2 elements or less; b. Staring Arrays having less than 256 elements.
	 <u>Technical Notes</u> 1. 'Scanning Arrays' are defined as "focal plane arrays" designed for use with a scanning optical system that images a scene in a sequential manner to produce an image;
	2. 'Staring Arrays' are defined as "focal plane arrays" designed for use with a non-scanning optical system that images a scene.

Category 6 contd.

6.A.2.a.3.	 <u>Note 6</u> In 6.A.2.a.3. the following "focal plane arrays" are not included in this List: a. Gallium Arsenide (GaAs) or Gallium Aluminum Arsenide (GaAlAs) quantum well "focal plane arrays" having less than 256 elements; b. Microbolometer "focal plane arrays" having less than 8,000 elements.
6.A.2.b.	"Monospectral imaging sensors" and "multispectral imaging sensors"
6.A.2.c.	 Direct view imaging equipment operating in the visible or infrared spectrum, incorporating any of the following: 1. Image intensifier tubes having the characteristics listed in 6.A.2.a.2.a. of this List; or 2. "Focal plane arrays" having the characteristics listed in 6.A.2.a.3. of this List;
6.A.2.e.	"Space-qualified" "focal plane arrays"
6.A.3.b.3.	Imaging cameras incorporating image intensifier tubes having the characteristics listed in 6.A.2.a.2.a. of this List;
6.A.3.b.4.	 Imaging cameras incorporating "focal plane arrays" having any of the following: a. Incorporating "focal plane arrays" listed in 6.A.2.a.3.a. to 6.A.2.a.3.e. of this List; or b. Incorporating "focal plane arrays" listed in 6.A.2.a.3.f. of this List <u>Note 1</u> 'Imaging cameras' described in 6.A.3.b.4 include "focal plane arrays" combined with sufficient signal processing electronics, beyond the read out integrated circuit, to enable as a minimum the output of an analogue or digital signal once power is supplied. <u>Note 2</u> 6.A.3.b.4.a. does not control imaging cameras incorporating linear "focal plane arrays" with twolve elements or favor, not
	 linear "focal plane arrays" with twelve elements or fewer, not employing time-delay-and-integration within the element, designed for any of the following: a. Industrial or civilian intrusion alarm, traffic or industrial movement control or counting systems; b. Industrial equipment used for inspection or monitoring of heat flows in buildings, equipment or industrial processes; c. Industrial equipment used for inspection, sorting or analysis of the properties of materials; d. Equipment specially designed for laboratory use; or e. Medical equipment.

Category 6 contd.

6.A.3.b.4. contd.	<u>Note 3</u>	6.A.3.b.4.b. does not control imaging cameras having any of the following characteristics:
		a. A maximum frame rate equal to or less than 9 Hz;
		b. Having all of the following:
		1. Having a minimum horizontal or vertical Instantaneous-Field-of-View (IFOV) of at least 10 mrad/pixel (milliradians/pixel);
		2. Incorporating a fixed focal-length lens that is not designed to be removed;
		 3. Not incorporating a direct view display; <u>and</u> <u>Technical Note</u>: 'Direct view' refers to an imaging camera operating in the infrared spectrum that presents a visual image to a human observer using a near-to-eye micro display incorporating any light-security mechanism.
		 4. Having any of the following: a. No facility to obtain a viewable image of the detected field-of-view<u>; or</u> b. The camera is designed for a single kind of application and designed not to be user modified; or
		<u>Technical Note</u> Instantaneous Field of View (IFOV) specified in Note 3.b. is the lesser figure of the Horizontal FOV or the Vertical FOV.
		Horizontal IFOV = horizontal Field of View (FOV)/number of horizontal detector elements Vertical IFOV= vertical Field of View (FOV)/number of vertical detector elements.
		c. Where the camera is specially designed for installation into a civilian passenger land vehicle of less than three tonnes (gross vehicle weight) and having all of the following:
		1. Is only operable when installed in any of the following:
		a. The civilian passenger land vehicle for which it was intended; <u>or</u>
		b. A specially designed, authorized maintenance test facility; <u>and</u>
		2. Incorporates an active mechanism that forces the camera not to function when it is removed from the vehicle for which it was intended.
		<u>Note</u> : When necessary, details of the item will be provided, upon request, to the appropriate authority in the exporter's country in order to ascertain compliance with the conditions described in Note 3.b.4. and Note 3.c.

above.

Category 6 contd.

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6.A.4.c. 6.A.4.d.	"Space-qualified" components for optical systems Optical control equipment
6.A.6.a.	"Magnetometers" using optically pumped or nuclear precession (proton/Overhauser) having a "noise level" (sensitivity) lower (better) than 2 pT rms per square root Hz.
6.A.6.g.	Magnetic compensation systemsNoteIn 6.A.6.g. those compensators which provide only absolute values of the earth's magnetic field as output, (i.e., the frequency bandwidth of the output extends from DC to at least 0.8 Hz) are not included in this List.
6.A.6.h.	"Superconductive" electromagnetic sensors
6.A.8.d. 6.A.8.h. 6.A.8.k. 6.A.8.1.3.	Radar systemsCapable of Radar systemsEmploying processing Radar systemsHaving "signal processing" Radar systemsHaving data processing Processing for
6.B.8.	Pulse radar cross-section
6.D.1. 6.D.3.a.	"Software" specially designed for the "development" or "production" of equipment in 6.A.4., 6.A.8. or 6.B.8. of this List. "Software", as follows:
6.E.1. 6.E.2.	"Technology" according to "Technology" according to the General Technology Note for the "production" of equipment in 6.A. or 6.B. of this List.
Category 7	
7.D.2.	"Source code" for the "use"
7.D.3.a. 7.D.3.b. 7.D.3.c. 7.D.3.d.1. to 4. & 7.	"Software" specially designed or modified to "Source code" for "Source code" for "Source code" for the "development" of
7.E.1. & 7.E.2.	"Technology" according to the General Technology Note
Category 8	
8.A.1.b. 8.A.1.c. 8.A.1.d. <u>Category 8</u> contd.	Manned, untethered submersible vehicles Unmanned, tethered submersible vehicles Unmanned, untethered submersible vehicles

Sensitive List

8.A.2.b.	 Systems specially designed or modified for the automated control of the motion of submersible vehicles in 8.A.1. of this List using navigation data and having closed loop servo-controls: 1. Enabling; 2. Maintaining; or 3. Maintaining;
8.A.2.h. 8.A.2.j. 8.A.2.o.3. 8.A.2.p.	"Robots" specially designed for underwater use Air independent power systems Noise reduction systems for use on vessels Pumpjet propulsion systems
8.D.1.	"Software" specially designed for the "development" or "production" of equipment in 8.A. of this List.
8.D.2	Specific "software"
8.E.1.	"Technology" according to the General Technology Note for the "development" or "production" of equipment in 8.A. of this List.
8.E.2.a.	Other "technology"
Category 9	
9.A.11. 9.B.1.b.	Ramjet, scramjet or combined cycle engines Ceramic cores or shells
9.D.1.	"Software" specially designed or modified for the "development" of equipment or "technology" in 9.A., 9.B. or 9.E.3. of this List.
9.D.2.	"Software" specially designed or modified for the "production" of equipment in 9.A. or 9.B. of this List.
9.D.4.a. 9.D.4.c.	Other "software"2D or 3D Other "software""Software" specially
9.E.1. 9.E.2.	"Technology" according to the General Technology Note "Technology" according to the General Technology Note
9.E.3.a.1. 9.E.3.a.2. to 5. &	Other "technology"Gas turbine blades Other "technology"

9.E.3.a.8., 9.E.3.a.9.

Very Sensitive List

VERY SENSITIVE LIST OF DUAL-USE GOODS AND TECHNOLOGIES

<u>N.B.</u> Where abbreviated entries are used, see List of Dual-Use Goods and Technologies for full details. Text that differs from that in the List of Dual-Use Goods and Technologies is shaded.

Category 1

1.A.2.a.	"Composite" structures or laminates having an organic "matrix" and made from materials listed under 1.C.10.c. or 1.C.10.d.
1.C.1.	Materials specially designed for use as absorbers of electromagnetic waves
1.C.12. 1.E.1.	Materials as follows "Technology" according to the General Technology Note for the "development" or "production" of equipment and materials in 1.A.2 or 1.C. of this List.
Category 2	None
Category 3	None
Category 4	None
Category 5 - Part 1	
5.A.1.b.5.	Digitally controlled radio receivers
5.D.1.a.	"Software" specially designed for the "development" or "production" of equipment, functions or features in Category 5, Part 1 of this List.
5.E.1.a.	"Technology" according to the General Technology Note for the "development" or "production" of equipment, functions, features or "software" in Category 5, Part 1 of this List.
Category 5 - Part 2	None

Very Sensitive List

Category 6	
6.A.1.a.1.b.1.	Object detection or location systems having a sound pressure level exceeding 210 dB (reference 1 μ Pa at 1 m) and an operating frequency in the band from 30 Hz to 2 kHz.
6.A.1.a.2.a.1. 6.A.1.a.2.a.2. 6.A.1.a.2.a.3. 6.A.1.a.2.a.5. 6.A.1.a.2.a.6.	HydrophonesIncorporating HydrophonesIncorporating flexible assemblies HydrophonesHaving any HydrophonesWhen designed HydrophonesDesigned for
6.A.1.a.2.b.	Towed acoustic hydrophone arrays
6.A.1.a.2.c.	Processing equipment, specially designed for real time application with towed acoustic hydrophone arrays, having "user accessible programmability" and time or frequency domain processing and correlation, including spectral analysis, digital filtering and beamforming using Fast Fourier or other transforms or processes;
6.A.1.a.2.e.	 Bottom or bay cable systems having any of the following: 1. Incorporating hydrophones or 2. Incorporating multiplexed hydrophone group signal modules;
6.A.1.a.2.f.	Processing equipment, specially designed for real time application with bottom or bay cable systems, having "user accessible programmability" and time or frequency domain processing and correlation, including spectral analysis, digital filtering and beamforming using Fast Fourier or other transforms or processes;
6.A.2.a.1.c. 6.A.8.1.3.	"Space-qualified" solid-state detectors Radar systemsHaving data processing Processing for
6.B.8.	Pulse radar cross-section
6.D.1.	"Software" specially designed for the "development" or "production" of equipment in 6.A.8., or 6.B.8. of this List.
6.D.3.a.	"Software", as follows:
6.E.1.	"Technology" according to the General Technology Note for the "development" of equipment or "software" in 6.A., 6.B., or 6.D. of this List.
6.E.2.	"Technology" according to the General Technology Note for the "production" of equipment in 6.A. or 6.B. of this List.

Very Sensitive List

Category 7	
7.D.3.a. 7.D.3.b.	"Software" specially designed or modified to "Source code" for
Category 8	
8.A.1.b. 8.A.1.d. 8.A.2.o.3.b.	Manned, untethered submersible vehicles Unmanned, untethered submersible vehicles Active noise reduction or cancellation systems
8.D.1.	"Software" specially designed for the "development" or "production" of equipment in 8.A. of this List.
8.E.1.	"Technology" according to the General Technology Note for the "development" or "production" of equipment in 8.A. of this List.
Category 9	
9.A.11.	Ramjet, scramjet or combined cycle engines
9.D.1.	"Software" specially designed or modified for the "development" of equipment or "technology" in 9.A. or 9.E.3. of this List.
9.D.2.	"Software" specially designed or modified for the "production" of equipment in 9.A. of this List.
9.E.1.	"Technology" according to the General Technology Note for the "development" of equipment or "software" in 9.A.11. or 9.D. of this List.
9.E.2.	"Technology" according to the General Technology Note for the "production" of equipment in 9.A.11. of this List.
9.E.3.a.1.	Other "technology"Gas turbine blades
9.E.3.a.3.a.	"Technology" "required" for Components manufactured from Organic "composite" materials designed to operate above 588 K (315°C).

MUNITIONS LIST*

- <u>Note 1</u> Terms in "quotations" are defined terms. Refer to 'Definitions of Terms used in these Lists' annexed to this List.
- <u>Note 2</u> Chemicals are listed by name and CAS number. Chemicals of the same structural formula (including hydrates) are controlled regardless of name or CAS number. CAS numbers are shown to assist in identifying whether a particular chemical or mixture is controlled, irrespective of nomenclature. CAS numbers cannot be used as unique identifiers because some forms of the listed chemical have different CAS numbers, and mixtures containing a listed chemical may also have different CAS numbers.
- ML1. Smooth-bore weapons with a calibre of less than 20 mm, other arms and automatic weapons with a calibre of 12.7 mm (calibre 0.50 inches) or less and accessories, as follows, and specially designed components therefor:
 - a. Rifles, carbines, revolvers, pistols, machine pistols and machine guns:
 - <u>Note</u> ML1.a. does not control the following:
 - 1. Muskets, rifles and carbines manufactured earlier than 1938;
 - 2. Reproductions of muskets, rifles and carbines the originals of which were manufactured earlier than 1890;
 - 3. *Revolvers, pistols and machine guns manufactured earlier than 1890, and their reproductions;*
 - b. Smooth-bore weapons, as follows:
 - 1. Smooth-bore weapons specially designed for military use;
 - 2. Other smooth-bore weapons, as follows:
 - a. Of the fully automatic type;
 - b. Of the semi-automatic or pump-action type;
 - c. Weapons using caseless ammunition;
 - d. Silencers, special gun-mountings, clips, weapons sights and flash suppressers for arms controlled by sub-items ML1.a., ML1.b. or ML1.c.
- <u>Note 1</u> *ML1.* does not control smooth-bore weapons used for hunting or sporting purposes. These weapons must not be specially designed for military use or of the fully automatic firing type.
- <u>Note 2</u> *ML1.* does not control firearms specially designed for dummy ammunition and which are incapable of firing any controlled ammunition.
- <u>Note 3</u> *ML1.* does not control weapons using non-centre fire cased ammunition and which are not of the fully automatic firing type.
- <u>Note 4</u> ML1.d. does not control optical weapon sights without electronic image processing, with a magnification of 4 times or less, provided they are not specially designed or modified for military use.

^{*} France, the Russian Federation and Ukraine view this list as a reference list drawn up to help in the selection of dual-use goods which could contribute to the indigenous development, production or enhancement of conventional munitions capabilities.

- ML2. Smooth-bore weapons with a calibre of 20 mm or more, other weapons or armament with a calibre greater than 12.7 mm (calibre 0.50 inches), projectors and accessories, as follows, and specially designed components therefor:
 - a. Guns, howitzers, cannon, mortars, anti-tank weapons, projectile launchers, military flame throwers, recoilless rifles and signature reduction devices therefor;
 - <u>Note</u> ML2.a. includes injectors, metering devices, storage tanks and other specially designed components for use with liquid propelling charges for any of the equipment controlled by ML2.a.
 - b. Military smoke, gas and pyrotechnic projectors or generators. <u>Note</u> ML2.b. does not control signal pistols.
 - c. Weapons sights.
- ML3. Ammunition and fuze setting devices, as follows, and specially designed components therefor:
 - a. Ammunition for the weapons controlled by ML1., ML2. or ML12.;
 - b. Fuze setting devices specially designed for ammunition controlled by ML3.a.
 - <u>Note 1</u> Specially designed components include:
 - a. Metal or plastic fabrications such as primer anvils, bullet cups, cartridge links, rotating bands and munitions metal parts;
 - b. Safing and arming devices, fuses, sensors and initiation devices;
 - c. Power supplies with high one-time operational output;
 - *d. Combustible cases for charges;*
 - *e.* Submunitions including bomblets, minelets and terminally guided projectiles.
 - <u>Note 2</u> *ML3.a.* does not control ammunition crimped without a projectile (blank star) and dummy ammunition with a pierced powder chamber.
 - <u>Note 3</u> ML3.a. does not control cartridges specially designed for any of the following purposes:
 - a. Signalling;
 - b. Bird scaring; or
 - c. Lighting of gas flares at oil wells.

ML4. Bombs, torpedoes, rockets, missiles, other explosive devices and charges and related equipment and accessories, as follows, specially designed for military use, and specially designed components therefor:

<u>N.B.</u> For guidance and navigation equipment, see ML11, Note 7.

a. Bombs, torpedoes, grenades, smoke canisters, rockets, mines, missiles, depth charges, demolition-charges, demolition-devices and demolition-kits, "pyrotechnic" devices, cartridges and simulators (i.e. equipment simulating the characteristics of any of these items);

<u>Note</u> ML4.a. includes:

- 1. Smoke grenades, fire bombs, incendiary bombs and explosive devices;
- 2. Missile rocket nozzles and re-entry vehicle nosetips.
- b. Equipment specially designed for the handling, control, activation, powering with one-time operational output, launching, laying, sweeping, discharging, decoying, jamming, detonation or detection of items controlled by ML4.a.

<u>Note</u> ML4.b. includes:

- 1. Mobile gas liquefying equipment capable of producing 1,000 kg or more per day of gas in liquid form;
- 2. Buoyant electric conducting cable suitable for sweeping magnetic mines.

Technical Note

Hand-held devices, limited by design solely to the detection of metal objects and incapable of distinguishing between mines and other metal objects, are not considered to be specially designed for the detection of items controlled by ML4.a.

- ML5. Fire control, and related alerting and warning equipment, and related systems, test and alignment and countermeasure equipment, as follows, specially designed for military use, and specially designed components and accessories therefor:
 - a. Weapon sights, bombing computers, gun laying equipment and weapon control systems;
 - b. Target acquisition, designation, range-finding, surveillance or tracking systems; detection, data fusion, recognition or identification equipment; and sensor integration equipment;
 - c. Countermeasure equipment for items controlled by ML5.a. or ML5.b.
 - d. Field test or alignment equipment, specially designed for items controlled by ML5.a. or ML5.b.

ML6. Ground vehicles and components, as follows:

<u>N.B.</u> For guidance and navigation equipment, see ML11, Note 7.

- a. Ground vehicles and components therefor, specially designed or modified for military use; <u>Technical Note</u> For the purposes of ML6.a. the term ground vehicles includes trailers.
- b. All wheel-drive vehicles capable of off-road use which have been manufactured or fitted with materials to provide ballistic protection to level III (NIJ 0108.01, September 1985, or comparable national standard) or better.
- <u>N.B.</u> See also ML13.a.
- <u>Note 1</u> ML6.a. includes:
 - a. Tanks and other military armed vehicles and military vehicles fitted with mountings for arms or equipment for mine laying or the launching of munitions controlled under ML4;
 - b. Armoured vehicles;
 - c. Amphibious and deep water fording vehicles;
 - *d. Recovery vehicles and vehicles for towing or transporting ammunition or weapon systems and associated load handling equipment.*

<u>Note 2</u> Modification of a ground vehicle for military use controlled by ML6.a. entails a structural, electrical or mechanical change involving one or more specially designed military components. Such components include:

- a. Pneumatic tyre casings of a kind specially designed to be bullet-proof or to run when deflated;
- b. Tyre inflation pressure control systems, operated from inside a moving vehicle;
- c. Armoured protection of vital parts, (e.g., fuel tanks or vehicle cabs);
- d. Special reinforcements or mountings for weapons;
- e. Black-out lighting.
- <u>Note 3</u> *ML6. does not control civil automobiles, or trucks designed or modified for transporting money or valuables, having armoured or ballistic protection.*

- ML7. Chemical or biological toxic agents, "riot control agents", radioactive materials, related equipment, components, and materials, as follows:
 - a. Biological agents and radioactive materials "adapted for use in war" to produce casualties in humans or animals, degrade equipment or damage crops or the environment;
 - b. Chemical warfare (CW) agents including:
 - 1. CW nerve agents:
 - a. O-Alkyl (equal to or less than C10, including cycloalkyl) alkyl (Methyl, Ethyl, n-Propyl or Isopropyl) phosphonofluoridates, such as: Sarin (GB):O-Isopropyl methylphosphonofluoridate (CAS 107-44-8); and Soman (GD):O-Pinacolyl methylphosphonofluoridate (CAS 96-64-0);
 - b. O-Alkyl (equal to or less than C10, including cycloalkyl) N,N-dialkyl (Methyl, Ethyl, n-Propyl or Isopropyl) phosphoramidocyanidates, such as: Tabun (GA):O-Ethyl N,N-dimethylphosphoramidocyanidate (CAS 77-81-6);
 - c. O-Alkyl (H or equal to or less than C10, including cycloalkyl) S-2-dialkyl (Methyl, Ethyl, n-Propyl or Isopropyl)-aminoethyl alkyl (Methyl, Ethyl, n-Propyl or Isopropyl) phosphonothiolates and corresponding alkylated and protonated salts, such as: VX: O-Ethyl S-2-diisopropylaminoethyl methyl phosphonothiolate (CAS 50782-69-9);
 - 2. CW vesicant agents:
 - a. Sulphur mustards, such as:
 - 1. 2-Chloroethylchloromethylsulphide (CAS 2625-76-5);
 - 2. Bis(2-chloroethyl) sulphide (CAS 505-60-2);
 - 3. Bis(2-chloroethylthio) methane (CAS 63869-13-6);
 - 4. 1,2-bis (2-chloroethylthio) ethane (CAS 3563-36-8);
 - 5. 1,3-bis (2-chloroethylthio) -n-propane (CAS 63905-10-2);
 - 6. 1,4-bis (2-chloroethylthio) -n-butane (CAS 142868-93-7);
 - 7. 1,5-bis (2-chloroethylthio) -n-pentane (CAS 142868-94-8);
 - 8. Bis (2-chloroethylthiomethyl) ether (CAS 63918-90-1);
 - 9. Bis (2-chloroethylthioethyl) ether (CAS 63918-89-8);
 - b. Lewisites, such as:
 - 1. 2-chlorovinyldichloroarsine (CAS 541-25-3);
 - 2. Tris (2-chlorovinyl) arsine (CAS 40334-70-1);
 - 3. Bis (2-chlorovinyl) chloroarsine (CAS 40334-69-8);

- ML7. b. 2. c. Nitrogen mustards, such as:
 - 1. HN1: bis (2-chloroethyl) ethylamine (CAS 538-07-8);
 - 2. HN2: bis (2-chloroethyl) methylamine (CAS 51-75-2);
 - 3. HN3: tris (2-chloroethyl) amine (CAS 555-77-1);
 - 3. CW incapacitating agents, such as:
 - a. 3-Quinuclidinyl benzilate (BZ) (CAS 6581-06-2);
 - 4. CW defoliants, such as:
 - a. Butyl 2-chloro-4-fluorophenoxyacetate (LNF);
 - b. 2,4,5-trichlorophenoxyacetic acid mixed with
 - 2,4-dichlorophenoxyacetic acid (Agent Orange).
 - c. CW binary precursors and key precursors, as follows:
 - 1. Alkyl (Methyl, Ethyl, n-Propyl or Isopropyl Phosphonyl Difluorides, such as: DF: Methyl Phosphonyldifluoride (CAS 676-99-3);
 - O-Alkyl (H or equal to or less than C₁₀, including cycloalkyl) O-2-dialkyl (Methyl, Ethyl, n-Propyl or Isopropyl) aminoethyl alkyl (Methyl, Ethyl, n-Propyl or Isopropyl) phosphonites and corresponding alkylated and protonated salts, such as: QL: O-Ethyl-2-di-isopropylaminoethyl methylphosphonite (CAS 57856-11-8);
 - 3. Chlorosarin: O-Isopropyl methylphosphonochloridate (CAS 1445-76-7);
 - 4. Chlorosoman: O-Pinacolyl methylphosphonochloridate (CAS 7040-57-5);
 - d. "Riot control agents", active constituent chemicals and combinations thereof, including:
 - 1. α-Bromobenzeneacetonitrile, (Bromobenzyl cyanide) (CA) (CAS 5798-79-8);
 - 2. [(2-chlorophenyl) methylene] propanedinitrile, (o-Chlorobenzylidenemalononitrile) (CS) (CAS 2698-41-1);
 - 2-Chloro-1-phenylethanone, Phenylacyl chloride (ω-chloroacetophenone) (CN) (CAS 532-27-4);
 - 4. Dibenz-(b,f)-1,4-oxazephine, (CR) (CAS 257-07-8);
 - 10-Chloro-5,10-dihydrophenarsazine, (Phenarsazine chloride), (Adamsite), (DM) (CAS 578-94-9);
 - 6. N-Nonanoylmorpholine, (MPA) (CAS 5299-64-9);
 - <u>Note 1</u> ML7.d. does not control "riot control agents" individually packaged for personal self defence purposes.
 - <u>Note 2</u> *ML7.d.* does not control active constituent chemicals, and combinations thereof identified and packaged for food production or medical purposes.

- ML7. e. Equipment specially designed or modified for military use, for the dissemination of any of the following and specially designed components therefor:
 - 1. Materials or agents controlled by ML7.a., ML7.b. or d.; or
 - 2. CW made up of precursors controlled by ML7.c.
 - f. Protective and decontamination equipment, specially designed components therefor, and specially formulated chemical mixtures, as follows:
 - 1. Equipment, specially designed or modified for military use, for defence against materials controlled by ML7.a., ML7.b. or d. and specially designed components therefor;
 - 2. Equipment, specially designed or modified for military use, for the decontamination of objects contaminated with materials controlled by ML7.a. or ML7.b. and specially designed components therefor;
 - 3. Chemical mixtures specially developed/formulated for the decontamination of objects contaminated with materials controlled by ML7.a. or ML7.b.;
 - <u>Note</u> ML7.f.1. includes:
 - a. Air conditioning units specially designed or modified for nuclear, biological or chemical filtration;
 - b. Protective clothing.
 - <u>N.B.</u> For civil gas masks, protective and decontamination equipment see, also entry 1.A.4. on the Dual-Use List.
 - g. Equipment, specially designed or modified for military use, for the detection or identification of materials controlled by ML7.a., ML7.b. or d. and specially designed components therefor;

<u>Note</u> *ML7.g.* does not control personal radiation monitoring dosimeters.

- <u>N.B.</u> See also entry 1.A.4. on the Dual-Use List.
- h. "Biopolymers" specially designed or processed for the detection or identification of CW agents controlled by ML7.b., and the cultures of specific cells used to produce them;
- i. "Biocatalysts" for the decontamination or degradation of CW agents, and biological systems therefor, as follows:
 - 1. "Biocatalysts" specially designed for the decontamination or degradation of CW agents controlled by ML7.b. resulting from directed laboratory selection or genetic manipulation of biological systems;
 - 2. Biological systems, as follows: "expression vectors", viruses or cultures of cells containing the genetic information specific to the production of "biocatalysts" controlled by ML7.i.1.;

ML 7. contd.

<u>Note 1</u> ML7.b. and ML7.d. do not control:

- a. Cyanogen chloride (CAS 506-77-4);
- b. Hydrocyanic acid (CAS 74-90-8);
- *c. Chlorine* (*CAS* 7782-50-5);
- d. Carbonyl chloride (phosgene) (CAS 75-44-5);
- e. Diphosgene (trichloromethyl-chloroformate) (CAS 503-38-8);
- f. Deleted
- *g. Xylyl bromide, ortho: (CAS 89-92-9), meta: (CAS 620-13-3), para: (CAS 104-81-4);*
- h. Benzyl bromide (CAS 100-39-0);
- *i.* Benzyl iodide (CAS 620-05-3);
- j. Bromo acetone (CAS 598-31-2);
- k. Cyanogen bromide (CAS 506-68-3);
- *l.* Bromo methylethylketone (CAS 816-40-0);
- *m.* Chloro acetone (CAS 78-95-5);
- *n. Ethyl iodoacetate (CAS 623-48-3);*
- o. Iodo acetone (CAS 3019-04-3);
- p. Chloropicrin (CAS 76-06-2).
- <u>Note 2</u> The cultures of cells and biological systems listed in ML7.h. and ML7.i.2. are exclusive and these sub-items do not control cells or biological systems for civil purposes, such as agricultural, pharmaceutical, medical, veterinary, environmental, waste management, or in the food industry.

ML8. "Energetic materials", and related substances, as follows:

N.B. See also 1.C.11 on the Dual-Use List

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- 1. For the purposes of this entry, mixture refers to a composition of two or more substances with at least one substance being listed in the ML8 sub-items.
- 2. Any substance listed in the ML8 sub-items is controlled by this list, even when utilized in an application other than that indicated. (e.g., TAGN is predominantly used as an explosive but can also be used either as a fuel or an oxidizer.)
- a. "Explosives", as follows, and mixtures thereof:
 - 1. ADNBF (aminodinitrobenzofuroxan or 7-amino-4,6-dinitrobenzofurazane-1-oxide) (CAS 97096-78-1);
 - 2. BNCP (cis-bis (5-nitrotetrazolato) tetra amine-cobalt (III) perchlorate) (CAS 117412-28-9);
 - 3. CL-14 (diamino dinitrobenzofuroxan or 5,7-diamino-4,6dinitrobenzofurazane-1-oxide) (CAS 117907-74-1);
 - CL-20 (HNIW or Hexanitrohexaazaisowurtzitane) (CAS 135285-90-4); chlathrates of CL-20 (see also ML8.g.3. and g.4. for its "precursors");
 - 5. CP (2-(5-cyanotetrazolato) penta amine-cobalt (III) perchlorate) (CAS 70247-32-4);
 - 6. DADE (1,1-diamino-2,2-dinitroethylene, FOX7);
 - 7. DATB (diaminotrinitrobenzene) (CAS 1630-08-6);
 - 8. DDFP (1,4-dinitrodifurazanopiperazine);
 - 9. DDPO (2,6-diamino-3,5-dinitropyrazine-1-oxide, PZO) (CAS 194486-77-6);
 - 10. DIPAM (3,3'-diamino-2,2',4,4',6,6'-hexanitrobiphenyl or dipicramide) (CAS 17215-44-0);
 - 11. DNGU (DINGU or dinitroglycoluril) (CAS 55510-04-8);
 - 12. Furazans, as follows:
 - a. DAAOF (diaminoazoxyfurazan);
 - b. DAAzF (diaminoazofurazan) (CAS 78644-90-3);
 - 13. HMX and derivatives (see also ML8.g.5. for its "precursors"), as follows:
 - a. HMX (Cyclotetramethylenetetranitramine, octahydro-1,3,5,7-tetranitro-1,3,5,7-tetrazine, 1,3,5,7-tetranitro-1,3,5,7-tetraza-cyclooctane, octogen or octogene) (CAS 2691-41-0);
 - b. difluoroaminated analogs of HMX;
 - c. K-55 (2,4,6,8-tetranitro-2,4,6,8-tetraazabicyclo [3,3,0]-octanone-3, tetranitrosemiglycouril or keto-bicyclic HMX) (CAS 130256-72-3):
 - 14. HNAD (hexanitroadamantane) (CAS 143850-71-9);
 - 15. HNS (hexanitrostilbene) (CAS 20062-22-0);

- ML8. a. 16. Imidazoles, as follows:
 - a. BNNII (Octahydro-2,5-bis(nitroimino)imidazo [4,5-d]imidazole);
 - b. DNI (2,4-dinitroimidazole) (CAS 5213-49-0);
 - c. FDIA (1-fluoro-2,4-dinitroimidazole);
 - d. NTDNIA (N-(2-nitrotriazolo)-2,4-dinitroimidazole);
 - e. PTIA (1-picryl-2,4,5-trinitroimidazole);
 - 17. NTNMH (1-(2-nitrotriazolo)-2-dinitromethylene hydrazine);
 - 18. NTO (ONTA or 3-nitro-1,2,4-triazol-5-one) (CAS 932-64-9);
 - 19. Polynitrocubanes with more than four nitro groups;
 - 20. PYX (2,6-Bis(picrylamino)-3,5-dinitropyridine) (CAS 38082-89-2);
 - 21. RDX and derivatives, as follows:
 - a. RDX (cyclotrimethylenetrinitramine, cyclonite, T4, hexahydro-1,3,5trinitro-1,3,5-triazine, 1,3,5-trinitro-1,3,5-triaza-cyclohexane, hexogen or hexogene) (CAS 121-82-4);
 - b. Keto-RDX (K-6 or 2,4,6-trinitro-2,4,6-triazacyclohexanone) (CAS 115029-35-1);
 - 22. TAGN (triaminoguanidinenitrate) (CAS 4000-16-2);
 - 23. TATB (triaminotrinitrobenzene) (CAS 3058-38-6) (see also ML8.g.7 for its "precursors");
 - 24. TEDDZ (3,3,7,7-tetrabis(difluoroamine) octahydro-1,5-dinitro-1,5-diazocine);
 - 25. Tetrazoles, as follows:
 - a. NTAT (nitrotriazol aminotetrazole);
 - b. NTNT (1-N-(2-nitrotriazolo)-4-nitrotetrazole);
 - 26. Tetryl (trinitrophenylmethylnitramine) (CAS 479-45-8);
 - 27. TNAD (1,4,5,8-tetranitro-1,4,5,8-tetraazadecalin) (CAS 135877-16-6) (see also ML8.g.6. for its "precursors");
 - 28. TNAZ (1,3,3-trinitroazetidine) (CAS 97645-24-4) (see also ML8.g.2. for its "precursors");
 - 29. TNGU (SORGUYL or tetranitroglycoluril) (CAS 55510-03-7);
 - 30. TNP (1,4,5,8-tetranitro-pyridazino[4,5-d]pyridazine) (CAS 229176-04-9);
 - 31. Triazines, as follows:
 - a. DNAM (2-oxy-4,6-dinitroamino-s-triazine) (CAS 19899-80-0);
 - b. NNHT (2-nitroimino-5-nitro-hexahydro-1,3,5-triazine) (CAS 130400-13-4);
 - 32. Triazoles, as follows:
 - a. 5-azido-2-nitrotriazole;
 - b. ADHTDN (4-amino-3,5-dihydrazino-1,2,4-triazole dinitramide) (CAS 1614-08-0);
 - c. ADNT (1-amino-3,5-dinitro-1,2,4-triazole);
 - d. BDNTA ([bis-dinitrotriazole]amine);
 - e. DBT (3,3'-dinitro-5,5-bi-1,2,4-triazole) (CAS 30003-46-4);
 - f. DNBT (dinitrobistriazole) (CAS 70890-46-9);
 - g. NTDNA (2-nitrotriazole 5-dinitramide) (CAS 75393-84-9);
 - h. NTDNT (1-N-(2-nitrotriazolo) 3,5-dinitrotriazole);
 - i. PDNT (1-picryl-3,5-dinitrotriazole);
 - j. TACOT (tetranitrobenzotriazolobenzotriazole) (CAS 25243-36-1);

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- ML8. a. 33. Any explosive not listed elsewhere in ML8.a. with a detonation velocity exceeding 8,700 m/s at maximum density or a detonation pressure exceeding 34 GPa (340 kbar);
 - 34. Other organic explosives not listed elsewhere in ML8.a. yielding detonation pressures of 25 GPa (250 kbar) or more that will remain stable at temperatures of 523K (250°C) or higher for periods of 5 minutes or longer.
- ML8. b. "Propellants", as follows:
 - 1. Any United Nations (UN) Class 1.1 solid "propellant" with a theoretical specific impulse (under standard conditions) of more than 250 seconds for non-metallized, or more than 270 seconds for aluminized compositions;
 - 2. Any UN Class 1.3 solid "propellant" with a theoretical specific impulse (under standard conditions) of more than 230 seconds for non-halogenized, 250 seconds for non-metallized compositions and 266 seconds for metallized compositions;
 - 3. "Propellants" having a force constant of more than 1,200 kJ/kg;
 - 4. "Propellants" that can sustain a steady-state linear burning rate of more than 38 mm/s under standard conditions (as measured in the form of an inhibited single strand) of 6.89 MPa (68.9 bar) pressure and 294K (21°C);
 - 5. Elastomer modified cast double base (EMCDB) "propellants" with extensibility at maximum stress of more than 5% at 233K (-40°C);
 - 6. Any "propellant" containing substances listed in ML8.a.
- ML8. c. "Pyrotechnics", fuels and related substances, as follows, and mixtures thereof:
 - 1. Aircraft fuels specially formulated for military purposes;
 - 2. Alane (aluminum hydride) (CAS 7784-21-6);
 - 3. Carboranes; decaborane (CAS 17702-41-9); pentaboranes (CAS 19624-22-7 and 18433-84-6) and their derivatives;
 - 4. Hydrazine and derivatives, as follows (see also ML8.d.8. and d.9. for oxidising hydrazine derivatives):
 - a. Hydrazine (CAS 302-01-2) in concentrations of 70% or more;
 - b. Monomethyl hydrazine (CAS 60-34-4);
 - c. Symmetrical dimethyl hydrazine (CAS 540-73-8);
 - d. Unsymmetrical dimethyl hydrazine (CAS 57-14-7);
 - 5. Metal fuels in particle form whether spherical, atomized, spheroidal, flaked or ground, manufactured from material consisting of 99 % or more of any of the following:
 - a. Metals and mixtures thereof, as follows:
 - 1. Beryllium (CAS 7440-41-7) in particle sizes of less than $60 \mu m$;
 - 2. Iron powder (CAS 7439-89-6) with particle size of 3 μm or less produced by reduction of iron oxide with hydrogen;

ML8. c. 5. 6. 7. 8.	 b. Mixtures, which contain any of the following: Zirconium (CAS 7440-67-7), magnesium (CAS 7439-95-4) or alloys of these in particle sizes of less than 60 μm; Boron (CAS 7440-42-8) or boron carbide (CAS 12069-32-8) fuels of 85% purity or higher and particle sizes of less than 60 μm; Military materials containing thickeners for hydrocarbon fuels specially formulated for use in flame throwers or incendiary munitions, such as metal stearates or palmates (e.g. octal (CAS 637-12-7)) and M1, M2, and M3 thickeners; Perchlorates, chlorates and chromates composited with powdered metal or other high energy fuel components; Spherical aluminum powder (CAS 7429-90-5) with a particle size of 60 μm or less, manufactured from material with an aluminum content of 99% or more;
9.	Titanium subhydride (TiH _n) of stoichiometry equivalent to $n=0.65-1.68$.
<u>Note 1</u>	<i>Aircraft fuels controlled by ML8.c.1. are finished products not their constituents.</i>
<u>Note 2</u>	ML8.c.4.a. does not control hydrazine mixtures specially formulated for corrosion control.
<u>Note 3</u>	Explosion control. Explosives and fuels containing the metals or alloys listed in ML8.c.5. are controlled whether or not the metals or alloys are encapsulated in aluminum, magnesium, zirconium, or beryllium.
<u>Note 4</u>	ML8.c.5.b.2. does not control boron and boron carbide enriched with boron-10 (20% or more of total boron-10 content.)
ML8. d. Oxid	dizers, as follows, and mixtures thereof:
1.	ADN (ammonium dinitramide or SR 12) (CAS 140456-78-6);
2.	AP (ammonium perchlorate) (CAS 7790-98-9);
3.	Compounds composed of fluorine and any of the following:
	a. Other halogens;
	 b. Oxygen; <u>or</u> c. Nitrogen;
	<u>Note 1</u> ML8.d.3 does not control chlorine trifluoride.
	<u>Note 2</u> <i>ML8.d.3 does not control nitrogen trifluoride in its gaseous state.</i>
4.	DNAD (1,3-dinitro-1,3-diazetidine) (CAS 78246-06-7);
5.	HAN (hydroxylammonium nitrate) (CAS 13465-08-2);
6.	HAP (hydroxylammonium perchlorate) (CAS 15588-62-2);
7.	HNF (hydrazinium nitroformate) (CAS 20773-28-8);
8.	Hydrazine nitrate (CAS 37836-27-4);
9. 10.	Hydrazine perchlorate (CAS 27978-54-7); Liquid oxidisers comprised of or containing inhibited red fuming nitric acid
10.	(IRFNA) (CAS 8007-58-7);
	<u>Note</u> ML8.d.10 does not control non-inhibited fuming nitric acid.

- ML8. e. Binders, plasticizers, monomers, polymers, as follows:
 - 1. AMMO (azidomethylmethyloxetane and its polymers) (CAS 90683-29-7) (see also ML8.g.1. for its "precursors");
 - 2. BAMO (bisazidomethyloxetane and its polymers) (CAS 17607-20-4) (see also ML8.g.1. for its "precursors");
 - 3. BDNPA (bis (2,2-dinitropropyl)acetal) (CAS 5108-69-0);
 - 4. BDNPF (bis (2,2-dinitropropyl)formal) (CAS 5917-61-3);
 - 5. BTTN (butanetrioltrinitrate) (CAS 6659-60-5) (see also ML8.g.8. for its "precursors");
 - 6. Energetic monomers, plasticizers and polymers containing nitro, azido, nitrate, nitraza or difluoroamino groups specially formulated for military use;
 - 7. FAMAO (3-difluoroaminomethyl-3-azidomethyl oxetane) and its polymers;
 - 8. FEFO (bis-(2-fluoro-2,2-dinitroethyl) formal) (CAS 17003-79-1);
 - 9. FPF-1 (poly-2,2,3,3,4,4-hexafluoropentane-1,5-diol formal) (CAS 376-90-9);
 - 10. FPF-3 (poly-2,4,4,5,5,6,6-heptafluoro-2-tri-fluoromethyl-3-oxaheptane-1,7-diol formal);
 - 11. GAP (glycidylazide polymer) (CAS 143178-24-9) and its derivatives;
 - HTPB (hydroxyl terminated polybutadiene) with a hydroxyl functionality equal to or greater than 2.2 and less than or equal to 2.4, a hydroxyl value of less than 0.77 meq/g, and a viscosity at 30°C of less than 47 poise (CAS 69102-90-5);
 - 13. Low (less then 10,000) molecular weight, alcohol functionalised, poly(epichlorohydrin); poly(epichlorohydrindiol) and triol;
 - 14. NENAs (nitratoethylnitramine compounds) (CAS 17096-47-8, 85068-73-1, 82486-83-7, 82486-82-6 and 85954-06-9);
 - 15. PGN (poly-GLYN, polyglycidylnitrate or poly(nitratomethyl oxirane) (CAS 27814-48-8);
 - 16. Poly-NIMMO (poly nitratomethylmethyloxetane) or poly-NMMO (poly[3-Nitratomethyl-3-methyloxetane]) (CAS 84051-81-0);
 - 17. Polynitroorthocarbonates;
 - 18. TVOPA (1,2,3-tris[1,2-bis(difluoroamino)ethoxy] propane or tris vinoxy propane adduct) (CAS 53159-39-0).
- ML8. f. "Additives", as follows:
 - 1. Basic copper salicylate (CAS 62320-94-9);
 - 2. BHEGA (bis-(2-hydroxyethyl) glycolamide) (CAS 17409-41-5);
 - 3. BNO (butadienenitrileoxide) (CAS 9003-18-3);
 - 4. Ferrocene derivatives, as follows:
 - a. Butacene (CAS 125856-62-4);
 - b. Catocene (2,2-bis-ethylferrocenyl propane) (CAS 37206-42-1);
 - c. Ferrocene carboxylic acids;
 - d. n-butyl-ferrocene (CAS 31904-29-7);
 - e. Other adducted polymer ferrocene derivatives;
 - 5. Lead beta-resorcylate (CAS 20936-32-7);
 - 6. Lead citrate (CAS 14450-60-3);
 - 7. Lead-copper chelates of beta-resorcylate or salicylates (CAS 68411-07-4);
 - 8. Lead maleate (CAS 19136-34-6);
 - 9. Lead salicylate (CAS 15748-73-9);
 - 10. Lead stannate (CAS 12036-31-6);

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- ML8. f. 11. MAPO (tris-1-(2-methyl)aziridinyl phosphine oxide) (CAS 57-39-6); BOBBA 8 (bis(2-methyl aziridinyl) 2-(2-hydroxypropanoxy) propylamino phosphine oxide); and other MAPO derivatives;
 - 12. Methyl BAPO (bis(2-methyl aziridinyl) methylamino phosphine oxide) (CAS 85068-72-0);
 - 13. N-methyl-p-nitroaniline (CAS 100-15-2);
 - 14. 3-Nitraza-1,5-pentane diisocyanate (CAS 7406-61-9);
 - 15. Organo-metallic coupling agents, as follows:
 - a. Neopentyl[diallyl]oxy, tri[dioctyl]phosphato-titanate (CAS 103850-22-2); also known as titanium IV, 2,2[bis 2-propenolato-methyl, butanolato, tris (dioctyl) phosphato] (CAS 110438-25-0); or LICA 12 (CAS 103850-22-2);
 - b. Titanium IV, [(2-propenolato-1) methyl, n-propanolatomethyl] butanolato-1, tris[dioctyl] pyrophosphate or KR3538;
 - c. Titanium IV, [(2-propenolato-1)methyl, n-propanolatomethyl] butanolato-1, tris(dioctyl)phosphate;
 - 16. Polycyanodifluoroaminoethyleneoxide;
 - 17. Polyfunctional aziridine amides with isophthalic, trimesic (BITA or butylene imine trimesamide), isocyanuric or trimethyladipic backbone structures and 2-methyl or 2-ethyl substitutions on the aziridine ring;
 - 18. Propyleneimine (2-methylaziridine) (CAS 75-55-8);
 - 19. Superfine iron oxide (Fe₂O₃) with a specific surface area more than $250 \text{ m}^2/\text{g}$ and an average particle size of 3.0 nm or less;
 - 20. TEPAN (tetraethylenepentaamineacrylonitrile) (CAS 68412-45-3); cyanoethylated polyamines and their salts;
 - 21. TEPANOL (tetraethylenepentaamineacrylonitrileglycidol) (CAS 68412-46-4); cyanoethylated polyamines adducted with glycidol and their salts;
 - 22. TPB (triphenyl bismuth) (CAS 603-33-8).
- ML8. g. "Precursors", as follows:
 - <u>N.B.</u> In ML8.g. the references are to controlled "Energetic Materials" manufactured from these substances.
 - 1. BCMO (bischloromethyloxetane) (CAS 142173-26-0) (see also ML8.e.1. and e.2.);
 - 2. Dinitroazetidine-t-butyl salt (CAS 125735-38-8) (see also ML8.a.28.);
 - 3. HBIW (hexabenzylhexaazaisowurtzitane) (CAS 124782-15-6) (see also ML8.a.4.);
 - 4. TAIW (tetraacetyldibenzylhexaazaisowurtzitane) (see also ML8.a.4.);
 - 5. TAT (1,3,5,7 tetraacetyl-1,3,5,7,-tetraaza cyclo-octane) (CAS 41378-98-7) (see also ML8.a.13.);
 - 6. 1,4,5,8-tetraazadecalin (CAS 5409-42-7) (see also ML8.a.27.);
 - 7. 1,3,5-trichlorobenzene (CAS 108-70-3) (see also ML8.a.23.);
 - 8. 1,2,4-trihydroxybutane (1,2,4-butanetriol) (CAS 3068-00-6) (see also ML8.e.5.).

- <u>Note 5</u> For charges and devices see ML4.
- <u>Note 6</u> ML8. does not control the following substances unless they are compounded or mixed with the "energetic material" mentioned in ML8.a. or powdered metals in ML8.c.:
 - a. Ammonium picrate;
 - b. Black powder;
 - *c. Hexanitrodiphenylamine;*
 - d. Difluoroamine;
 - e. Nitrostarch;
 - f. Potassium nitrate;
 - g. Tetranitronaphthalene;
 - *h. Trinitroanisol;*
 - *i. Trinitronaphthalene;*
 - j. Trinitroxylene;
 - *k. N-pyrrolidinone; 1-methyl-2-pyrrolidinone;*
 - *l. Dioctylmaleate;*
 - *m. Ethylhexylacrylate;*
 - n. Triethylaluminium (TEA), trimethylaluminium (TMA), and other pyrophoric metal alkyls and aryls of lithium, sodium, magnesium, zinc or boron;
 - o. Nitrocelluose;
 - p. Nitroglycerin (or glyceroltrinitrate, trinitroglycerine) (NG);
 - q. 2,4,6-trinitrotoluene (TNT);
 - *r. Ethylenediaminedinitrate (EDDN);*
 - s. Pentaerythritoltetranitrate (PETN);
 - t. Lead azide, normal and basic lead styphnate, and primary explosives or priming compositions containing azides or azide complexes;
 - u. Triethyleneglycoldinitrate (TEGDN);
 - v. 2,4,6-trinitroresorcinol (styphnic acid);
 - *w. Diethyldiphenyl urea; dimethylidiphenyl urea; methylethyldiphenyl urea [Centralites];*
 - *x. N*,*N*-diphenylurea (unsymmetrical diphenylurea);
 - y. *Methyl-N,N-diphenylurea (methyl unsymmetrical diphenylurea);*
 - z. Ethyl-N,N-diphenylurea (ethyl unsymmetrical diphenylurea);
 - aa. 2-Nitrodiphenylamine (2-NDPA);
 - *bb.* 4-Nitrodiphenylamine (4-NDPA);
 - cc. 2,2-dinitropropanol;
 - dd. Nitroguanidine (see 1.C.11.d. on the Dual-Use List).

ML9. Vessels of war, special naval equipment and accessories, as follows, and components therefor, specially designed for military use:

<u>N.B.</u> For guidance and navigation equipment, see ML11, Note 7.

- a. Combatant vessels and vessels (surface or underwater) specially designed or modified for offensive or defensive action, whether or not converted to nonmilitary use, regardless of current state of repair or operating condition, and whether or not they contain weapon delivery systems or armour, and hulls or parts of hulls for such vessels;
- b. Engines, as follows:
 - 1. Diesel engines specially designed for submarines with both of the following characteristics:
 - a. A power output of 1.12 MW (1,500 hp.) or more; and
 - b. A rotary speed of 700 rpm or more;
 - 2. Electric motors specially designed for submarines having all of the following characteristics:
 - a. A power output of more than 0.75 MW (1,000 hp.);
 - b. Quick reversing;
 - c. Liquid cooled; and
 - d. Totally enclosed;
 - 3. Non-magnetic diesel engines specially designed for military use with a power output of 37.3 kW (50 hp.) or more and with a non-magnetic content in excess of 75% of total mass;
- c. Underwater detection devices specially designed for military use and controls thereof;
- d. Submarine and torpedo nets;
- e. Deleted
- f. Hull penetrators and connectors specially designed for military use that enable interaction with equipment external to a vessel;
 - <u>Note</u> ML9.f. includes connectors for vessels which are of the single-conductor, multi-conductor, coaxial or waveguide type, and hull penetrators for vessels, both of which are capable of remaining impervious to leakage from without and of retaining required characteristics at marine depths exceeding 100 m; and fibre-optic connectors and optical hull penetrators specially designed for "laser" beam transmission regardless of depth. It does not include ordinary propulsive shaft and hydrodynamic control-rod hull penetrators.
- g. Silent bearings, with gas or magnetic suspension, active signature or vibration suppression controls, and equipment containing those bearings, specially designed for military use.

ML10. "Aircraft", "lighter-than-air vehicles", unmanned airborne vehicles, aero-engines and "aircraft" equipment, related equipment and components, specially designed or modified for military use, as follows:

<u>N.B.</u> For guidance and navigation equipment, see ML11, Note 7.

- a. Combat "aircraft" and specially designed components therefor;
- b. Other "aircraft" and "lighter-than-air vehicles" specially designed or modified for military use, including military reconnaissance, assault, military training, transporting and airdropping troops or military equipment, logistics support, and specially designed components therefor;
- c. Unmanned airborne vehicles and related equipment, specially designed or modified for military use, as follows, and specially designed components therefor:
 - 1. Unmanned airborne vehicles including remotely piloted air vehicles (RPVs), autonomous programmable vehicles and "lighter-than-air vehicles";
 - 2. Associated launchers and ground support equipment;
 - 3. Related equipment for command and control.
- d. Aero-engines specially designed or modified for military use, and specially designed components therefor;
- e. Airborne equipment, including airborne refuelling equipment, specially designed for use with the "aircraft" controlled by ML10.a. or ML10.b. or the aero-engines controlled by ML10.d., and specially designed components therefor;
- f. Pressure refuellers, pressure refuelling equipment, equipment specially designed to facilitate operations in confined areas and ground equipment, developed specially for "aircraft" controlled by ML10.a. or ML10.b., or for aero-engines controlled by ML10.d.;
- g. Military crash helmets and protective masks and specially designed components therefor, pressurised breathing equipment and partial pressure suits for use in "aircraft", anti-g suits, liquid oxygen converters used for "aircraft" or missiles, and catapults and cartridge actuated devices for emergency escape of personnel from "aircraft";
- h. Parachutes and related equipment, used for combat personnel, cargo dropping or "aircraft" deceleration, as follows, and specially designed components therefor:
 - 1. Parachutes for:
 - a. Pin point dropping of rangers;
 - b. Dropping of paratroopers;

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- ML10.h. 2. Cargo parachutes;
 - 3. Paragliders, drag parachutes, drogue parachutes for stabilisation and attitude control of dropping bodies, (e.g. recovery capsules, ejection seats, bombs);
 - 4. Drogue parachutes for use with ejection seat systems for deployment and inflation sequence regulation of emergency parachutes;
 - 5. Recovery parachutes for guided missiles, drones or space vehicles;
 - 6. Approach parachutes and landing deceleration parachutes;
 - 7. Other military parachutes;
 - 8. Equipment specially designed for high altitude parachutists (e.g., suits, special helmets, breathing systems, navigation equipment);
- ML10.i. Automatic piloting systems for parachuted loads; equipment specially designed or modified for military use for controlled opening jumps at any height, including oxygen equipment.
- <u>Note 1</u> ML10.b. does not control "aircraft" or variants of those "aircraft" specially designed for military use which:
 - a. Are not configured for military use and are not fitted with equipment or attachments specially designed or modified for military use; <u>and</u>
 - b. Have been certified for civil use by the civil aviation authority in a participating state.
- <u>Note 2</u> ML10.d. does not control:
 - a. Aero-engines designed or modified for military use which have been certified by civil aviation authorities in a participating state for use in "civil aircraft", or specially designed components therefor;
 - b. Reciprocating engines or specially designed components therefor, except those specially designed for unmanned airborne vehicles.
- <u>Note 3</u> The control in ML10.b. and ML10.d. on specially designed components and related equipment for non-military "aircraft" or aero-engines modified for military use applies only to those military components and to military related equipment required for the modification to military use.

- ML11. Electronic equipment, not controlled elsewhere on the Munitions List as follows, and specially designed components therefor:
 - a. Electronic equipment specially designed for military use.
 - <u>Note</u> ML11.a. includes:
 - 1. Electronic countermeasure and electronic counter-countermeasure equipment (i.e., equipment designed to introduce extraneous or erroneous signals into radar or radio communication receivers or otherwise hinder the reception, operation or effectiveness of adversary electronic receivers including their countermeasure equipment), including jamming and counter-jamming equipment;
 - 2. Frequency agile tubes;
 - 3. Electronic systems or equipment designed either for surveillance and monitoring of the electro-magnetic spectrum for military intelligence or security purposes or for counteracting such surveillance and monitoring;
 - 4. Underwater countermeasures, including acoustic and magnetic jamming and decoy, equipment designed to introduce extraneous or erroneous signals into sonar receivers;
 - 5. Data processing security equipment, data security equipment and transmission and signalling line security equipment, using ciphering processes;
 - 6. Identification, authentification and keyloader equipment and key management, manufacturing and distribution equipment.
 - 7. Guidance and navigation equipment.
 - b. Global Navigation Satellite Systems (GNSS) jamming equipment.

- ML12. High velocity kinetic energy weapon systems and related equipment, as follows, and specially designed components therefor:
 - a. Kinetic energy weapon systems specially designed for destruction or effecting mission-abort of a target;
 - b. Specially designed test and evaluation facilities and test models, including diagnostic instrumentation and targets, for dynamic testing of kinetic energy projectiles and systems.
 - <u>N.B.</u> For weapon systems using sub-calibre ammunition or employing solely chemical propulsion, and ammunition therefor, see ML1. to ML4.
 - <u>Note 1</u> ML12. includes the following when specially designed for kinetic energy weapon systems:
 - a. Launch propulsion systems capable of accelerating masses larger than 0.1 g to velocities in excess of 1.6 km/s, in single or rapid fire modes;
 - b. Prime power generation, electric armour, energy storage, thermal management, conditioning, switching or fuel-handling equipment; and electrical interfaces between power supply, gun and other turret electric drive functions;
 - c. Target acquisition, tracking, fire control or damage assessment systems;
 - d. Homing seeker, guidance or divert propulsion (lateral acceleration) systems for projectiles.
 - <u>Note 2</u> *ML12. controls weapon systems using any of the following methods of propulsion:*
 - a. Electromagnetic;
 - b. Electrothermal;
 - c. Plasma;
 - d. Light gas; or
 - e. Chemical (when used in combination with any of the above).

- ML13. Armoured or protective equipment and constructions and components, as follows:
 - a. Armoured plate as follows:
 - 1. Manufactured to comply with a military standard or specification; or
 - 2. Suitable for military use;
 - b. Constructions of metallic or non-metallic materials or combinations thereof specially designed to provide ballistic protection for military systems, and specially designed components therefor;
 - c. Military helmets;
 - d. Body armour and protective garments manufactured according to military standards or specifications, or equivalent, and specially designed components therefor.
 - <u>N.B.</u> For "fibrous or filamentary materials" used in the manufacture of body armour, see entry 1.C.10. on the Dual-Use List.
 - <u>Note 1</u> *ML13.b.* includes materials specially designed to form explosive reactive armour or to construct military shelters.
 - <u>Note 2</u> *ML13.c.* does not control conventional steel helmets, neither modified or designed to accept, nor equipped with any type of accessory device.
 - <u>Note 3</u> *ML13.d.* does not control body armour or protective garments when accompanying their user for the user's own personal protection.
 - <u>N.B.</u> See also entry 1.A.5. on the Dual-Use List.
- ML14. Specialised equipment for military training or for simulating military scenarios, simulators specially designed for training in the use of any firearm or weapon controlled by ML1. or ML2., and specially designed components and accessories therefor.

Technical Note

The term 'specialised equipment for military training' includes military types of attack trainers, operational flight trainers, radar target trainers, radar target generators, gunnery training devices, anti-submarine warfare trainers, flight simulators (including human-rated centrifuges for pilot/astronaut training), radar trainers, instrument flight trainers, navigation trainers, missile launch trainers, target equipment, drone "aircraft", armament trainers, pilotless "aircraft" trainers, mobile training units and training equipment for ground military operations.

- <u>Note 1</u> *ML14. includes image generating and interactive environment systems for simulators when specially designed or modified for military use.*
- <u>Note 2</u> *ML14. does not control equipment specially designed for training in the use of hunting or sporting weapons.*

- ML15. Imaging or countermeasure equipment, as follows, specially designed for military use, and specially designed components and accessories therefor:
 - a. Recorders and image processing equipment;
 - b. Cameras, photographic equipment and film processing equipment;
 - c. Image intensifier equipment;
 - d. Infrared or thermal imaging equipment;
 - e. Imaging radar sensor equipment;
 - f. Countermeasure or counter-countermeasure equipment for the equipment controlled by sub-items ML15.a. to ML15.e.
 - <u>Note</u> ML15.f. includes equipment designed to degrade the operation or effectiveness of military imaging systems or to minimize such degrading effects.
 - <u>Note 1</u> The term 'specially designed components' includes the following when specially designed for military use:
 - a. Infrared image converter tubes;
 - b. Image intensifier tubes (other than first generation);
 - c. Microchannel plates;
 - d. Low-light-level television camera tubes;
 - e. Detector arrays (including electronic interconnection or read out systems);
 - f. Pyroelectric television camera tubes;
 - g. Cooling systems for imaging systems;
 - h. Electrically triggered shutters of the photochromic or electro-optical type having a shutter speed of less than 100 μ s, except in the case of shutters which are an essential part of a high speed camera;
 - *i. Fibre optic image inverters;*
 - *j.* Compound semiconductor photocathodes.
 - <u>Note 2</u> ML15 does not control "first generation image intensifier tubes" or equipment specially designed to incorporate "first generation image intensifier tubes".
 - <u>N.B.</u> For the status of weapons sights incorporating "first generation image intensifier tubes" see entries ML1., ML2. and ML5.a.
 - <u>N.B.</u> See also entries 6.A.2.a.2. and 6.A.2.b. on the Dual-Use List.
- ML16. Forgings, castings and other unfinished products the use of which in a controlled product is identifiable by material composition, geometry or function, and which are specially designed for any products controlled by ML1.to ML4., ML6., ML9., ML10., ML12. or ML19.

- ML17. Miscellaneous equipment, materials and libraries, as follows, and specially designed components therefor:
 - a. Self-contained diving and underwater swimming apparatus, as follows:
 - 1. Closed or semi-closed circuit (rebreathing) apparatus specially designed for military use (i.e. specially designed to be non magnetic);
 - 2. Specially designed components for use in the conversion of open-circuit apparatus to military use;
 - 3. Articles designed exclusively for military use with self-contained diving and underwater swimming apparatus;
 - b. Construction equipment specially designed for military use;
 - c. Fittings, coatings and treatments for signature suppression, specially designed for military use;
 - d. Field engineer equipment specially designed for use in a combat zone;
 - e. "Robots", "robot" controllers and "robot" "end-effectors", having any of the following characteristics:
 - 1. Specially designed for military use;
 - 2. Incorporating means of protecting hydraulic lines against externally induced punctures caused by ballistic fragments (e.g., incorporating self-sealing lines) and designed to use hydraulic fluids with flash points higher than 839 K (566°C); or
 - 3. Specially designed or rated for operating in an electro-magnetic pulse (EMP) environment;
 - f. Libraries (parametric technical databases) specially designed for military use with equipment controlled by the Munitions List;
 - g. Nuclear power generating equipment or propulsion equipment, including "nuclear reactors", specially designed for military use and components therefor specially designed or modified for military use;
 - h. Equipment and material, coated or treated for signature suppression, specially designed for military use, other than those controlled elsewhere in the Munitions List;
 - i. Simulators specially designed for military "nuclear reactors";
 - j. Mobile repair shops specially designed or modified to service military equipment;
 - k. Field generators specially designed or modified for military use;
 - 1. Containers specially designed or modified for military use;
 - m. Ferries, other than those controlled elsewhere in the Munitions List, bridges and pontoons, specially designed for military use;
 - n. Test models specially designed for the "development" of items controlled by ML4., ML6., ML9. or ML10.;
 - o. Laser protection equipment (e.g., eye and sensor protection) specially designed for military use.

Technical Notes

- 1. For the purpose of ML17., the term 'library' (parametric technical database) means a collection of technical information of a military nature, reference to which may enhance the performance of military equipment or systems.
- 2. For the purpose of ML17, 'modified' means any structural, electrical, mechanical, or other change that provides a non-military item with military capabilities equivalent to an item which is specially designed for military use.

- ML18. Equipment for the production of products referred to in the Munitions List, as follows:
 - a. Specially designed or modified production equipment for the production of products controlled by the Munitions List, and specially designed components therefor;
 - b. Specially designed environmental test facilities and specially designed equipment therefor, for the certification, qualification or testing of products controlled by the Munitions List.

Technical Note

For the purposes of ML18., the term 'production' includes design, examination, manufacture, testing and checking.

<u>Note 1</u> *ML*18.*a.* and *ML*18.*b.* include the following equipment:

- a. Continuous nitrators;
 - *b. Centrifugal testing apparatus or equipment having any of the following characteristics:*
 - 1. Driven by a motor or motors having a total rated horsepower of more than 298 kW (400 hp);
 - 2. Capable of carrying a payload of 113 kg or more; or
 - 3. Capable of exerting a centrifugal acceleration of 8 g or more on a payload of 91 kg or more;
- c. Dehydration presses;
- *d.* Screw extruders specially designed or modified for military explosive extrusion;
- e. Cutting machines for the sizing of extruded propellants;
- f. Sweetie barrels (tumblers) 1.85 m or more in diameter and having over 227 kg product capacity;
- g. Continuous mixers for solid propellants;
- *h.* Fluid energy mills for grinding or milling the ingredients of military explosives;
- *i.* Equipment to achieve both sphericity and uniform particle size in metal powder listed in ML8.c.8.;
- *j.* Convection current converters for the conversion of materials listed in ML8.c.3.
- <u>Note 2</u> a. The term 'products referred to in the Munitions List' includes:
 - 1. Products not controlled if inferior to specified concentrations as follows:
 - a. Hydrazine (see ML8.c.4.);
 - b. "Explosives" (see ML8.);
 - 2. Products not controlled if inferior to technical limits, (i.e., "superconductive" materials not controlled by 1.C.5. on the Dual-Use List; "superconductive" electromagnets not controlled by 3.A.1.e.3. on the Dual-Use List; "super-conductive" electrical equipment excluded from control under ML20.b.);
 - 3. Metal fuels and oxidants deposited in laminar form from the vapour phase (see ML8.c.5.);

ML18. Note 2. contd.

b.

- The term 'products referred to in the Munitions List' does not include:
 - 1. Signal pistols (see ML2.b.);
 - 2. The substances excluded from control under Note 3 to ML7.;
 - 3. Personal radiation monitoring dosimeters (see ML7.g.) and masks for protection against specific industrial hazards, see also Dual-Use List;
 - 4. Difluoroamine and potassium nitrate powder (see Note 6 to ML8.);
 - 5. Aero-engines excluded from control under ML10.;
 - 6. Conventional steel helmets not equipped with, or modified or designed to accept, any type of accessory device (see Note 2 to ML13.);
 - 7. Equipment fitted with industrial machinery, which is not controlled such as coating machinery not elsewhere specified and equipment for the casting of plastics;
 - 8. Muskets, rifles and carbines dated earlier than 1938, reproductions of muskets, rifles and carbines dated earlier than 1890, revolvers, pistols and machine guns dated earlier than 1890, and their reproductions.
- <u>Note 3</u> Note 2.b.8. of ML18. does not release from controls production equipment for non-antique small arms, even if used to produce reproductions of antique small arms.

- ML19. Directed energy weapon systems (DEW), related or countermeasure equipment and test models, as follows, and specially designed components therefor:
 - a. "Laser" systems specially designed for destruction or effecting mission-abort of a target;
 - b. Particle beam systems capable of destruction or effecting mission-abort of a target;
 - c. High power radio-frequency (RF) systems capable of destruction or effecting mission-abort of a target;
 - d. Equipment specially designed for the detection or identification of, or defence against, systems controlled by ML19.a. to ML19.c.;
 - e. Physical test models and related test results for the systems, equipment and components controlled by this Item.
 - f. Continuous wave or pulsed "laser" systems specially designed to cause permanent blindness to unenhanced vision, i.e., to the naked eye or to the eye with corrective eyesight devices.
 - <u>Note 1</u> Directed energy weapon systems controlled by ML19. include systems whose capability is derived from the controlled application of:
 - a. "Lasers" of sufficient continuous wave or pulsed power to effect destruction similar to the manner of conventional ammunition;
 - *b. Particle accelerators which project a charged or neutral particle beam with destructive power;*
 - c. High pulsed power or high average power radio frequency beam transmitters which produce fields sufficiently intense to disable electronic circuitry at a distant target.
 - <u>Note 2</u> ML19. includes the following when specially designed for directed energy weapon systems:
 - a. Prime power generation, energy storage, switching, power conditioning or fuel-handling equipment;
 - b. Target acquisition or tracking systems;
 - c. Systems capable of assessing target damage, destruction or missionabort;
 - d. Beam-handling, propagation or pointing equipment;
 - *e.* Equipment with rapid beam slew capability for rapid multiple target operations;
 - f. Adaptive optics and phase conjugators;
 - g. Current injectors for negative hydrogen ion beams;
 - *h.* "Space qualified" accelerator components;
 - *i.* Negative ion beam funnelling equipment;
 - *j.* Equipment for controlling and slewing a high energy ion beam;
 - *k.* "Space qualified" foils for neutralising negative hydrogen isotope beams.

- ML20. Cryogenic and "superconductive" equipment, as follows, and specially designed components and accessories therefor:
 - Equipment specially designed or configured to be installed in a vehicle for military ground, marine, airborne or space applications, capable of operating while in motion and of producing or maintaining temperatures below 103 K (- 170°C);
 - <u>Note</u> ML20.a. includes mobile systems incorporating or employing accessories or components manufactured from non-metallic or non-electrical conductive materials, such as plastics or epoxy-impregnated materials.
 - b. "Superconductive" electrical equipment (rotating machinery and transformers) specially designed or configured to be installed in a vehicle for military ground, marine, airborne or space applications, capable of operating while in motion.
 - <u>Note</u> ML20.b. does not control direct-current hybrid homopolar generators that have single-pole normal metal armatures which rotate in a magnetic field produced by superconducting windings, provided those windings are the only superconducting component in the generator.
- ML21. "Software", as follows:
 - a. "Software" specially designed or modified for the "development", "production" or "use" of equipment or materials controlled by the Munitions List;
 - b. Specific "software", as follows:
 - 1. "Software" specially designed for:
 - a. Modelling, simulation or evaluation of military weapon systems;
 - b. "Development", monitoring, maintenance or up-dating of "software" embedded in military weapon systems;
 - c. Modelling or simulating military operation scenarios, not controlled by ML14.;
 - d. Command, Communications, Control and Intelligence (C³I) or Command, Communications, Control, Computer and Intelligence (C⁴I) applications;
 - 2. "Software" for determining the effects of conventional, nuclear, chemical or biological warfare weapons.
 - 3. "Software", not controlled by ML21.a., b.1. or b.2., specially designed or modified to enable equipment not controlled by the Munitions List to perform the military functions of equipment controlled by ML5., ML7.g., ML9.c., ML9.e., ML10.e., ML11., ML14., ML15., ML17.i., or ML18.

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- ML22. "Technology" as follows:
 - a. "Technology", other than specified in ML22.b, which is "required" for the "development", "production" or "use" of items controlled in the Munitions List.
 - b. "Technology" as follows:
 - 1. "Technology" "required" for the design of, the assembly of components into, and the operation, maintenance and repair of complete production installations for items controlled in the Munitions List, even if the components of such production installations are not controlled;
 - 2. "Technology" "required" for the "development" and "production" of small arms even if used to produce reproductions of antique small arms;
 - 3. "Technology" "required" for the "development", "production" or "use" of toxicological agents, related equipment or components controlled by ML7.a. to ML7.g.;
 - 4. "Technology" "required" for the "development", "production" or "use" of "biopolymers" or cultures of specific cells controlled by ML7.h.;
 - 5. "Technology" "required" exclusively for the incorporation of "biocatalysts", controlled by ML7.i.1., into military carrier substances or military material.
 - <u>Note 1</u> "Technology" "required" for the "development", "production" or "use" of items controlled in the Munitions List remains under control even when applicable to any uncontrolled item.
 - <u>Note 2</u> ML22 does not control "technology" as follows:
 - a. Which is the minimum necessary for the installation, operation, maintenance (checking) and repair of those items which are not controlled or whose export has been authorised;
 - b. Which is "in the public domain", "basic scientific research" or the minimum necessary information for patent applications;
 - *c.* For magnetic induction for continuous propulsion of civil transport devices.

DEFINITIONS OF TERMS USED IN THESE LISTS

This document contains the definitions of the terms used in these Lists, in alphabetical order.

- <u>Note 1</u> Definitions apply throughout the Lists and their Annexes. The references are purely advisory and have no effect on the universal application of defined terms throughout these Lists and their Annexes.
- <u>Note 2</u> Words and terms contained in the List of Definitions only take the defined meaning where this is indicated by their being enclosed in quotations marks (""). Elsewhere, words and terms take their commonly accepted (dictionary) meanings, unless a local definition for a particular control is given. (See also 'Statements of Understanding and Validity Notes Definition of Terms used in these Lists').

Cat 2 "Accuracy"

Cat 6 (Usually measured in terms of inaccuracy) is the maximum deviation, positive or negative, of an indicated value from an accepted standard or true value.

Cat 7 "Active flight control systems" Function to prevent undesirable "aircraft" and missile motions or structural loads by autonomously processing outputs from multiple sensors and then providing necessary preventive commands to effect automatic control.

Cat 6 "Active pixel"

Cat 8

A minimum (single) element of the solid state array which has a photoelectric transfer function when exposed to light (electromagnetic) radiation.

- Cat 1 "Adapted for use in war"
- ML 7 Any modification or selection (such as altering purity, shelf life, virulence, dissemination characteristics, or resistance to UV radiation) designed to increase the effectiveness in producing casualties in humans or animals, degrading equipment or damaging crops or the environment.
- ML8. "Additives" Substances used in explosive formulations to improve their properties.

Cat 1	"Aircraft"
Cat 7 & 9 ML 8, 9 &	A fixed wing, swivel wing, rotary wing (helicopter), tilt rotor or tilt- 10 wing airborne vehicle.
Cat 2	"All compensations available" "All compensations available" means after all feasible measures available to the manufacturer to minimise all systematic positioning errors for the particular machine-tool model are considered.
Cat 3 Cat 5 P1	"Allocated by the ITU" The allocation of frequency bands according to the current edition of the ITU Radio Regulations for primary, permitted and secondary services. <u>N.B.</u> Additional and alternative allocations are not included.
Cat 2	"Angular position deviation" The maximum difference between angular position and the actual, very accurately measured angular position after the workpiece mount of the table has been turned out of its initial position. (Reference: VDI/VDE 2617, Draft: 'Rotary tables on coordinate measuring machines').
Cat 5	"Asymmetric algorithm" A cryptographic algorithm using different, mathematically-related keys for encryption and decryption. <u>Technical Note</u> A common use of "asymmetric algorithms" is key management.
Cat 6	"Automatic target tracking" A processing technique that automatically determines and provides as output an extrapolated value of the most probable position of the target in real time.
Cat 3	 "Basic gate propagation delay time" The propagation delay time value corresponding to the basic gate used in a "monolithic integrated circuit". For a 'family' of "monolithic integrated circuits", this may be specified either as the propagation delay time per typical gate within the given 'family' or as the typical propagation delay time per gate within the given 'family'. <u>Technical Notes</u> 1. "Basic gate propagation delay time" is not to be confused with the input/output delay time of a complex "monolithic integrated circuit". 2. 'Family' consists of all integrated circuits to which all of the following are applied as their manufacturing methodology and specifications except their respective functions: a. The common hardware and software architecture; b. The common design and process technology; and c. The common basic characteristics.

GTN	"Basic scientific research" Experimental or theoretical work undertaken principally to acquire new knowledge of the fundamental principles of phenomena or observable facts, not primarily directed towards a specific practical aim or objective.
Cat 7	"Bias" (accelerometer) An accelerometer output when no acceleration is applied.
ML 7, 22	"Biocatalysts" Enzymes for specific chemical or biochemical reactions or other biological compounds which bind to and accelerate the degradation of CW agents. <u>Technical Note</u> 'Enzymes' means "biocatalysts" for specific chemical or biochemical reactions.
ML 7, 22	 "Biopolymers" Biological macromolecules as follows: a. Enzymes for specific chemical or biochemical reactions; b. Antibodies, monoclonal, polyclonal or anti-idiotypic; c. Specially designed or specially processed receptors; <u>Technical Notes</u> 1. 'Anti-idiotypic antibodies' means antibodies which bind to the specific antigen binding sites of other antibodies; 2. 'Monoclonal antibodies' means proteins which bind to one antigenic site and are produced by a single clone of cells; 3. 'Polyclonal antibodies' means a mixture of proteins which bind to the specific antigen and are produced by more than one clone of cells; 4. 'Receptors' means biological macromolecular structures capable of binding ligands, the binding of which affects physiological functions.
Cat 2	"Camming" (axial displacement) Axial displacement in one revolution of the main spindle measured in a plane perpendicular to the spindle faceplate, at a point next to the circumference of the spindle faceplate (Reference: ISO 230/1 1986, paragraph 5.63).
Cat 1	"Carbon fibre preforms" An ordered arrangement of uncoated or coated fibres intended to constitute a framework of a part before the "matrix" is introduced to form a "composite".
Cat 4	"CE" "CE" is equivalent to "computing element".
Cat 6	"Chemical Laser" A "laser" in which the excited species is produced by the output energy from a chemical reaction.

	"Circuit element" A single active or passive functional part of an electronic circuit, such as one diode, one transistor, one resistor, one capacitor, etc.
Cat 7	"Circulation-controlled anti-torque or circulation-controlled direction control systems" Control systems using air blown over aerodynamic surfaces to increase or control the forces generated by the surfaces.
Cat 1 Cat 7 Cat 9 ML 10	"Civil aircraft" Those "aircraft" listed by designation in published airworthiness certification lists by the civil aviation authorities to fly commercial civil internal and external routes or for legitimate civil, private or business use.
Cat 1	"Commingled" Filament to filament blending of thermoplastic fibres and reinforcement fibres in order to produce a fibre reinforcement "matrix" mix in total fibre form.
Cat 1	"Comminution" A process to reduce a material to particles by crushing or grinding.
Cat 5	"Common channel signalling" A signalling method in which a single channel between exchanges conveys, by means of labelled messages, signalling information relating to a multiplicity of circuits or calls and other information such as that used for network management.
Cat 4	"Communications channel controller" The physical interface which controls the flow of synchronous or asynchronous digital information. It is an assembly that can be integrated into computer or telecommunications equipment to provide communications access.
Cat 1 Cat 2 Cat 6 Cat 8 & 9	"Composite" A "matrix" and an additional phase or additional phases consisting of particles, whiskers, fibres or any combination thereof, present for a specific purpose or purposes.

Cat 3 Cat 4	 "Composite theoretical performance" ("CTP") A measure of computational performance given in millions of theoretical operations per second (Mtops), calculated using the aggregation of "computing elements" <u>N.B.</u> See Category 4, Technical Note.
Cat 2	"Compound rotary table" A table allowing the workpiece to rotate and tilt about two non-parallel axes, which can be coordinated simultaneously for "contouring control".
Cat 4	"Computing element" ("CE") The smallest computational unit that produces an arithmetic or logic result.
Cat 2	"Contouring control" Two or more "numerically controlled" motions operating in accordance with instructions that specify the next required position and the required feed rates to that position. These feed rates are varied in relation to each other so that a desired contour is generated (Ref. ISO/DIS 2806 - 1980).
Cat 1 Cat 3 Cat 6	"Critical temperature" (sometimes referred to as the transition temperature) of a specific "superconductive" material is the temperature at which the material loses all resistance to the flow of direct electrical current.
Cat 5	"Cryptography" The discipline which embodies principles, means and methods for the transformation of data in order to hide its information content, prevent its undetected modification or prevent its unauthorized use. "Cryptography" is limited to the transformation of information using one or more secret parameters (e.g., crypto variables) or associated key management. <u>Technical Note</u> 'Secret parameter': a constant or key kept from the knowledge of others or shared only within a group.
Cat 3 Cat 4	"CTP" "CTP" is equivalent to "Composite theoretical performance".
Cat 7	"Data-Based Referenced Navigation" ("DBRN") Systems Systems which use various sources of previously measured geo-mapping data integrated to provide accurate navigation information under dynamic conditions. Data sources include bathymetric maps, stellar maps, gravity maps, magnetic maps or 3-D digital terrain maps.

Cat 5	 "Data signalling rate" The rate, as defined in ITU Recommendation 53-36, taking into account that, for non-binary modulation, baud and bit per second are not equal. Bits for coding, checking and synchronisation functions are to be included. <u>Note</u> When determining the "data signalling rate", servicing and administrative channels shall be excluded. <u>Technical Note</u> It is the maximum one-way rate, i.e., the maximum rate in either transmission or reception.
Cat 6	 "Deformable Mirrors" Mirrors: a. Having a single continuous optical reflecting surface which is dynamically deformed by the application of individual torques or forces to compensate for distortions in the optical waveform incident upon the mirror; <u>or</u> b. Having multiple optical reflecting elements that can be individually and dynamically repositioned by the application of torques or forces to compensate for distortions in the optical waveform incident upon the mirror. "Deformable mirrors" are also known as adaptive optic mirrors.
GTN Both Lists	"Development" Is related to all stages prior to serial production, such as: design, design research, design analyses, design concepts, assembly and testing of prototypes, pilot production schemes, design data, process of transforming design data into a product, configuration design, integration design, layouts.
Cat 1 Cat 2 Cat 9	"Diffusion bonding" A solid state molecular joining of at least two separate metals into a single piece with a joint strength equivalent to that of the weakest material.
Cat 4 Cat 5	 "Digital computer" Equipment which can, in the form of one or more discrete variables, perform all of the following: a. Accept data; b. Store data or instructions in fixed or alterable (writable) storage devices; c. Process data by means of a stored sequence of instructions which is modifiable; <u>and</u> d. Provide output of data. <u>Technical Note</u> Modifications of a stored sequence of instructions include replacement of fixed storage devices, but not a physical change in wiring or interconnections.

Cat 5	"Digital transfer rate" The total bit rate of the information that is directly transferred on any type of medium. (See also "total digital transfer rate").
Cat 2	"Direct-acting hydraulic pressing" A deformation process which uses a fluid-filled flexible bladder in direct contact with the workpiece.
	"Discrete component" A separately packaged "circuit element" with its own external connections.
Cat 7	"Drift rate" (gyro) The time rate of output deviation from the desired output. It consists of random and systematic components and is expressed as an equivalent input angular displacement per unit time with respect to inertial space.
Cat 5	"Dynamic adaptive routing" Automatic rerouting of traffic based on sensing and analysis of current actual network conditions. <u>Note</u> This does not include cases of routing decisions taken on predefined information.
Cat 3	"Dynamic signal analysers" "Signal analysers" which use digital sampling and tranformation techniques to form a Fourier spectrum display of the given waveform including amplitude and phase information.
Cat 1	"Effective gram" "Effective gram" for plutonium isotope is defined as the isotope weight in grams.
Cat 5 Cat 6	"Electronically steerable phased array antenna" An antenna which forms a beam by means of phase coupling, (i.e., the beam direction is controlled by the complex excitation coefficients of the radiating elements) and the direction of that beam can be varied (both in transmission and reception) in azimuth or in elevation, or both, by application of an electrical signal.
Cat 2, 3 Cat 4, 5	"Electronic assembly" A number of electronic components (i.e., "circuit elements", "discrete components", integrated circuits, etc.) connected together to perform (a) specific function(s), replaceable as an entity and normally capable of being disassembled.

Cat 2 ML17	 "End-effectors" Grippers, active tooling units and any other tooling that is attached to the baseplate on the end of a "robot" manipulator arm. <u>Technical Note</u> 'Active tooling units' are devices for applying motive power, process energy or sensing to a workpiece.
ML4 ML8	"Energetic materials" Substances or mixtures that react chemically to release energy required for their intended application. "Explosives", "pyrotechnics" and "propellants" are subclasses of energetic materials.
Cat 6	"Equivalent Density" The mass of an optic per unit optical area projected onto the optical surface.
Cat 4 Cat 7	 "Expert systems" Systems providing results by application of rules to data which are stored independently of the "programme" and capable of any of the following: a. Modifying automatically the "source code" introduced by the user; b. Providing knowledge linked to a class of problems in quasi-natural language; <u>or</u> c. Acquiring the knowledge required for their development (symbolic training).
ML 8, 18	"Explosives" Solid, liquid or gaseous substances or mixtures of substances which, in their application as primary, booster, or main charges in warheads, demolition and other applications, are required to detonate.
ML 7	"Expression Vectors" Carriers (e.g., plasmid or virus) used to introduce genetic material into host cells.
Cat 7 Cat 9	"FADEC" Full Authority Digital Engine Control (FADEC) - an electronic control system for gas turbine or combined cycle engines utilising a digital computer to control the variables required to regulate engine thrust or shaft power output throughout the engine operating range from the beginning of fuel metering to fuel shutoff.

Cat 4	"Fault tolerance" The capability of a computer system, after any malfunction of any of its hardware or "software" components, to continue to operate without human intervention, at a given level of service that provides continuity of operation, data integrity and recovery of service within a given time.
Cat 1 Cat 8	 "Fibrous or filamentary materials" Include: a. Continuous monofilaments; b. Continuous yarns and rovings; c. Tapes, fabrics, random mats and braids; d. Chopped fibres, staple fibres and coherent fibre blankets; e. Whiskers, either monocrystalline or polycrystalline, of any length; f. Aromatic polyamide pulp.
Cat 3	"Film type integrated circuit" An array of "circuit elements" and metallic interconnections formed by deposition of a thick or thin film on an insulating "substrate".
ML 15	"First generation image intensifier tubes" Electrostatically focused tubes, employing input and output fibre optic or glass face plates, multi-alkali photocathodes (S-20 or S-25), but not microchannel plate amplifiers.
Cat 5	"Fixed" The coding or compression algorithm cannot accept externally supplied parameters (e.g., cryptographic or key variables) and cannot be modified by the user.
Cat 7	"Flight control optical sensor array" A network of distributed optical sensors, using "laser" beams, to provide real-time flight control data for on-board processing.
Cat 7	"Flight path optimization" A procedure that minimizes deviations from a four-dimensional (space and time) desired trajectory based on maximizing performance or effectiveness

for mission tasks.

Cat 6	 "Focal plane array" A linear or two-dimensional planar layer, or combination of planar layers, of individual detector elements, with or without readout electronics, which work in the focal plane. <u>Note</u> This definition does not include a stack of single detector elements or any two, three or four element detectors provided time delay and integration is not performed within the element.
Cat 3	"Fractional bandwidth" The "instantaneous bandwidth" divided by the centre frequency, expressed as a percentage.
Cat 5	"Frequency hopping " A form of "spread spectrum" in which the transmission frequency of a single communication channel is made to change by a random or pseudo- random sequence of discrete steps.
Cat 3 Cat 5	 "Frequency switching time" The maximum time (i.e., delay) taken by a signal, when switched from one selected output frequency to another selected output frequency, to reach any of the following: a. A frequency within 100 Hz of the final frequency; or b. An output level within 1 dB of the final output level.
Cat 3	"Frequency synthesiser" Any kind of frequency source or signal generator, regardless of the actual technique used, providing a multiplicity of simultaneous or alternative output frequencies, from one or more outputs, controlled by, derived from or disciplined by a lesser number of standard (or master) frequencies.
Cat 1	"Gas atomisation" A process to reduce a molten stream of metal alloy to droplets of 500 µm diameter or less by a high pressure gas stream.
Cat 6	"Geographically dispersed" Sensors are considered "geographically dispersed" when each location is distant from any other more than 1,500 m in any direction. Mobile sensors are always considered "geographically dispersed".
Cat 2	"Hot isostatic densification" A process of pressurising a casting at temperatures exceeding 375 K (102°C) in a closed cavity through various media (gas, liquid, solid particles, etc.) to create equal force in all directions to reduce or eliminate internal voids in the casting.

Cat 4 "Hybrid computer"

- Equipment which can perform all of the following:
- a. Accept data;
- b. Process data, in both analogue and digital representations; and
- c. Provide output of data.
- Cat 3 "Hybrid integrated circuit" Any combination of integrated circuit(s), or integrated circuit with "circuit elements" or "discrete components" connected together to perform (a) specific function(s), and having all of the following characteristics:
 - a. Containing at least one unencapsulated device;
 - b. Connected together using typical IC production methods;
 - c. Replaceable as an entity; and
 - d. Not normally capable of being disassembled.
- Cat 4 "Image enhancement"

The processing of externally derived information-bearing images by algorithms such as time compression, filtering, extraction, selection, correlation, convolution or transformations between domains (e.g., fast Fourier transform or Walsh transform). This does not include algorithms using only linear or rotational transformation of a single image, such as translation, feature extraction, registration or false coloration.

Cat 5 "Information security"

All the means and functions ensuring the accessibility, confidentiality or integrity of information or communications, excluding the means and functions intended to safeguard against malfunctions. This includes "cryptography", cryptanalysis, protection against compromising emanations and computer security.

Technical Note

'Cryptanalysis': the analysis of a cryptographic system or its inputs and outputs to derive confidential variables or sensitive data, including clear text. (ISO 7498-2-1988 (E), paragraph 3.3.18).

- Cat 3 "Instantaneous bandwidth" Cat 5P1 The bandwidth over which output power remains constant within 3 dB without adjustment of other operating parameters.
- Cat 6 "Instrumented range" The specified unambiguous display range of a radar.
- Cat 6 "Interconnected radar sensors" Two or more radar sensors are interconnected when they mutually exchange data in real time.

GTN GSN ML 22	"In the public domain" This means "technology" or "software" which has been made available without restrictions upon its further dissemination. <u>Note</u> Copyright restrictions do not remove "technology" or "software" from being "in the public domain".
Cat 6	"Intrinsic magnetic gradiometer" A single magnetic field gradient sensing element and associated electronics the output of which is a measure of magnetic field gradient.
Cat 2	"Isostatic presses" Equipment capable of pressurising a closed cavity through various media (gas, liquid, solid particles, etc.) to create equal pressure in all directions within the cavity upon a workpiece or material.
Cat 2, 3, 5, 6 & 9 ML5, 19	"Laser" An assembly of components which produce both spatially and temporally coherent light that is amplified by stimulated emission of radiation.
ML10	"Lighter-than-air vehicles" Balloons and airships that rely on hot air or on lighter-than-air gases such as helium or hydrogen for their lift.
Cat 2	"Linearity" (Usually measured in terms of non-linearity) is the maximum deviation of the actual characteristic (average of upscale and downscale readings), positive or negative, from a straight line so positioned as to equalise and minimise the maximum deviations.
Cat 4	 "Local area network" A data communication system having all of the following characteristics: a. Allows an arbitrary number of independent data devices to communicate directly with each other; and b. Is confined to a geographical area of moderate size (e.g., office building, plant, campus, warehouse). <u>Technical Note</u> 'Data device' means equipment capable of transmitting or receiving sequences of digital information.

Cat 6	"Magnetic gradiometers" Are designed to detect the spatial variation of magnetic fields from sources external to the instrument. They consist of multiple "magnetometers" and associated electronics the output of which is a measure of magnetic field gradient. (See also "Intrinsic Magnetic Gradiometer")
Cat 6	"Magnetometers" Are designed to detect magnetic fields from sources external to the instrument. They consist of a single magnetic field sensing element and associated electronics the output of which is a measure of the magnetic field.
Cat 4	"Main storage" The primary storage for data or instructions for rapid access by a central processing unit. It consists of the internal storage of a "digital computer" and any hierarchical extension thereto, such as cache storage or non-sequentially accessed extended storage.
Cat 1 Cat 2 Cat 8 & 9	"Matrix" A substantially continuous phase that fills the space between particles, whiskers or fibres.
Cat 2	"Measurement uncertainty" The characteristic parameter which specifies in what range around the output value the correct value of the measurable variable lies with a confidence level of 95%. It includes the uncorrected systematic deviations, the uncorrected backlash and the random deviations (Reference: ISO 10360-2, or VDI/VDE 2617).
Cat 1	"Mechanical alloying" An alloying process resulting from the bonding, fracturing and rebonding of elemental and master alloy powders by mechanical impact. Non-metallic particles may be incorporated in the alloy by addition of the appropriate powders.
Cat 1	"Melt extraction" A process to "solidify rapidly" and extract a ribbon-like alloy product by the insertion of a short segment of a rotating chilled block into a bath of a molten metal alloy.
Cat 1	"Melt spinning" A process to "solidify rapidly" a molten metal stream impinging upon a rotating chilled block, forming a flake, ribbon or rod-like product.

Cat 3	 "Microcomputer microcircuit" A "monolithic integrated circuit" or "multichip integrated circuit" containing an arithmetic logic unit (ALU) capable of executing general purpose instructions from an internal storage, on data contained in the internal storage. <u>Technical Note</u> The internal storage may be augmented by an external storage.
Cat 3	 "Microprocessor microcircuit" A "monolithic integrated circuit" or "multichip integrated circuit" containing an arithmetic logic unit (ALU) capable of executing a series of general purpose instructions from an external storage. <u>Technical Note</u> The "microprocessor microcircuit" normally does not contain integral user-accessible storage, although storage present on-the-chip may be used in performing its logic function. <u>Note</u> This definition includes chip sets which are designed to operate together to provide the function of a "microprocessor microcircuit".
	"Microprogramme" A sequence of elementary instructions maintained in a special storage, the execution of which is initiated by the introduction of its reference instruction register.
Cat 3	 "Monolithic integrated circuit" A combination of passive or active "circuit elements" or both which: a. Are formed by means of diffusion processes, implantation processes or deposition processes in or on a single semiconducting piece of material, a so-called 'chip'; b. Can be considered as indivisibly associated; and c. Perform the function(s) of a circuit.
Cat 6	"Monospectral imaging sensors" Are capable of acquisition of imaging data from one discrete spectral band.

Cat 3 "Multichip integrated circuit" Two or more "monolithic integrated circuits" bonded to a common "substrate".

Cat 4 "Multi-data-stream processing"

The "microprogramme" or equipment architecture technique which permits simultaneous processing of two or more data sequences under the control of one or more instruction sequences by means such as:

- a. Single Instruction Multiple Data (SIMD) architectures such as vector or array processors;
- b. Multiple Single Instruction Multiple Data (MSIMD) architectures;
- c. Multiple Instruction Multiple Data (MIMD) architectures, including those which are tightly coupled, closely coupled or loosely coupled; <u>or</u>
- d. Structured arrays of processing elements, including systolic arrays.

Cat 5 "Multilevel security"

A class of system containing information with different sensitivities that simultaneously permits access by users with different security clearances and needs-to-know, but prevents users from obtaining access to information for which they lack authorization.

Technical Note

"Multilevel security" is computer security and not computer reliability which deals with equipment fault prevention or human error prevention in general.

- Cat 6 "Multispectral imaging sensors" Are capable of simultaneous or serial acquisition of imaging data from two or more discrete spectral bands. Sensors having more than twenty discrete spectral bands are sometimes referred to as hyperspectral imaging sensors.
- Cat 4 "Network access controller" A physical interface to a distributed switching network. It uses a common medium which operates throughout at the same "digital transfer rate" using arbitration (e.g., token or carrier sense) for transmission. Independently from any other, it selects data packets or data groups (e.g., IEEE 802) addressed to it. It is an assembly that can be integrated into computer or telecommunications equipment to provide communications access.

Cat 4 "Neural computer" A computational device neuron or a collection

A computational device designed or modified to mimic the behaviour of a neuron or a collection of neurons, i.e., a computational device which is distinguished by its hardware capability to modulate the weights and numbers of the interconnections of a multiplicity of computational components based on previous data.

Cat 6	"Noise level" An electrical signal given in terms of power spectral density. The relation between "noise level" expressed in peak-to-peak is given by $S^2 pp = 8N_0(f_2-f_1)$, where S_{pp} is the peak-to-peak value of the signal (e.g., nanoteslas), N ₀ is the power spectral density (e.g., (nanotesla) ² /Hz) and (f_2-f_1) defines the bandwidth of interest.
ML 17	"Nuclear reactor" Includes the items within or attached directly to the reactor vessel, the equipment which controls the level of power in the core, and the components which normally contain or come into direct contact with or control the primary coolant of the reactor core.
Cat 2	"Numerical control" The automatic control of a process performed by a device that makes use of numeric data usually introduced as the operation is in progress (Ref. ISO 2382).
Cat 4 Cat 9	"Object code" "Object code": An equipment executable form of a convenient expression of one or more processes ("source code" (or source language)) which has been converted by a programming system.
Cat 5	"Optical amplification" In optical communications, an amplification technique that introduces a gain of optical signals that have been generated by a separate optical source, without conversion to electrical signals, i.e., using semiconductor optical amplifiers, optical fibre luminescent amplifiers.
Cat 4	"Optical computer" A computer designed or modified to use light to represent data and whose computational logic elements are based on directly coupled optical devices.
Cat 3	"Optical integrated circuit" A "monolithic integrated circuit" or a "hybrid integrated circuit", containing one or more parts designed to function as a photosensor or photoemitter or to perform (an) optical or (an) electro-optical function(s).
Cat 5	"Optical switching" The routing of or switching of signals in optical form without conversion to electrical signals.

Cat 3	"Overall current density" The total number of ampere-turns in the coil (i.e., the sum of the number of turns multiplied by the maximum current carried by each turn) divided by the total cross-section of the coil (comprising the superconducting filaments, the metallic matrix in which the superconducting filaments are embedded, the encapsulating material, any cooling channels, etc.).
Cat 6	"Peak power" Energy per pulse in joules divided by the pulse duration in seconds.
Cat 5	"Personalised smart card" A smart card containing a microcircuit which has been programmed for a specific application and cannot be reprogrammed for any other application by the user.
Cat 7	"Power management" Changing the transmitted power of the altimeter signal so that received power at the "aircraft" altitude is always at the minimum necessary to determine the altitude.
ML8	"Precursors" Speciality chemicals used in the manufacture of explosives.
Cat 1	"Previously separated" The application of any process intended to increase the concentration of the controlled isotope.
Cat 7	"Primary flight control" "Aircraft" stability or manoeuvering control using force/moment generators, i.e. aerodynamic control surfaces or propulsive thrust vectoring.
Cat 4	"Principal element" An element is a "principal element" when its replacement value is more than 35% of the total value of the system of which it is an element. Element value is the price paid for the element by the manufacturer of the system, or by the system integrator. Total value is the normal international selling price to unrelated parties at the point of manufacture or consolidation of shipment.
GTN Both Lists	"Production" Means all production stages, such as: product engineering, manufacture, integration, assembly (mounting), inspection, testing, quality assurance.

Cat 2 Cat 4 Cat 5 & 6	"Programme" A sequence of instructions to carry out a process in, or convertible into, a form executable by an electronic computer.
ML8	"Propellants" Substances or mixtures that react chemically to produce large volumes of hot gases at controlled rates to perform mechanical work.
Cat 6	"Pulse compression" The coding and processing of a radar signal pulse of long time duration to one of short time duration, while maintaining the benefits of high pulse energy.
Cat 6	"Pulse duration" Duration of a "laser" pulse measured at Full Width Half Intensity (FWHI) levels.
ML4 ML8	"Pyrotechnic(s)" Mixtures of solid or liquid fuels and oxidizers which, when ignited, undergo an energetic chemical reaction at a controlled rate intended to produce specific time delays, or quantities of heat, noise, smoke, visible light or infrared radiation. Pyrophorics are a subclass of pyrotechnics, which contain no oxidizers but ignite spontaneously on contact with air.
Cat 5P2	"Quantum cryptography" A family of techniques for the establishment of a shared key for "cryptography" by measuring the quantum-mechanical properties of a physical system (including those physical properties explicitly governed by quantum optics, quantum field theory, or quantum electrodynamics).
Cat 6	"Q-switched laser" A "laser" in which the energy is stored in the population inversion or in the optical resonator and subsequently emitted in a pulse.
Cat 6	"Radar frequency agility" Any technique which changes, in a pseudo-random sequence, the carrier frequency of a pulsed radar transmitter between pulses or between groups of pulses by an amount equal to or larger than the pulse bandwidth.
Cat 6	"Radar spread spectrum" Any modulation technique for spreading energy originating from a signal with a relatively narrow frequency band, over a much wider band of frequencies, by using random or pseudo-random coding.
Cat 3	"Real-time bandwidth"

For "dynamic signal analysers", the widest frequency range which the analyser can output to display or mass storage without causing any discontinuity in the analysis of the input data. For analysers with more than one channel, the channel configuration yielding the widest "real-time bandwidth" shall be used to make the calculation.

- Cat 2, "Real time processing"
- Cat 6 & 7 The processing of data by a computer system providing a required level of service, as a function of available resources, within a guaranteed response time, regardless of the load of the system, when stimulated by an external event.
- Cat 5 "Required"

Cat 6, 9 As applied to "technology", refers to only that portion of "technolog	sy"
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- GTN which is peculiarly responsible for achieving or exceeding the controlled ML 22 performance levels, characteristics or functions. Such "required" "technology" may be shared by different products.
- Cat 2 "Resolution"

The least increment of a measuring device; on digital instruments, the least significant bit. (Reference: ANSI B-89.1.12)

ML 7 "Riot control agents"

Substances which, under the expected conditions of use for riot control purposes, produce rapidly in humans sensory irritation or disabling physical effects which disappear within a short time following termination of exposure. (Tear gases are a subset of "riot control agents".)

Cat 2 "Robot"

Cat 8 ML 17

7

A manipulation mechanism, which may be of the continuous path or of the point-to-point variety, may use sensors, and has all the following characteristics:

- a. Is multifunctional;
- b. Is capable of positioning or orienting material, parts, tools or special devices through variable movements in three dimensional space;
- c. Incorporates three or more closed or open loop servo-devices which may include stepping motors; and
- d. Has "user-accessible programmability" by means of the teach/playback method or by means of an electronic computer which may be a programmable logic controller, i.e., without mechanical intervention.

<u>Note</u> The above definition does not include the following devices:

- 1. Manipulation mechanisms which are only manually/ teleoperator controllable;
- 2. Fixed sequence manipulation mechanisms which are automated moving devices, operating according to mechanically fixed programmed motions. The programme is mechanically limited by fixed stops, such as pins or cams. The sequence of motions and the selection of paths or angles are not variable or changeable by mechanical, electronic or electrical means;
- 3. Mechanically controlled variable sequence manipulation mechanisms which are automated moving devices, operating according to mechanically fixed programmed motions. The programme is mechanically limited by fixed, but adjustable stops, such as pins or cams. The sequence of motions and the selection of paths or angles are variable within the fixed programme pattern. Variations or modifications of the programme pattern (e.g., changes of pins or exchanges of cams) in one or more motion axes are accomplished only through mechanical operations;
- 4. Non-servo-controlled variable sequence manipulation mechanisms which are automated moving devices, operating according to mechanically fixed programmed motions. The programme is variable but the sequence proceeds only by the binary signal from mechanically fixed electrical binary devices or adjustable stops;
- 5. Stacker cranes defined as Cartesian coordinate manipulator systems manufactured as an integral part of a vertical array of storage bins and designed to access the contents of those bins for storage or retrieval.

Cat 1	"Rotary atomisation" A process to reduce a stream or pool of molten metal to droplets to a diameter of 500 µm or less by centrifugal force.		
Cat 2	"Run out" (out-of-true running) Radial displacement in one revolution of the main spindle measured in a plane perpendicular to the spindle axis at a point on the external or internal revolving surface to be tested (Reference: ISO 230/1-1986, paragraph 5.61).		
Cat 7	"Scale factor" (gyro or accelerometer) The ratio of change in output to a change in the input intended to be measured. Scale factor is generally evaluated as the slope of the straight line that can be fitted by the method of least squares to input-output data obtained by varying the input cyclically over the input range.		
Cat 3	"Settling time" The time required for the output to come within one-half bit of the final value when switching between any two levels of the converter.		
Cat 6	"SHPL" "SHPL" is equivalent to "Super High Power Laser".		
Cat 3	"Signal analysers" Apparatus capable of measuring and displaying basic properties of the single-frequency components of multi-frequency signals.		
Cat 3 Cat 4 Cat 5 Cat 6	"Signal processing" The processing of externally derived information- bearing signals by algorithms such as time compression, filtering, extraction, selection, correlation, convolution or transformations between domains (e.g., fast Fourier transform or Walsh transform).		
Both Lists	"Software" A collection of one or more "programmes" or "microprogrammes" fixed in any tangible medium of expression.		
	"Solidify rapidly" A process involving the solidification of molten material at cooling rates exceeding 1 000 K/sec.		
Cat 4 Cat 5, 6 Cat 7, 9	"Source code" A convenient expression of one or more processes which may be turned by a programming system into equipment executable form ("object code" (or object language)).		
Cat 7 Cat 9	"Spacecraft" Active and passive satellites and space probes.		

Cat 3 Cat 6 ML 23	"Space qualified" Products designed, manufactured and tested to meet the special electrical, mechanical or environmental requirements for use in the launch and deployment of satellites or high altitude flight systems operating at altitudes of 100 km or higher.
Cat 1	"Splat quenching" A process to "solidify rapidly" a molten metal stream impinging upon a chilled block, forming a flake-like product.
Cat 5	"Spread spectrum" The technique whereby energy in a relatively narrow-band communication channel is spread over a much wider energy spectrum.
Cat 6	"Spread spectrum" radar - see "Radar spread spectrum"
Cat 7	"Stability" Standard deviation (1 sigma) of the variation of a particular parameter from its calibrated value measured under stable temperature conditions. This can be expressed as a function of time.
Cat 3	"Substrate" A sheet of base material with or without an interconnection pattern and on which or within which "discrete components" or integrated circuits or both can be located.
Cat 6	"Substrate blanks" Monolithic compounds with dimensions suitable for the production of optical elements such as mirrors or optical windows.
Cat 2 Cat 9	"Superalloy" Nickel-, cobalt- or iron-base alloys having strengths superior to any alloys in the AISI 300 series at temperatures over 922 K (649°C) under severe environmental and operating conditions.
Cat 1 Cat 3, 6 Cat 8 ML18, 20	"Superconductive" Refers to materials,(i.e., metals, alloys or compounds) which can lose all electrical resistance (i.e., which can attain infinite electrical conductivity and carry very large electrical currents without Joule heating). <u>Technical Note</u> The "superconductive" state of a material is individually characterised by a "critical temperature", a critical magnetic field, which is a function of temperature, and a critical current density which is, however, a function of both magnetic field and temperature.

Cat 6	"Super High Power Laser" ("SHPL") A "laser" capable of delivering (the total or any portion of) the output energy exceeding 1 kJ within 50 ms or having an average or CW power exceeding 20 kW.		
Cat 1 Cat 2	"Superplastic forming" A deformation process using heat for metals that are normally characterised by low values of elongation (less than 20%) at the breaking point as determined at room temperature by conventional tensile strength testing, in order to achieve elongations during processing which are at least 2 times those values.		
Cat 5	 " Symmetric algorithm " A cryptographic algorithm using an identical key for both encryption and decryption. <u>Technical Note</u> A common use of "symmetric algorithms" is confidentiality of data. 		
Cat 6	"System tracks" Processed, correlated (fusion of radar target data to flight plan position) and updated aircraft flight position report available to the Air Traffic Control centre controllers.		
Cat 4	"Systolic array computer" A computer where the flow and modification of the data is dynamically controllable at the logic gate level by the user.		
GTN & Both Lists	"Technology" Specific information necessary for the "development", "production" or "use" of a product. The information takes the form of technical data or technical assistance. Controlled "technology" for the Dual-Use List is defined in the General Technology Note and in the Dual-Use List. Controlled "technology" for the Munitions List is specified in ML22.		
	 <u>Technical Notes</u> Technical data' may take forms such as blueprints, plans, diagrams, models, formulae, tables, engineering designs and specifications, manuals and instructions written or recorded on other media or devices such as disk, tape, read-only memories. Technical assistance' may take forms such as instruction, skills, training, working knowledge, consulting services. 'Technical assistance' may involve transfer of 'technical data'. 		

Cat 4	"Terminal interface equipment" Equipment at which information enters or leaves the telecommunication system, e.g., telephone, data device, computer, facsimile device.	
Cat 4	"Three dimensional Vector Rate" The number of vectors generated per second which have 10 pixel poly line vectors, clip tested, randomly oriented, with either integer or floating point X-Y-Z coordinate values (whichever produces the maximum rate).	
Cat 2	"Tilting spindle" A tool-holding spindle which alters, during the machining process, the angular position of its centre line with respect to any other axis.	
Cat 6	"Time constant" The time taken from the application of a light stimulus for the current increment to reach a value of 1-1/e times the final value (i.e., 63% of the final value).	
Cat 7	"Total control of flight" Automated control of "aircraft" state variables and flight path to meet mission objectives responding to real time changes in data regarding objectives, hazards or other "aircraft".	
Cat 5	"Total digital transfer rate" The number of bits, including line coding, overhead and so forth per unit time passing between corresponding equipment in a digital transmission system. (See also "digital transfer rate")	
Cat 6	"Transfer laser" A "laser" in which the lasing species is excited through the transfer of energy by collision of a non-lasing atom or molecule with a lasing atom or molecule species.	
Cat 6	"Tunable" The ability of a "laser" to produce a continuous output at all wavelengths over a range of several "laser" transitions. A line selectable "laser" produces discrete wavelengths within one "laser" transition and is not considered "tunable".	
Cat 9	"Unmanned aerial vehicle" ("UAV") Any "aircraft" capable of initiating flight and sustaining controlled flight and navigation without any human presence on board.	
GTN Cat 1, 2, 4 Cat 5, 6, 7 Cat 8 & 9 ML 21, 22	"Use" Operation, installation (including on-site installation), maintenance (checking), repair, overhaul and refurbishing.	

- Cat 4 "User-accessible programmability"
- Cat 5, 6 The facility allowing a user to insert, modify or replace "programmes" by means other than:
 - a. A physical change in wiring or interconnections; or
 - b. The setting of function controls including entry of parameters.
- Cat 1 "Vacuum atomisation" A process to reduce a molten stream of metal to droplets of a diameter of 500 μm or less by the rapid evolution of a dissolved gas upon exposure to a vacuum.
- Cat 7 "Variable geometry airfoils" Use trailing edge flaps or tabs, or leading edge slats or pivoted nose droop, the position of which can be controlled in flight.

Acronyms and Abbreviations

ACRONYMS AND ABBREVIATIONS USED IN THESE LISTS

An acronym or abbreviation, when used as a defined term, will be found in 'Definitions of Terms used in these Lists'.

<u>ACRONYM OR</u> <u>ABBREVIATION</u>	<u>MEANING</u>
ABEC	Annular Bearing Engineers Committee
AGMA	American Gear Manufacturers' Association
AHRS	attitude and heading reference systems
ALU	arithmetic logic unit
ATC	air traffic control
C ³ I	command, communications, control & intelligence
CAD	computer-aided-design
CAS	Chemical Abstracts Service
CDU	control and display unit
CEP	circular error probable
CNTD	controlled nucleation thermal deposition
CVD	chemical vapour deposition
CW	chemical warfare
CW (for lasers)	continuous wave
DEW	directed energy weapon systems
DME	distance measuring equipment
DS	directionally solidified
EB-PVD	electron beam physical vapour deposition
EBU	European Broadcasting Union
ECM	electro-chemical machining
ECR	electron cyclotron resonance
EDM	electrical discharge machines
EEPROMS	electrically erasable programmable read only memory
EIA	Electronic Industries Association
EMC	electromagnetic compatibility
EMCDB	elastomer modified cast double based propellants
FFT	Fast Fourier Transform
GLONASS	global navigation satellite system
GPS	global positioning system
HBT	hetero-bipolar transistors
HDDR	high density digital recording
HEMT	high electron mobility transistors
ICAO	International Civil Aviation Organisation
IEC	International Electro-technical Commission
IEEE	Institute of Electrical and Electronic Engineers
IFOV	instantaneous-field-of-view
ILS	instrument landing system

Acronyms and Abbreviations

ACRONYM OR ABBREVIATION

MEANING

IRIG	inter-range instrumentation group
ISAR	inverse synthetic aperture radar
ISO	International Organization for Standardization
ITU	International Telecommunication Union
JIS	Japanese Industrial Standard
JT	Joule-Thomson
LIDAR	light detection and ranging
LRU	line replaceable unit
MAC	me replaceable unit message authentication code
Mach	
MLS	ratio of speed of an object to speed of sound (after Ernst Mach)
	microwave landing systems
MOCVD	metal organic chemical vapour deposition
MRI	magnetic resonance imaging
MTBF	mean-time-between-failures
Mtops	million theoretical operations per second
MTTF	mean-time-to-failure
NBC	Nuclear, Biological and Chemical
NDT	non-destructive test
PAR	precision approach radar
PIN	personal identification number
ppm	parts per million
PSD	power spectral density
QAM	quadrature-amplitude-modulation
RF	radio frequency
RPV	remotely piloted air vehicles
SACMA	Suppliers of Advanced Composite Materials Association
SAR	synthetic aperture radar
SC	single crystal
SLAR	sidelooking airborne radar
SMPTE	Society of Motion Picture and Television Engineers
SRA	shop replaceable assembly
SRAM	static random access memory
SRM	SACMA Recommended Methods
SSB	single sideband
SSR	secondary surveillance radar
TCSEC	trusted computer system evaluation criteria
TIR	total indicated reading
UTS	ultimate tensile strength
VOR	very high frequency omni-directional range
YAG	yttrium/aluminum garnet

Statements of Understanding and Validity Notes

STATEMENTS OF UNDERSTANDING AND VALIDITY NOTES

Intangible Transfers* of Software and Technology (WA-GWG (01) DE 7 Version 2.0)

Participating States recognise that it is important to have comprehensive controls on listed "software" and "technology", including controls on intangible transfers. National export control legislation should therefore permit controls on transfers of listed "software" and "technology" irrespective of the way in which the transfer takes place.** Participating States also recognise that it is important to continue the mutual exchange within the Wassenaar Arrangement on the experiences gained concerning the implementation and enforcement of these national provisions on the control of intangible transfers. New developments should thus be taken into account in order to meet all risks connected with this issue.

- * "Transfers" in this context is understood in the sense of the Initial Elements. The term covers exports from one country to another.
- ** "irrespective of the way in which the transfer takes place" means, at a minimum:
 - tangible transfers
 - intangible transfers via transmission of listed software and technology by electronic media, fax or telephone.

MUNITIONS LIST

ML 8

Statement of Understanding

It is understood that specially formulated pharmaceutical products containing ML8. materials are not controlled.

ML 10 (NF (95) WG2/2)

Absence of items from the Munitions List and absence of configuration for military use would mean that an aircraft would not be considered military.

DUAL-USE LIST OF GOODS AND TECHNOLOGIES

General Technology Note (NF (95) CA WP 1)

Governments agree that the transfer of "technology" according to the General Technology Note, for "production" or "development" of items on this list shall be treated with vigilance in accordance with national policies and the aims of this regime.

Statements of Understanding and Validity Notes

General Technology Note (WG2 GTN TWG/WP1 Revised 2)

It is understood that Member Governments are expected to exercise controls on intangible "technology" as far as the scope of their legislation will allow.

General Software Note (NF (95) CA WP 1)

Governments agree that the transfer of "software", for "production" or "development" of items on this list shall be treated with vigilance in accordance with national policies and the aims of this regime.

Statement of Understanding - medical equipment (NF (96) DG PL/WP1)

Participating countries agree that equipment specially designed for medical end-use that incorporates an item controlled in the Dual-Use List is not controlled.

Category 6

<u>Validity note:</u> The control text contained in 6.A.2.a. Nota Bene, 6.A.2.a.3. Nota Bene, 6.A.2.a.3.c. Nota Bene, 6.A.2.a.3.f., 6.A.3.b.4. and 6.A.3.b.4. Notes 1, 2 and 3 is valid until 05 December 2007 and its renewal will require unanimous consent.

Category 9

9.A.12.

Statement of Understanding

Participating States understand a model aircraft as intended for recreational and competition purposes.

9.E.2.

Statement of Understanding

"Development" or "production" "technology" controlled by 9.E. for gas turbine engines remains controlled when used as "use" "technology" for repair, rebuild and overhaul. Excluded from control are: technical data, drawings or documentation for maintenance activities directly associated with calibration, removal or replacement of damaged or unserviceable line replaceable units, including replacement of whole engines or engine modules.

Statements of Understanding and Validity Notes

DEFINITION OF TERMS USED IN THESE LISTS

Statement of Understanding

Participating States note that, in these Lists, words and terms appearing under 'Definitions of Terms used in these Lists', if used in their undefined forms, take their common or dictionary meanings. Governments are expected to preserve these distinctions, as far as national languages and legislation allow, when the Lists are translated into national legislation. (See also Note 2 to 'Definitions of Terms used in these Lists').

<u>N.B.</u> The references in this section refer to the List of Dual-Use Goods and Technologies and the Munitions List approved by the Plenary meeting (13-14 December 2005).